



# **Nanoplasmonics: From Surface-Enhanced Raman Spectroscopy to Nanophotonic Circuits**

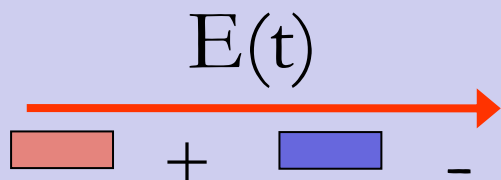
**Hongxing Xu**

**Institute of Physics, CAS  
Wuhan University**

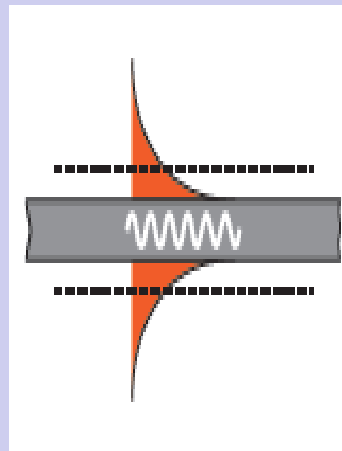
**2014, 4, 17 Beijing**

# 表面等离激元及其研究意义

表面等离激元：  
金属自由电子气的集体振荡

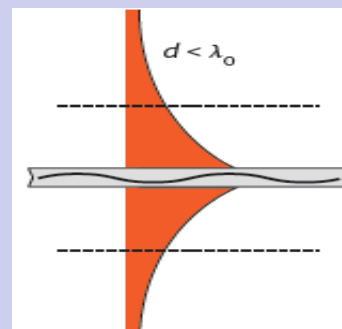


特殊的共振特性  
局域电场增强效应



等离激元结构  
尺寸**小于波长**

突破衍射极限

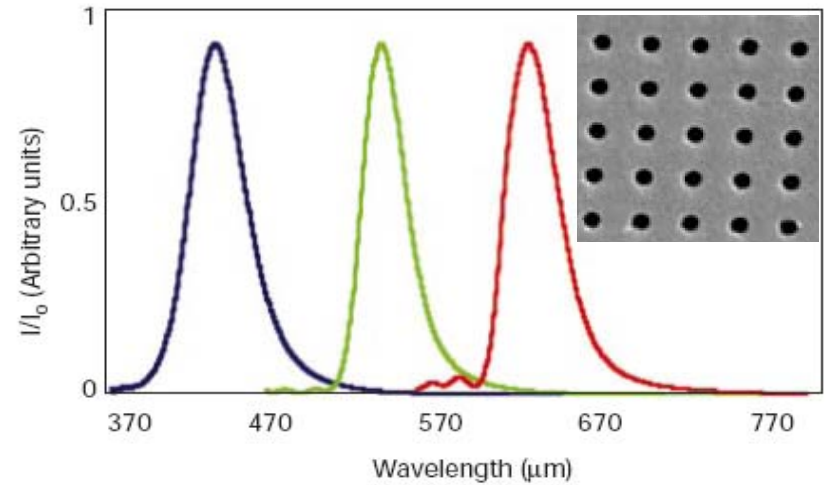
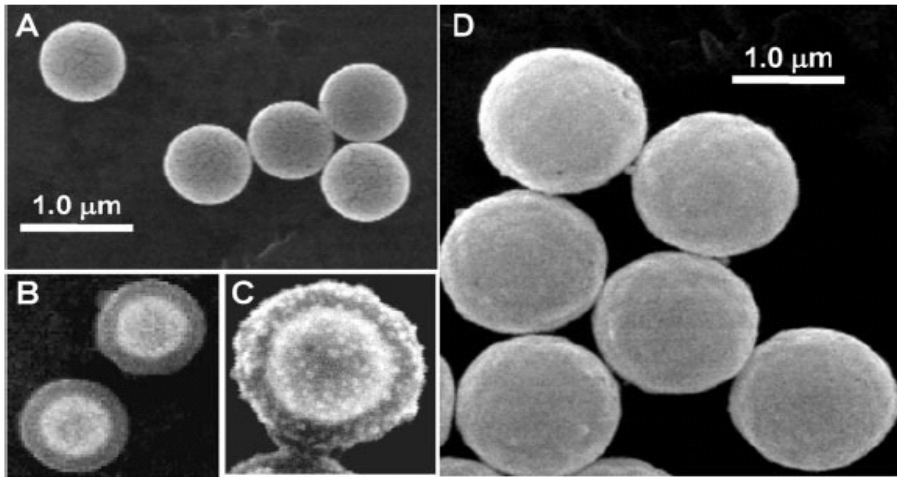
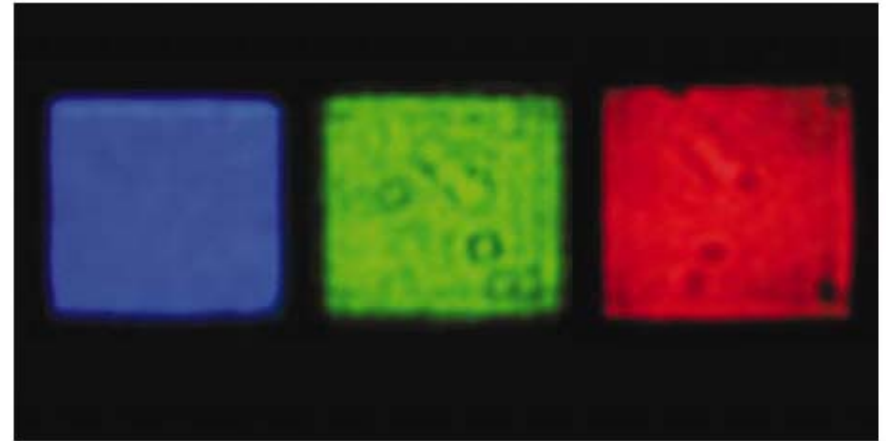
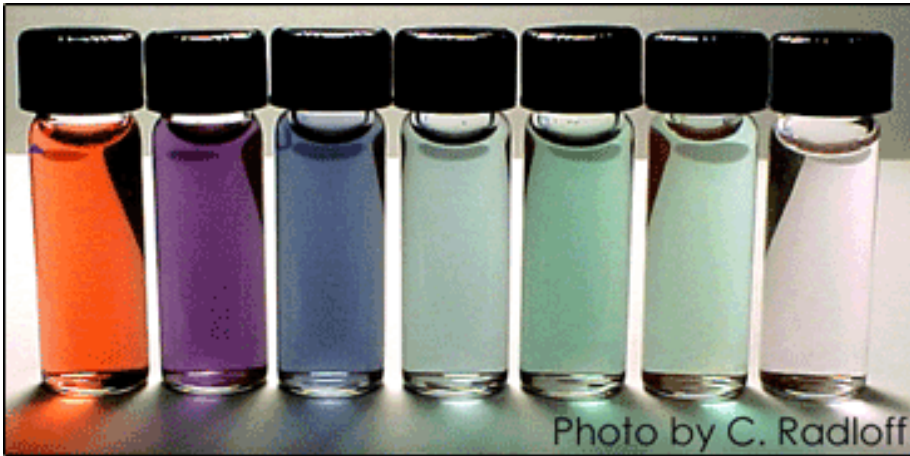


介质光传输结构  
尺寸**大于波长**

衍射极限

- 亚波长的光束缚和远程传播
- 纳米尺度上光的调控

# 例1—共振频率可调



*Halas et al. Science, 302, 419 (2003)*

*Ebbesen et al. Nature 424, 824 (2003)*

# 金属纳米颗粒的奇特的散射和透射

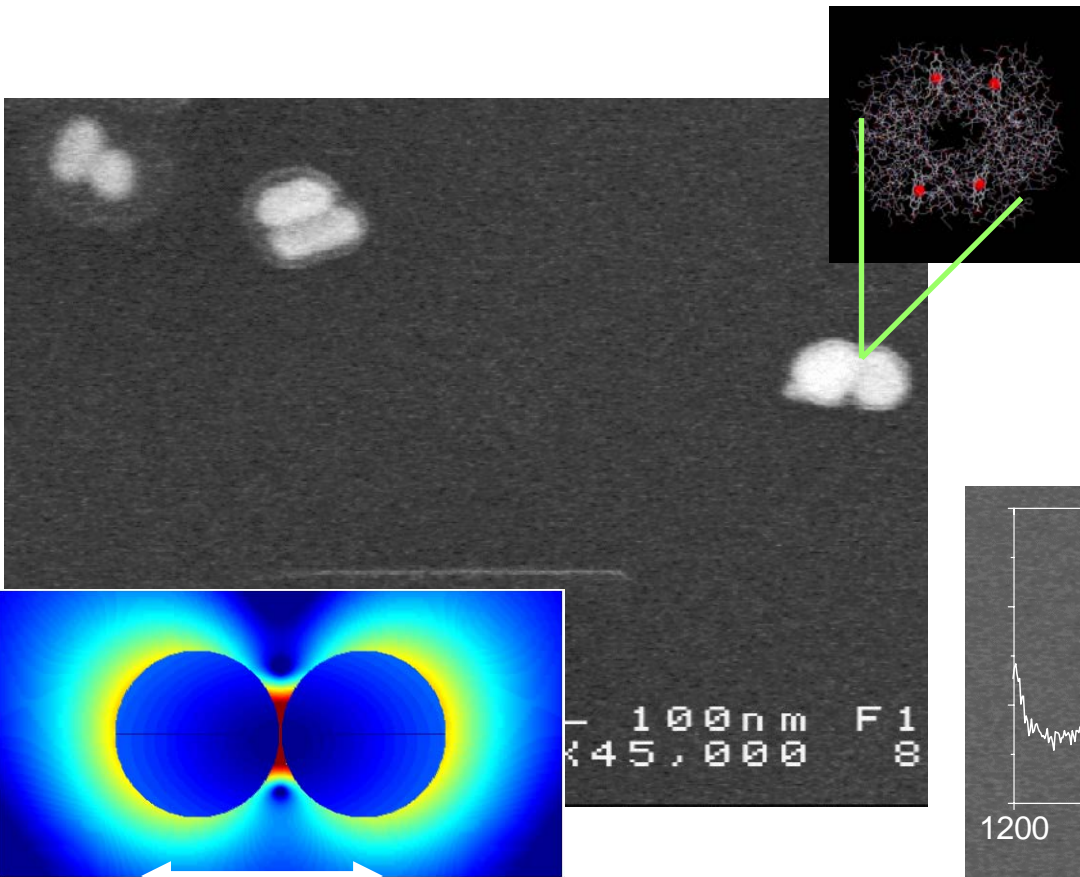
## The Lycurgus Cup



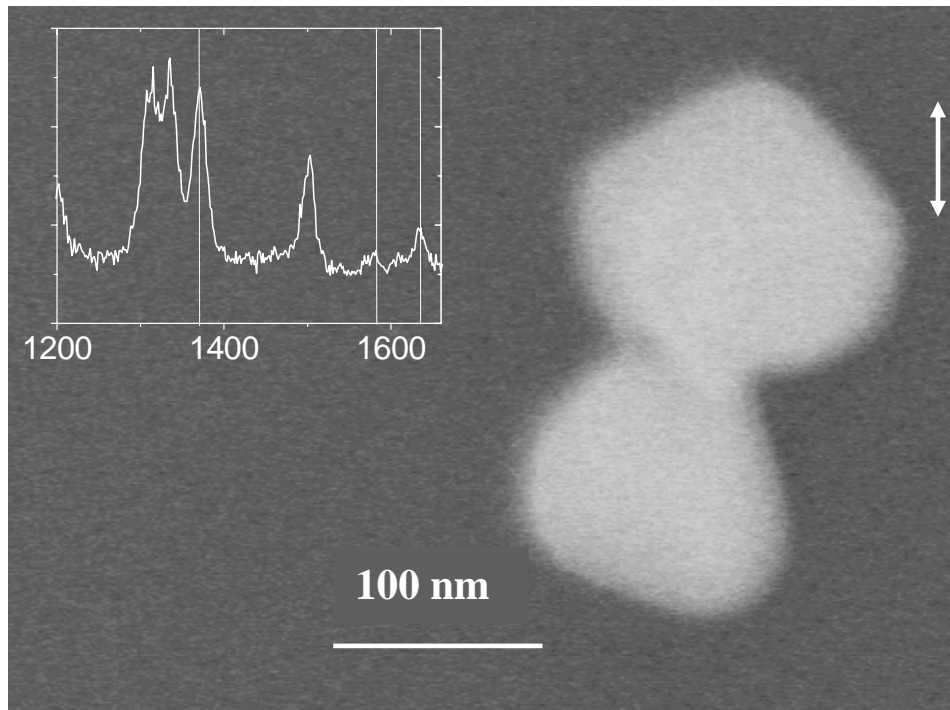
*Gold Bull* 2007, 40, 270-277



# 例2—巨大电磁增强效应

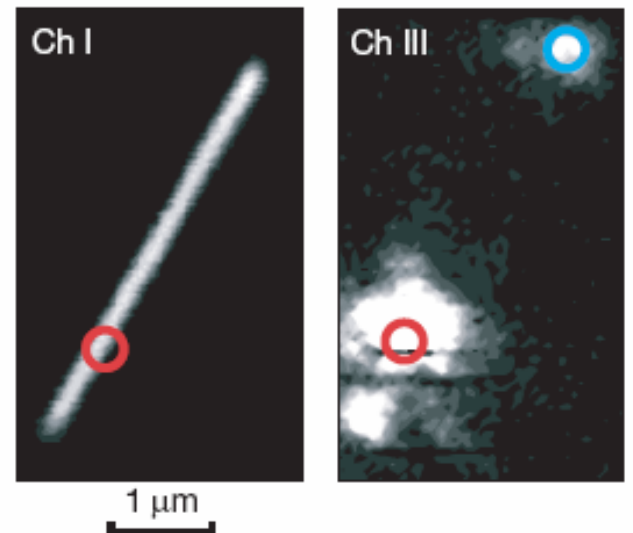
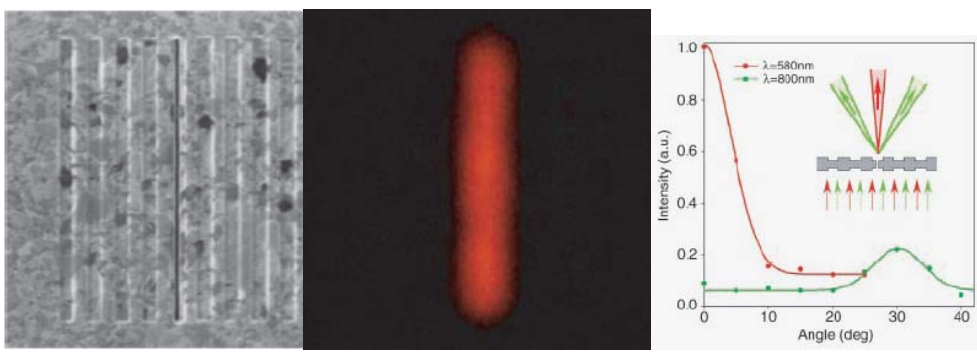
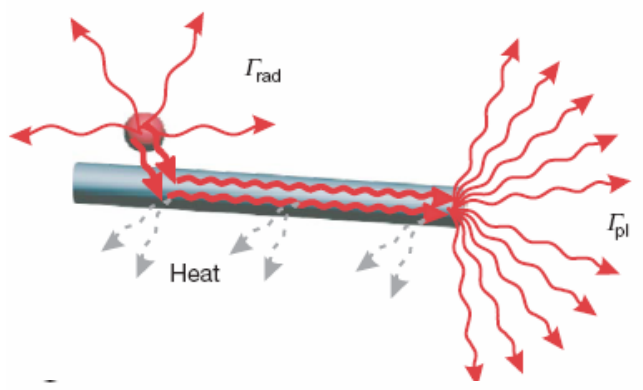
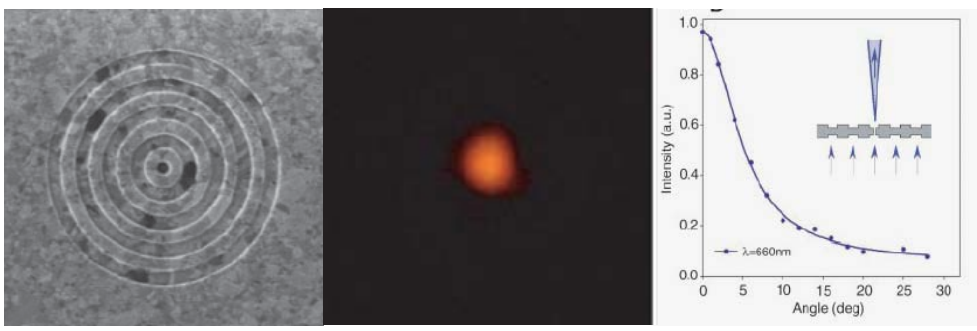


- 当银胶溶液与血红蛋白溶液混合后,两个银颗粒被单个血红蛋白分子粘在一起
- 血红蛋白分子/银颗粒  $\sim 1:4$



徐红星 等 **PRL 83** 4357 (1999)  
巨大的电磁增强效应, 解释了  
单分子表面增强拉曼散射的机理。

# 例3—纳米尺度光的传导



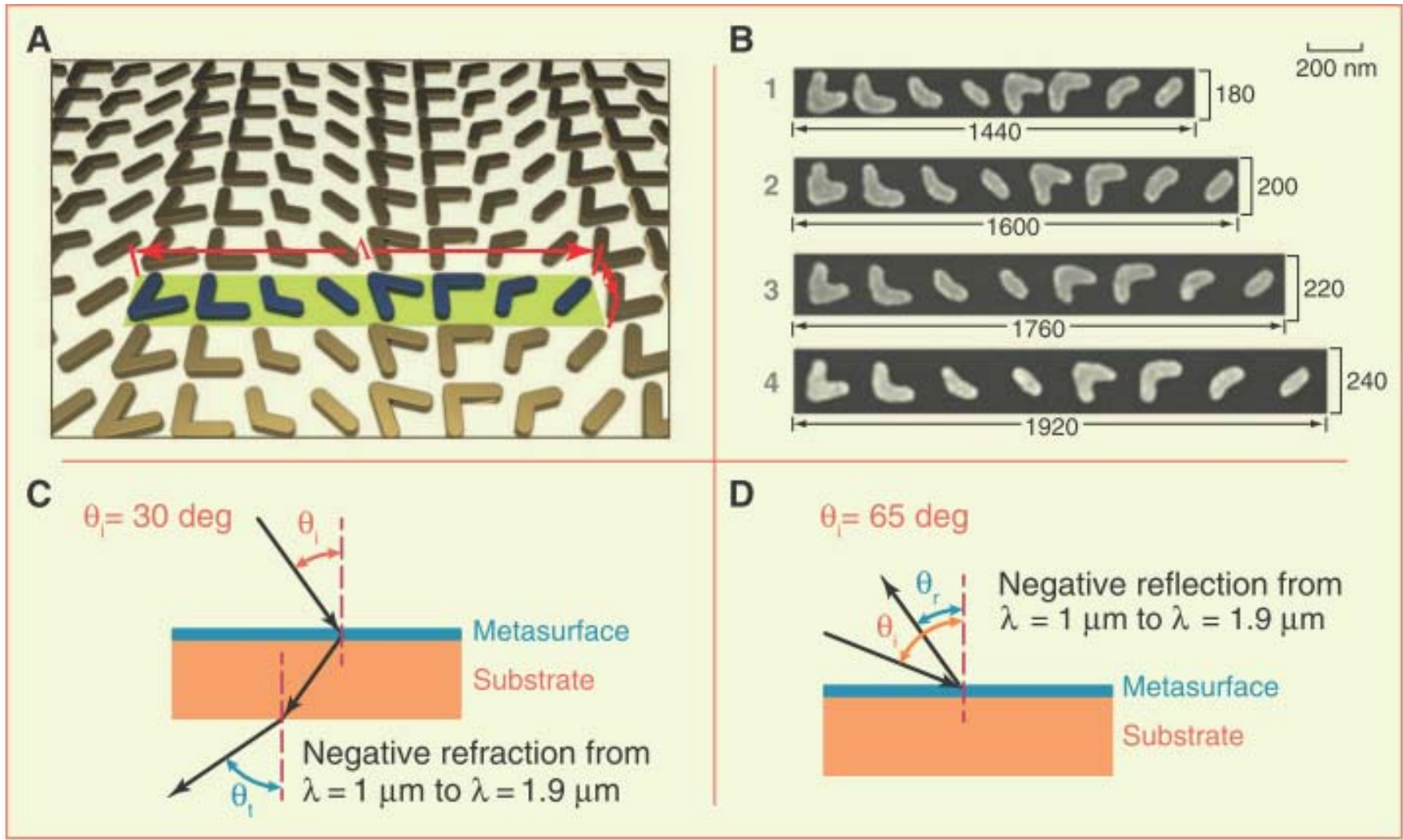
Lezec *et al.* *Science* **297**, 820 (2002)

Akimov *et al.* *nature* **450**, 402 (2007)

克服光的衍射极限的传播!

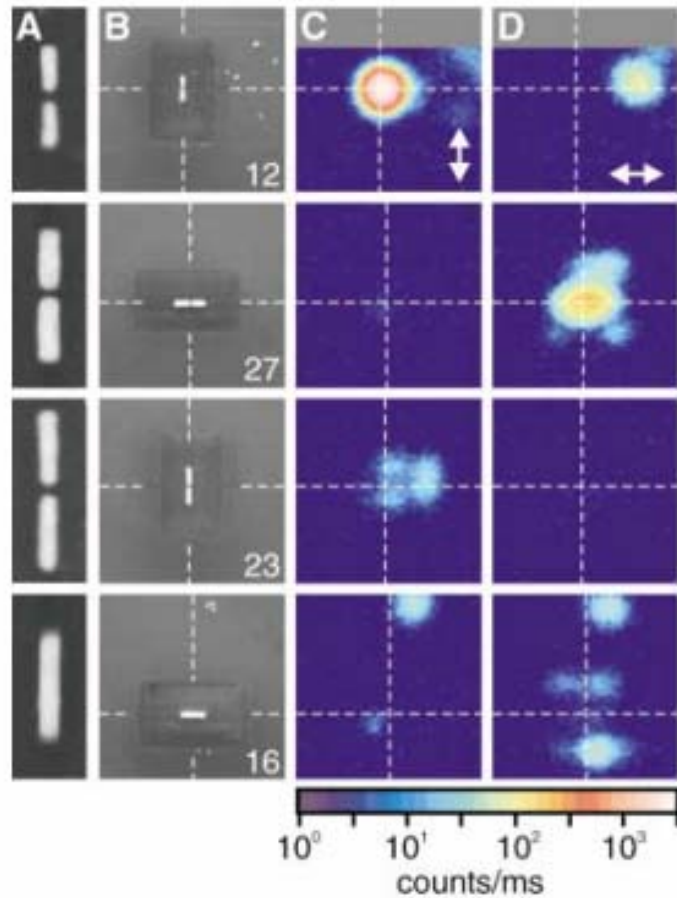
# 例4—任意的透射和反射规律

## Metasurfaces



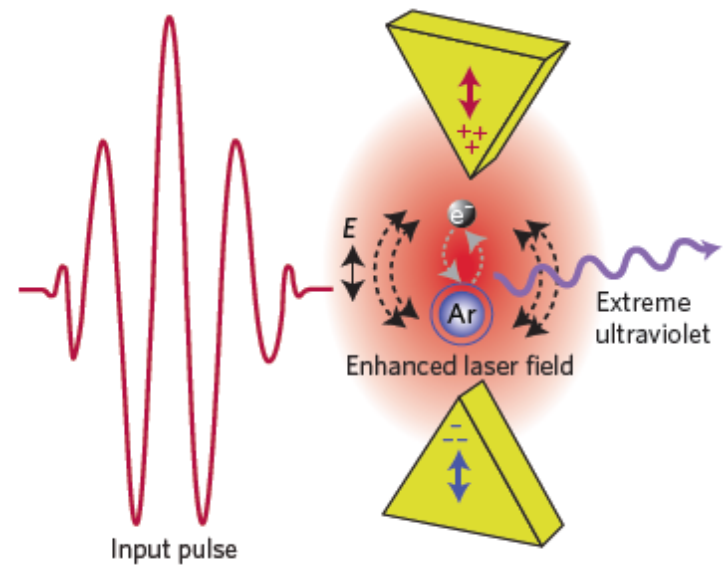
# 例5—增强光学非线性效应

## 二阶和频产生



*Science* 2005, 308, 1607-1609

## 高阶和频产生

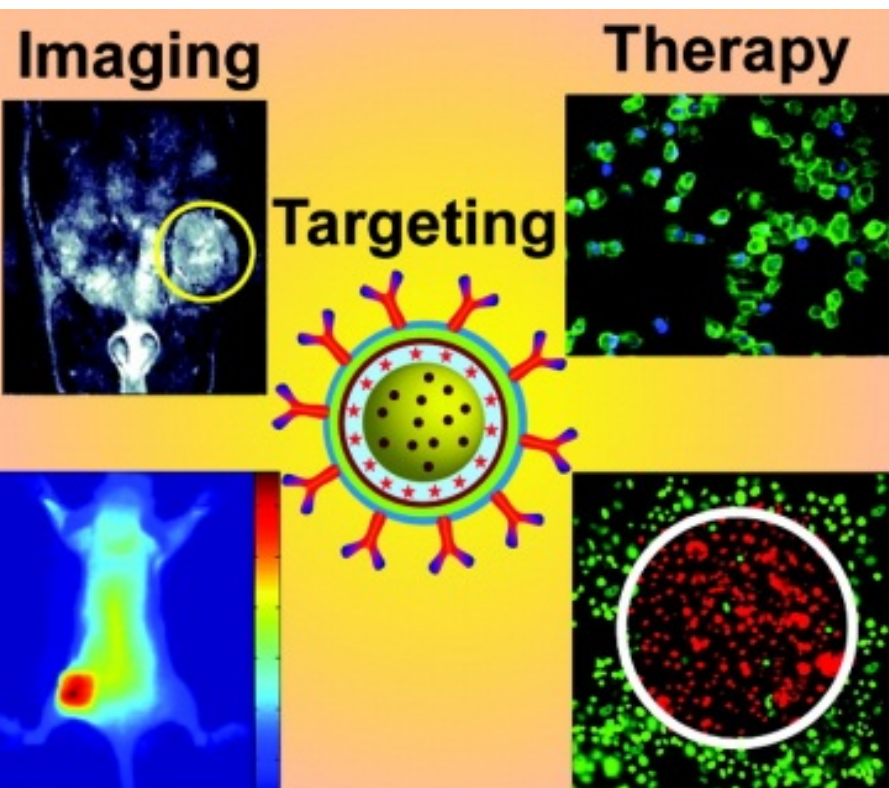


*Nature* 453, 757-760 (2008)

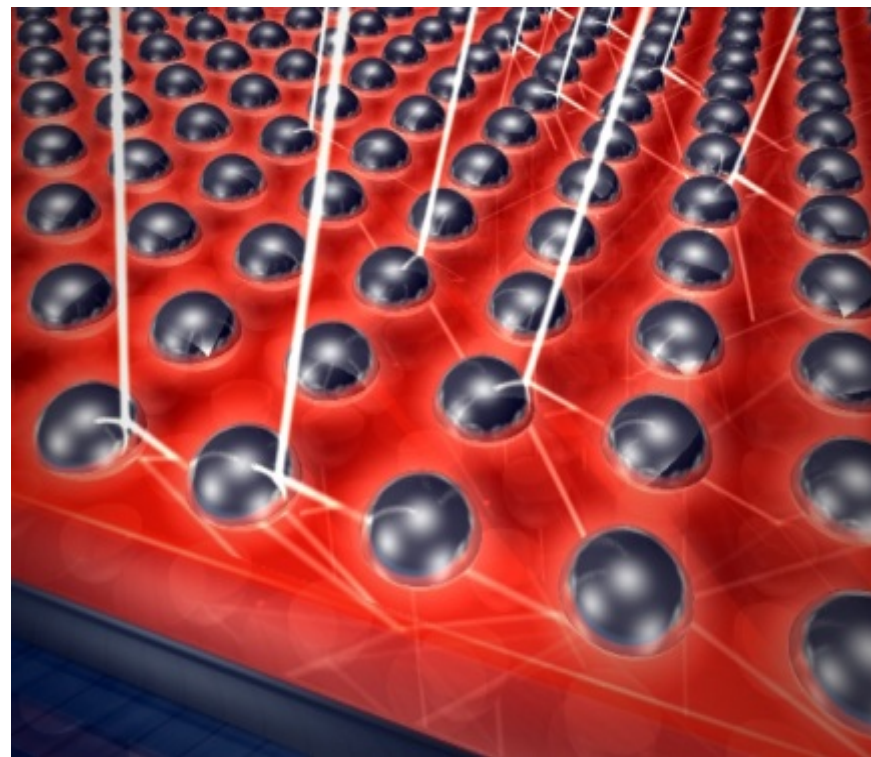


# 例6—癌症热疗与太阳能电池

## 癌症热疗



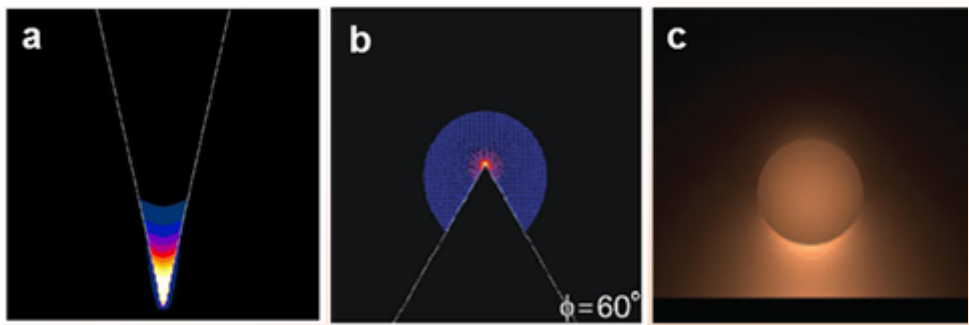
## 太阳能电池





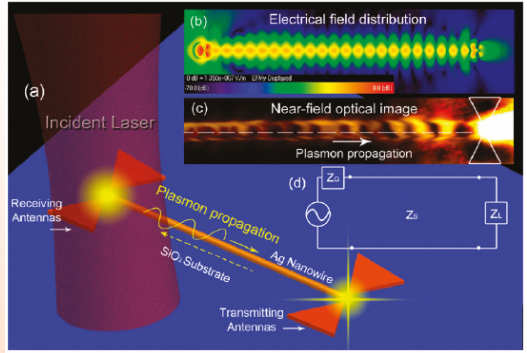
# 例6—微纳光器件

## 亚波长波导



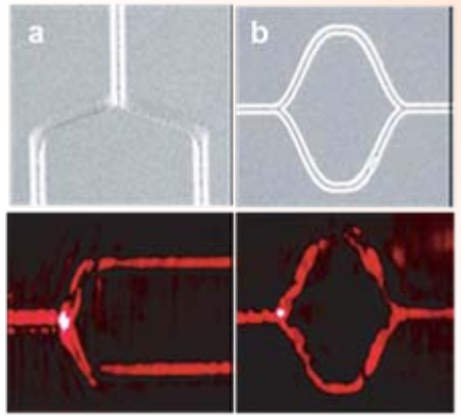
*Opt. Lett.* **2006**, *31*, 3447-3449; *Phys. Rev. Lett.* **2008**, *100*, 023901;  
*Nat. Photon.* **2008**, *2*, 496-500

## 耦合器



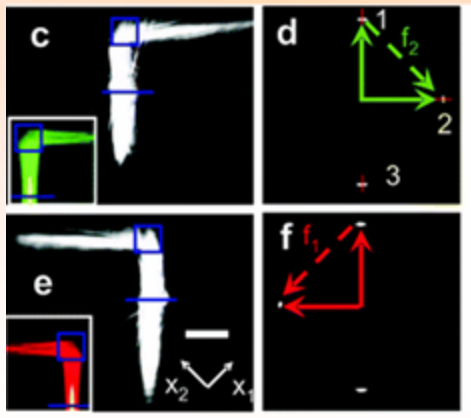
*Nano Lett.*, **2011**, *11* (4), 1676-1680

## 干涉器



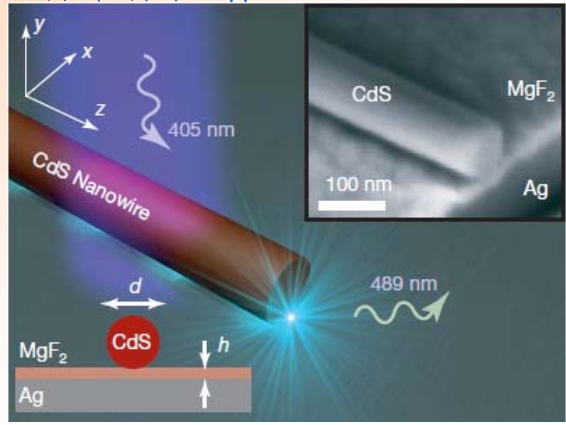
*Nature*, **440**(23), 508-511(2006)

## 分光器



*Nano Lett.* **2007**, *7*, 1697-1700

## 纳米激光器



*Nature* **2009**, *461* (7264), 629-632

还有聚焦元件、反射器、滤波器……

# 广阔的应用前景

等离激元逻辑运算

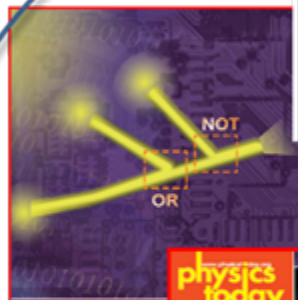
纳米光电检测器

纳米天线

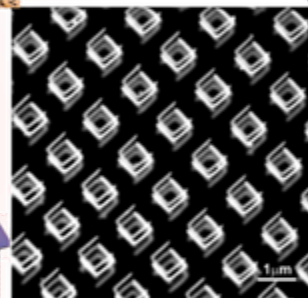
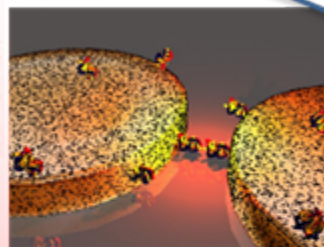
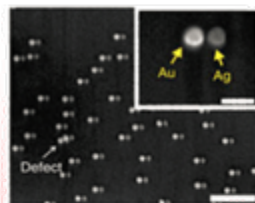
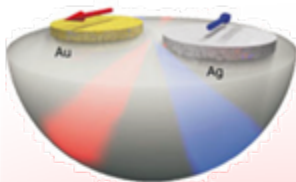
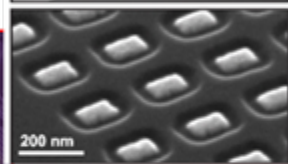
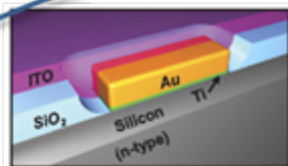
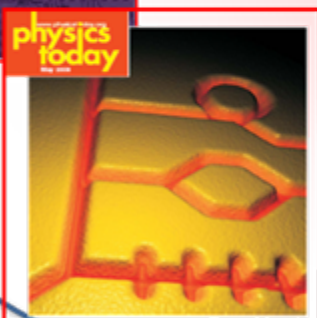
化学生物传感器

超材料

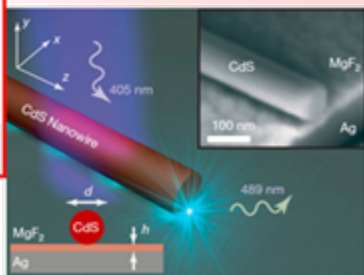
等离激元光子学  
( Plasmonics )  
发展迅速的  
前沿交叉学科



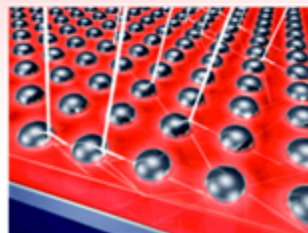
physics today



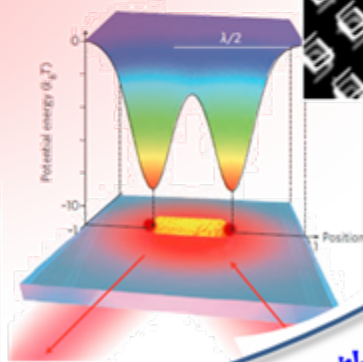
等离激元全光芯片



纳米激光器



太阳能电池

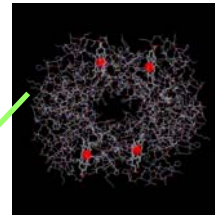
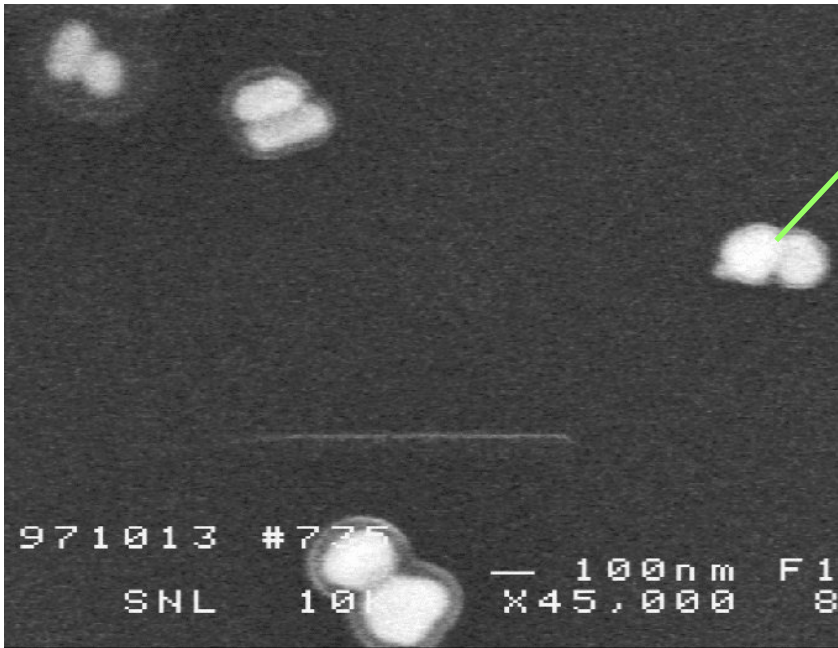


等离激元光镊

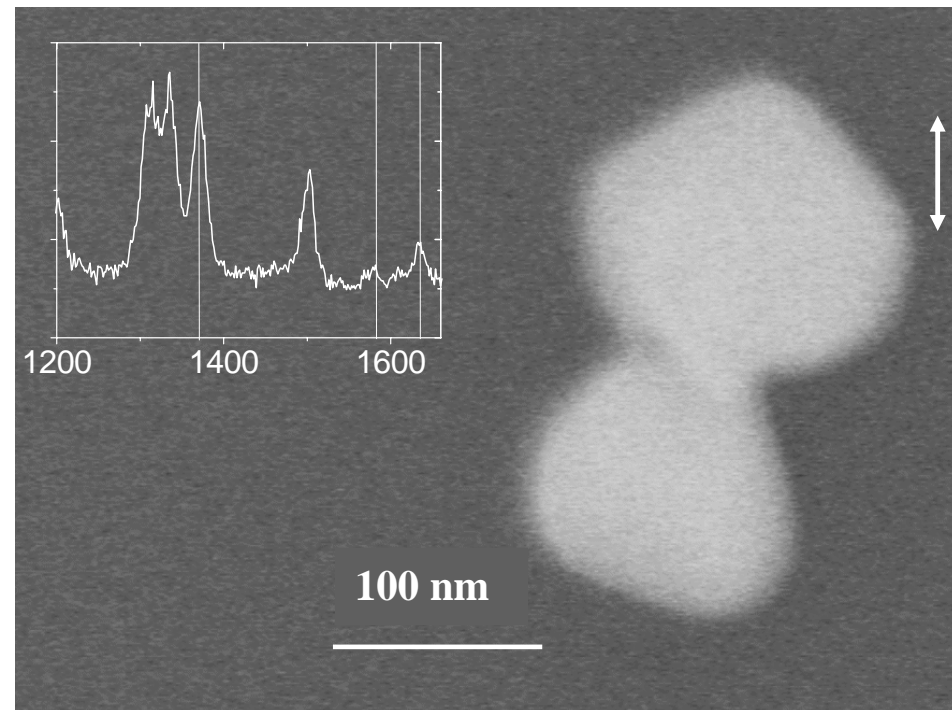
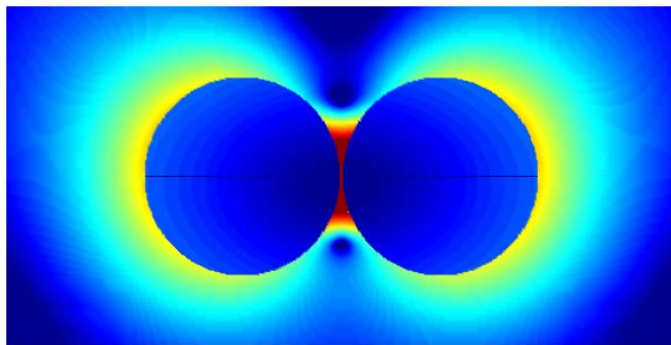
# **1. Surface enhanced Raman spectroscopy**

# Hot spot/ Nanogap for huge SERS(EM) enhance

## Coupling Plasmons for Single Molecule SERS



- Ag sol mixed with  $10^{-11}$ M Hb  
Hb/Ag particles  $\sim 1:4$
- Ag dimers can be observed,  
which is most likely  
connected by Hb



Xu *et al.* PRL **83** 4357 (1999)

&

Xu & Aizpurua *et al.* PRE **62** 4318 (2000)



Plasmon optical forces

Plasmochemistry

Dimer Antenna

Receival Antenna ( $|E/E_0|^2$ )

Emission Antenna ( $|E/E_0|^2$ )

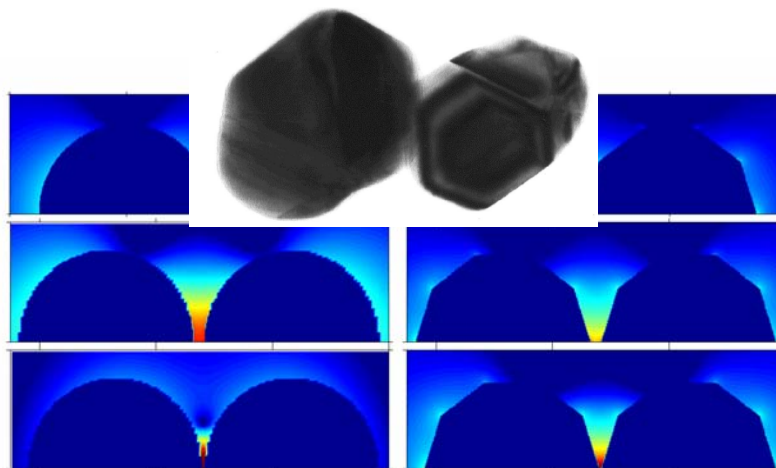
Plasmon hybridization

Quantum plasmon  
(coupling)

Nanogap/Hot spot ...  
for SERS

Nonlinear  
plasmonic  
effects

The base of  
many directions  
in plasmonics

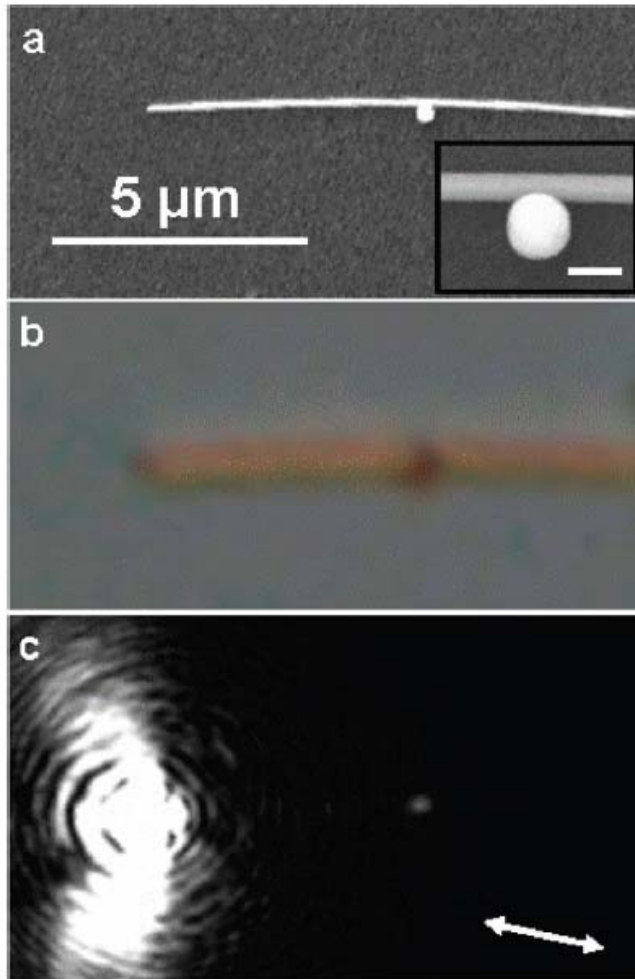


Xu *et al.* PRL **83** 4357 (1999);

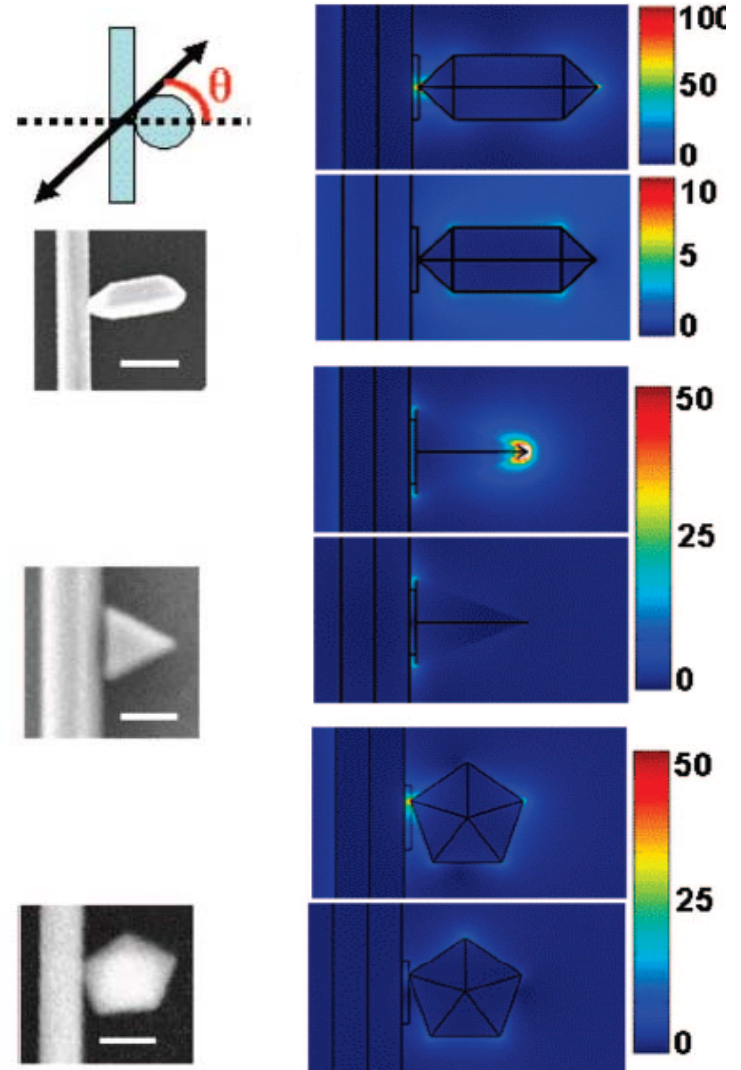
Xu & Aizpurua *et al.* PRE **62** 4318 (2000)



# Remote-Excitation Raman Using Propagating Surface Plasmons

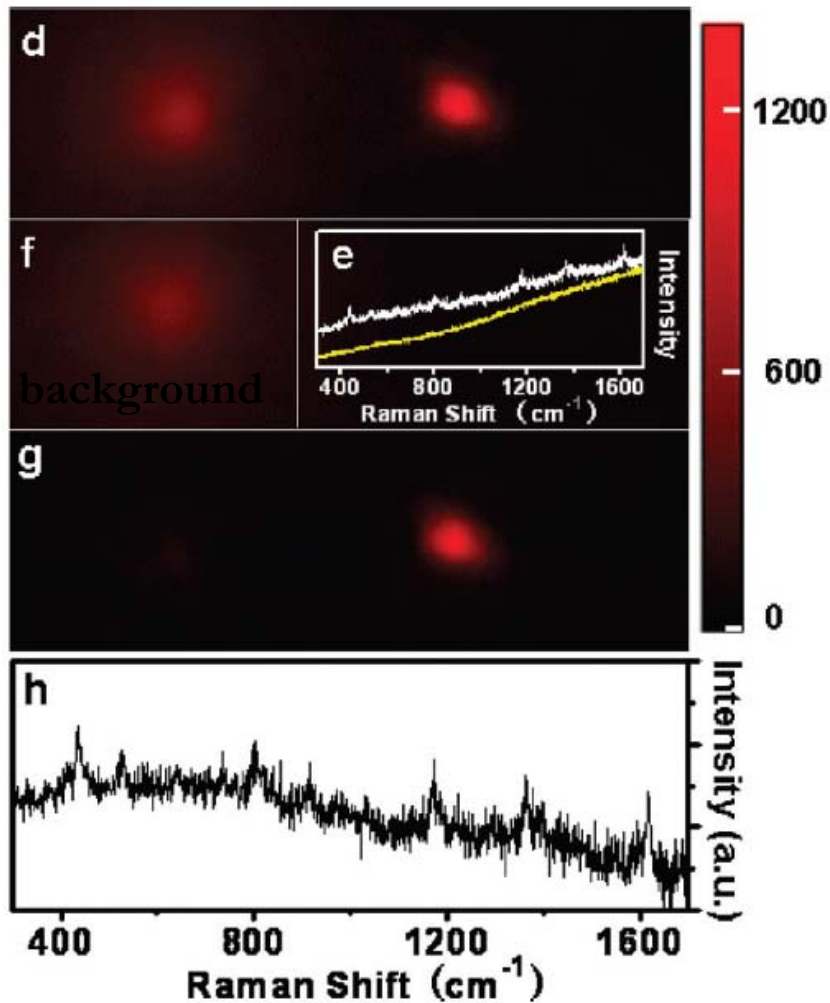


Fang&Wei et al, Nano Lett. 9, 2049 (2009)

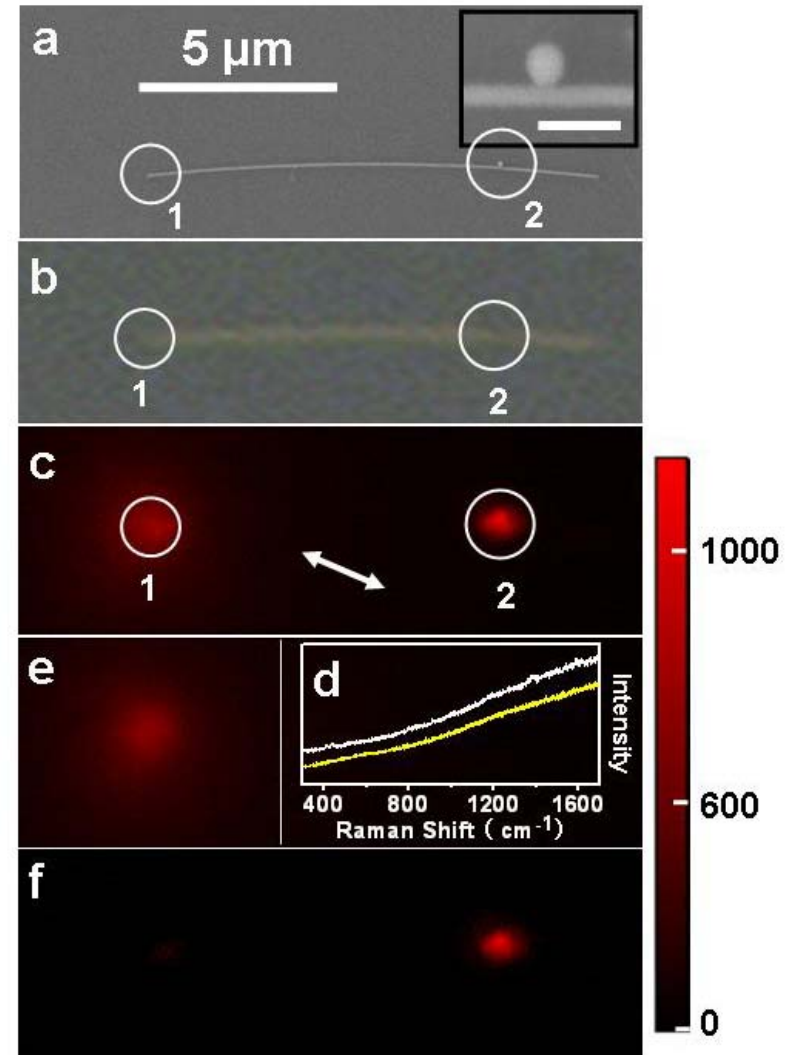


Wei et al., Nano Lett., 8, 2497, 2008

# Remote-Excitation Raman Using Propagating Surface Plasmons



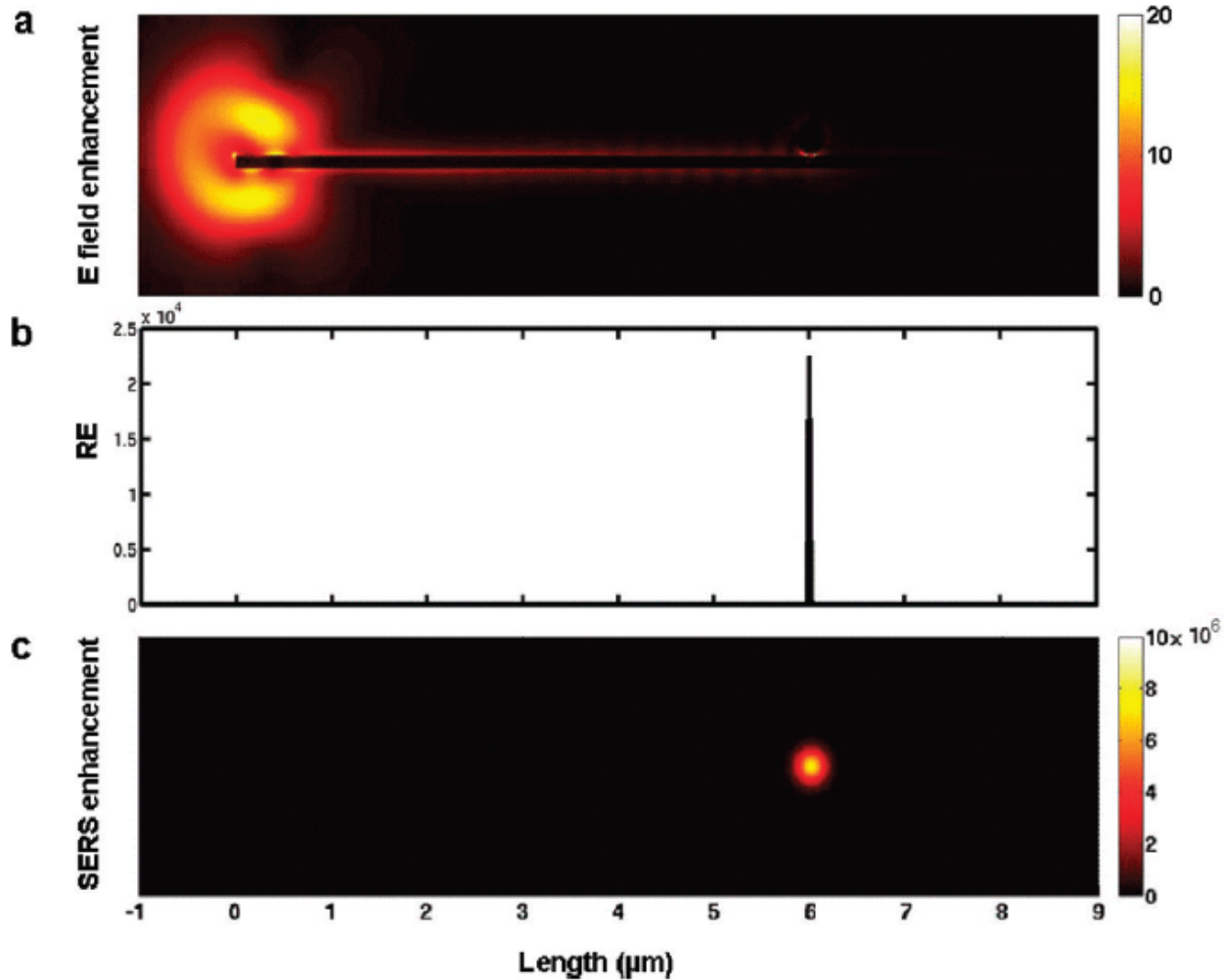
Raman spectra of  
malachite green isothiocyanate  
(MGITC)



Fang&Wei et al, Nano Lett. 9, 2049 (2009)

# Remote-Excitation Raman Using Propagating Surface Plasmons

Finite Element Method      COMSOL



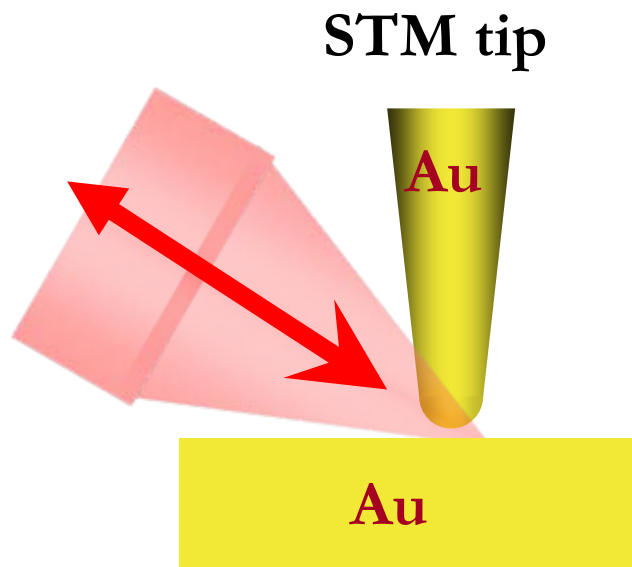
Fang&Wei et al, Nano Lett. 9, 2049 (2009)

# Remote-Excitation Raman Using Propagating Surface Plasmons

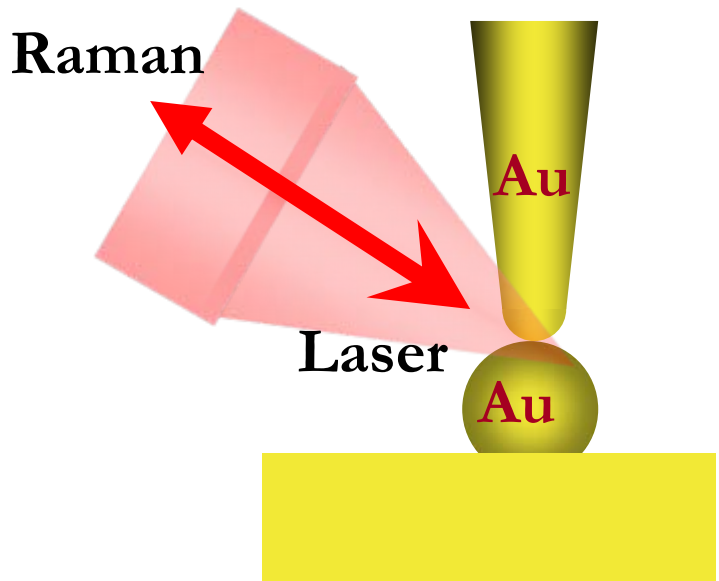
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## Advantages of Remote sensing for SERS

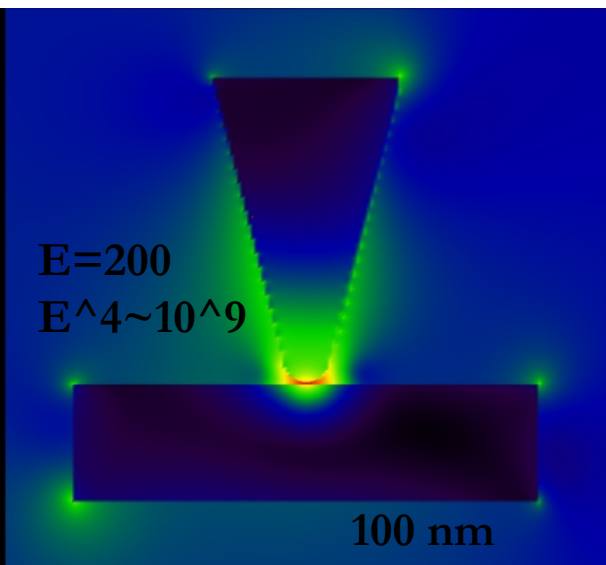
- *Nano light source*
- *Background free*
- *Low damage*



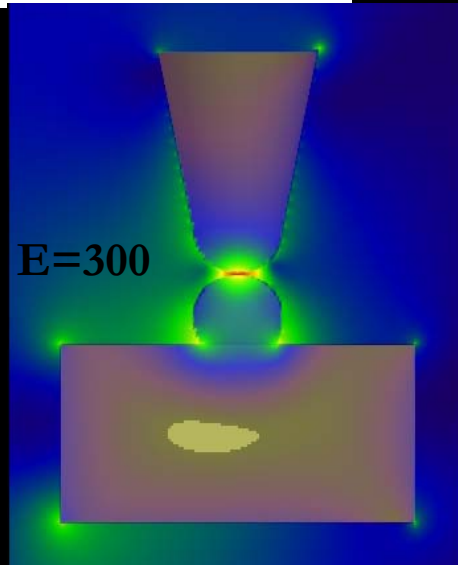
Normal TERS setup



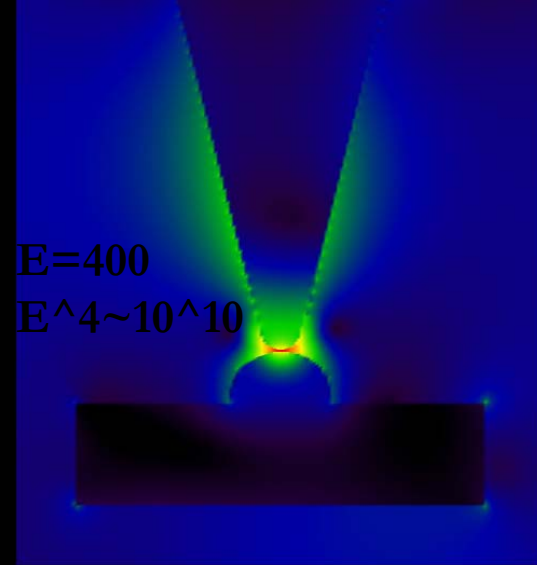
Double-tip TERS setup



2.063e+002 V/m Mag EFM Displayed  
 Spatial location (nm): [0.00, -0.00, 0.00]  
 Cell location: [95, 72, 115][?, 3][2, 3][?]  
 (0.0 [dB]) MagEFM: 0.549[V/m][5.150e+001[dB]]



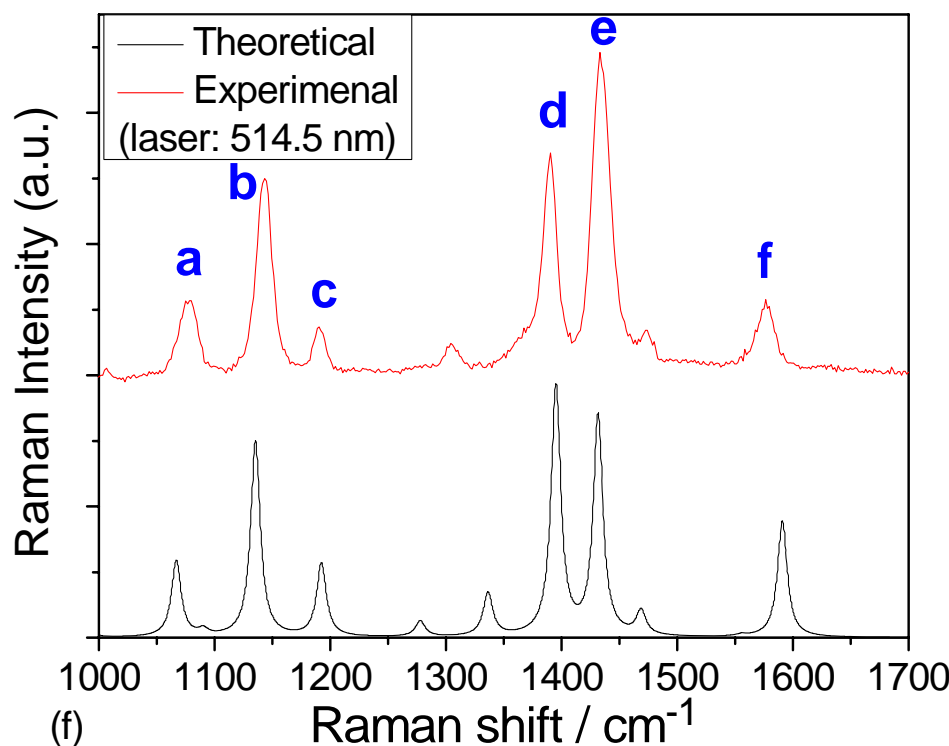
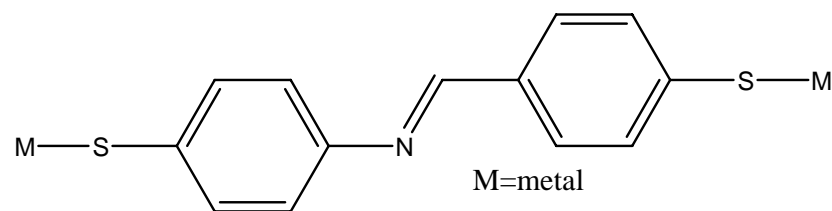
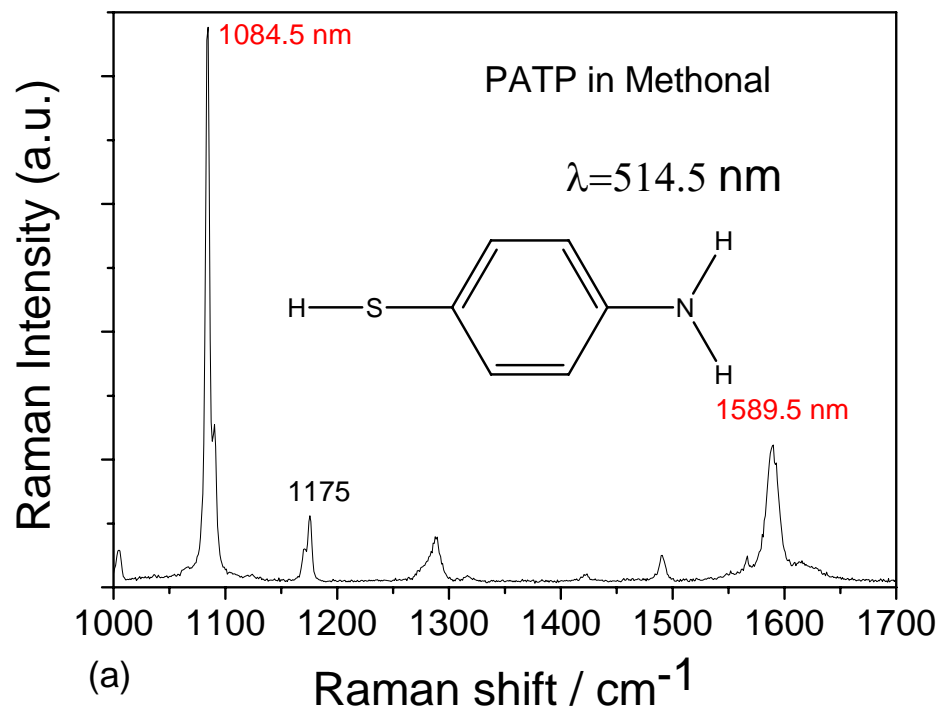
Mag EFM Displayed  
 Spatial location (nm): [0.00, -0.00, 0.00]  
 Cell location: [95, 82, 142][?, 3][?]  
 (0.0 [dB]) MagEFM: 0.654[V/m][5.572e+001[dB]]





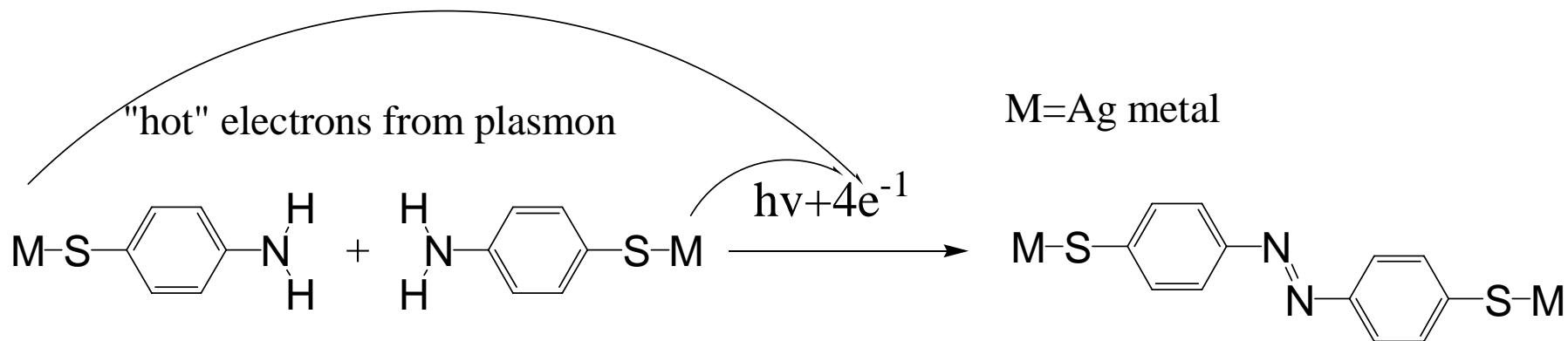
# Plasmon-Assisted Chemical Reactions

# Surface catalyzed reaction of PATP dimerizing to DMAB



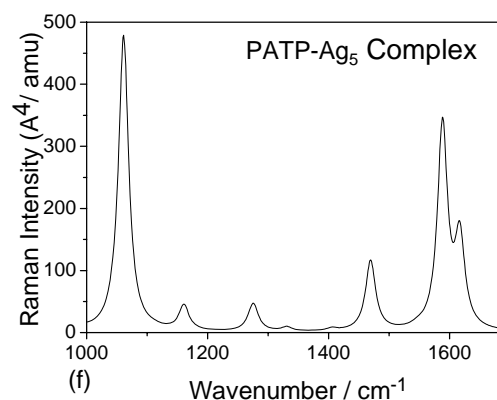
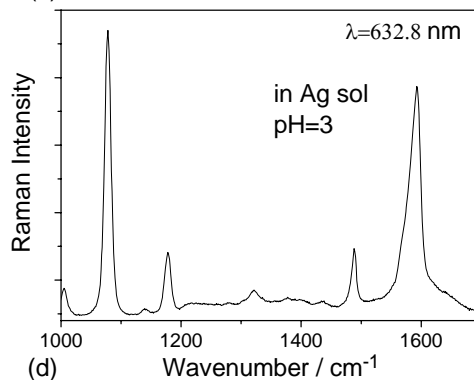
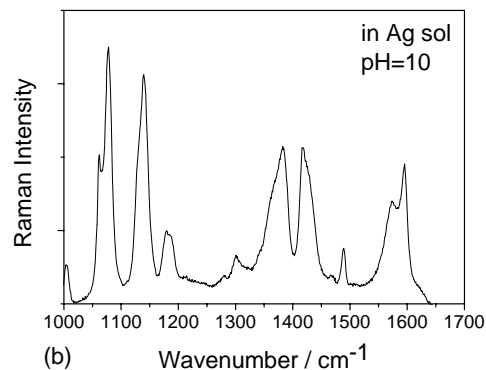
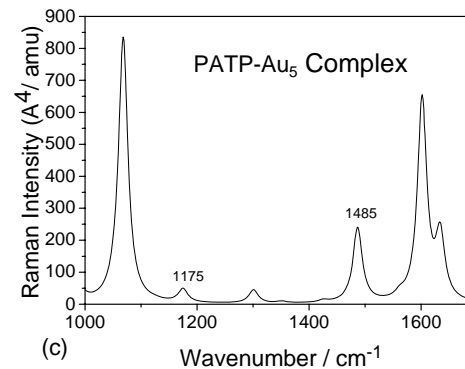
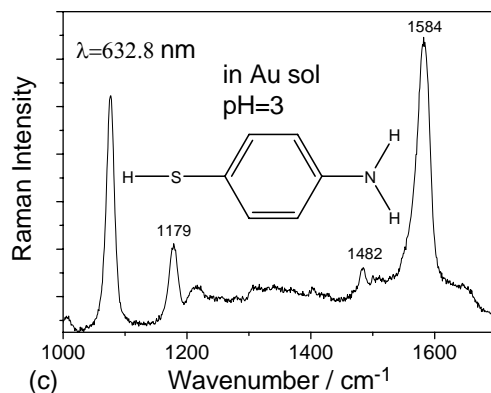
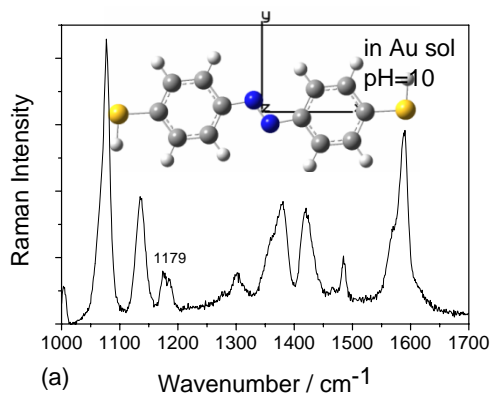
# Mechanism of surface catalyzed reaction

## Hot electrons?



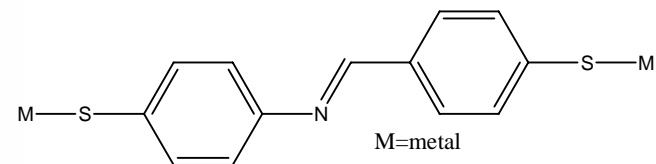
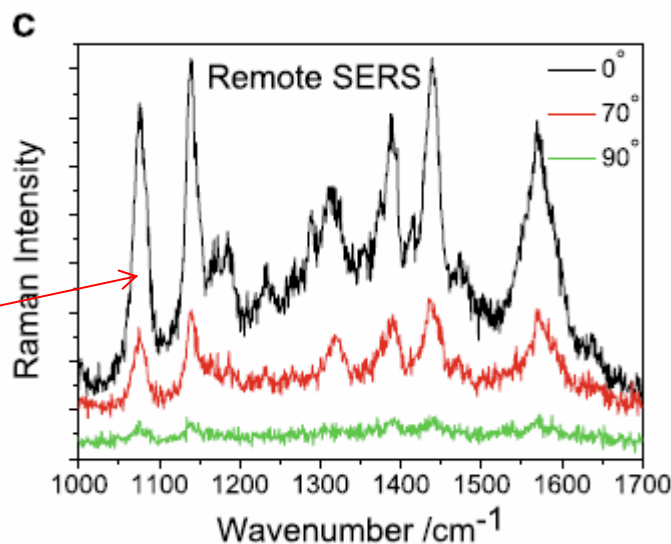
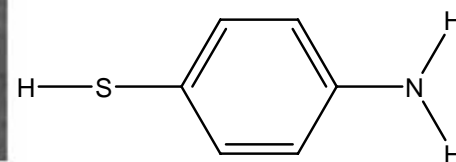
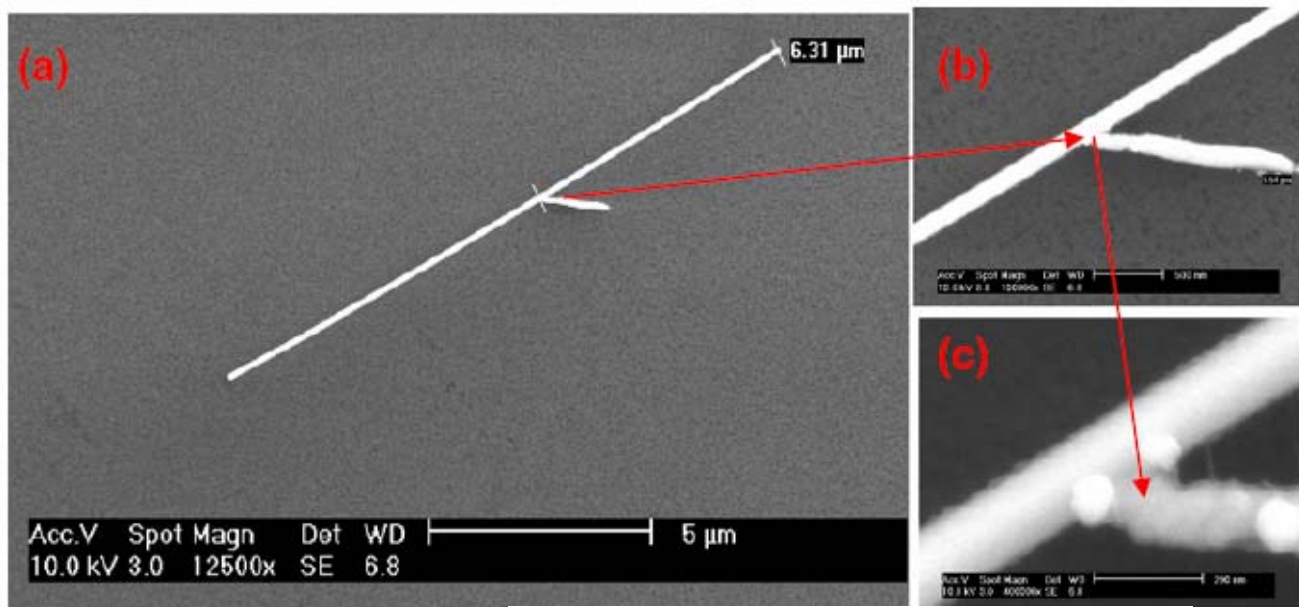
Scheme 1. The mechanism of plasmon-assisted surface catalyzed reaction.

# The pH-controlled plasmon-assisted surface catalyzed reaction

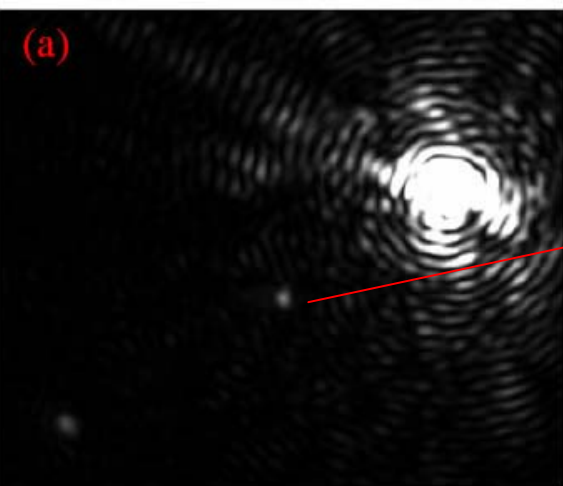


Sun, M. T. and H. X. Xu, *J. Phys. Chem. C*, 2011, 115, 9629.

# Remote-excitation surface catalyzed reaction by plasmonic waveguide

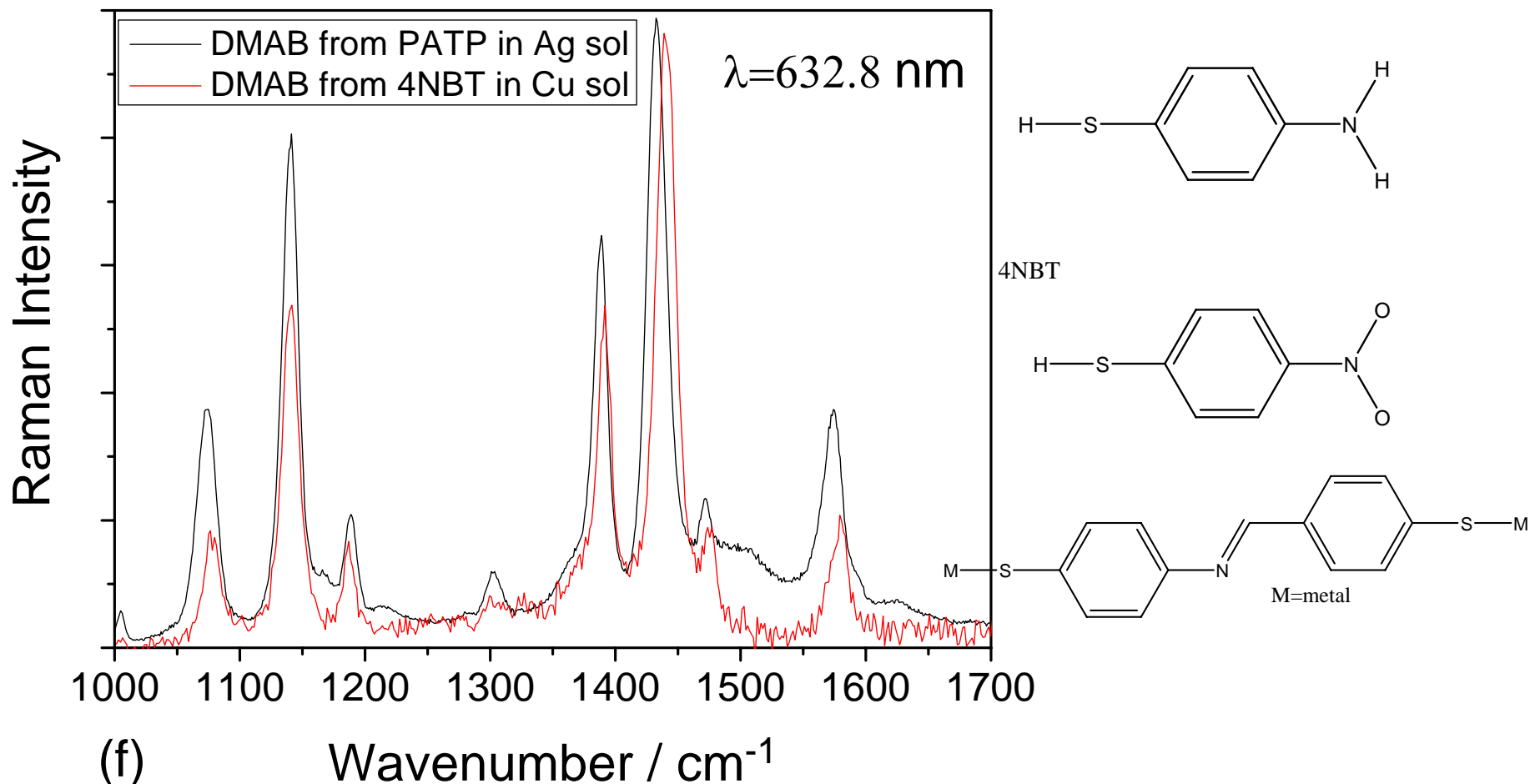


Plasmonics, 6, 681 (2011)

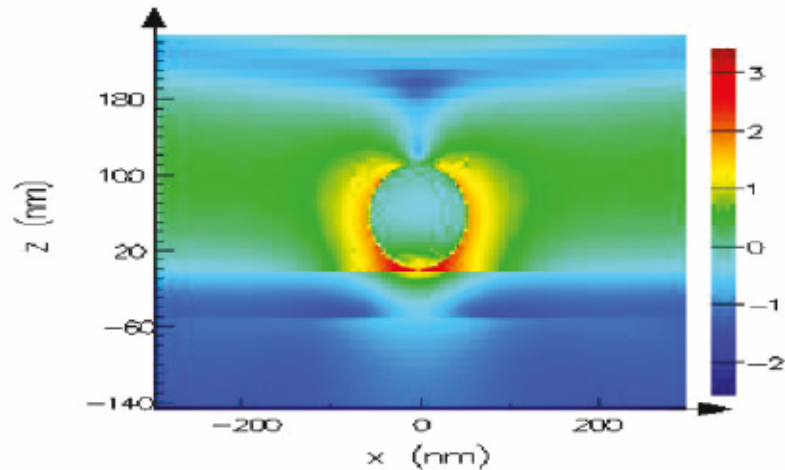
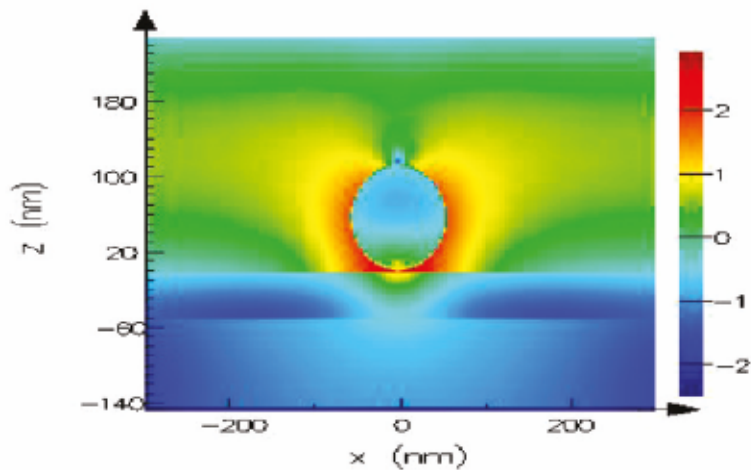
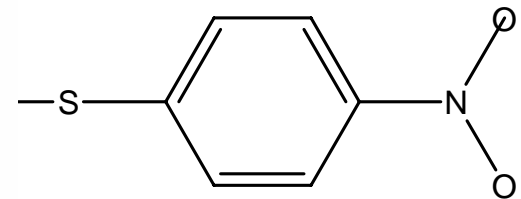
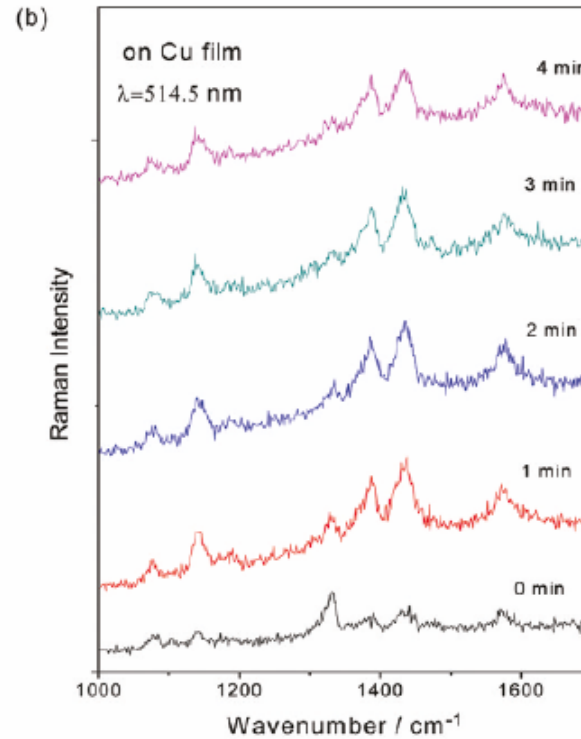
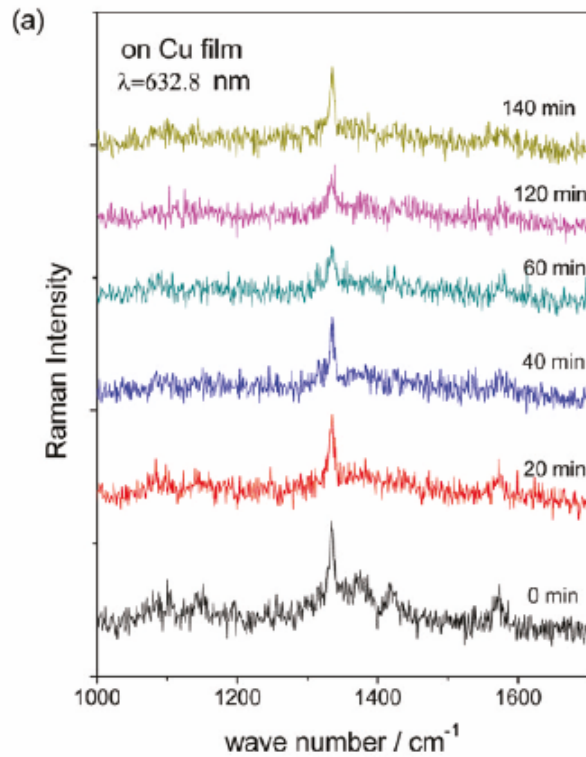




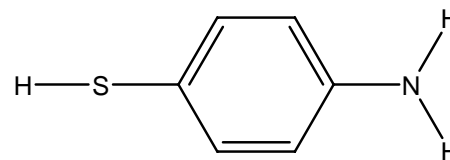
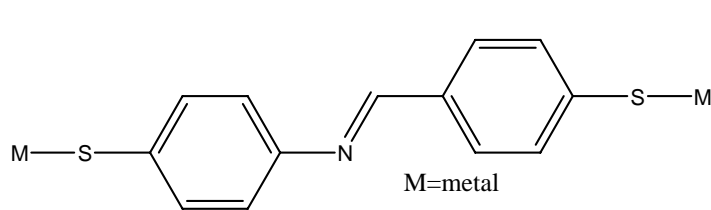
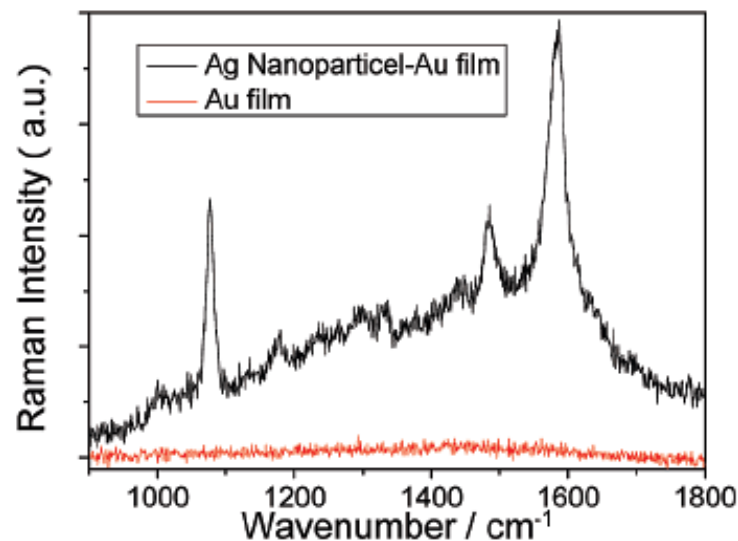
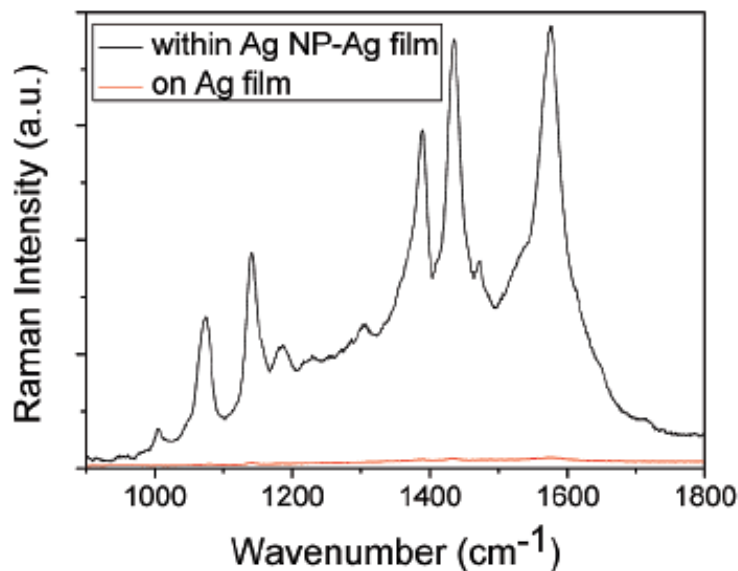
# surface catalyzed reaction of 4NBT dimerizing to DMAB



# Controlling such chemical reaction



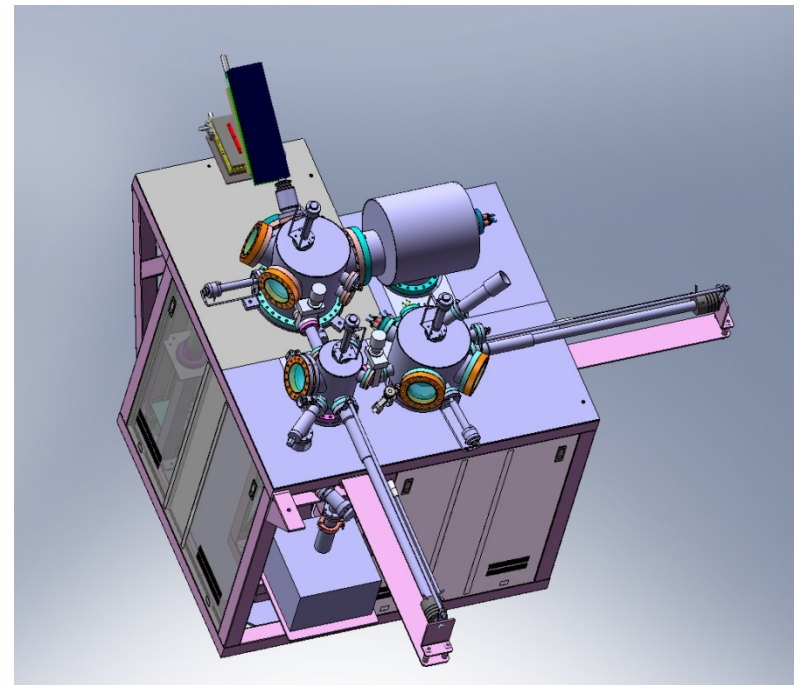
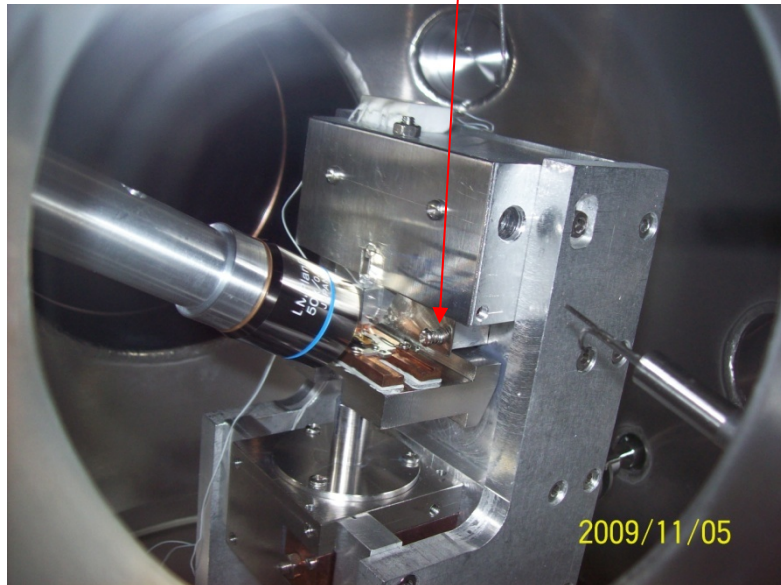
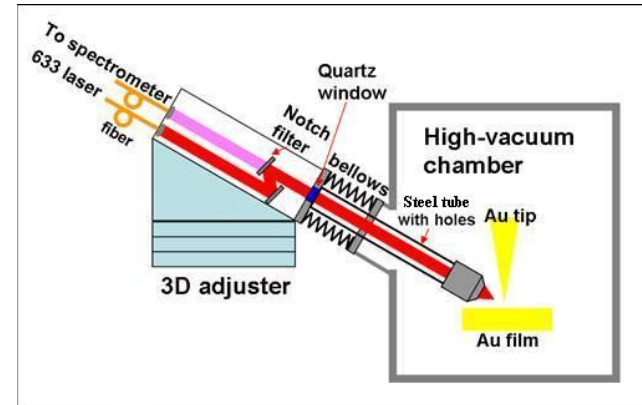
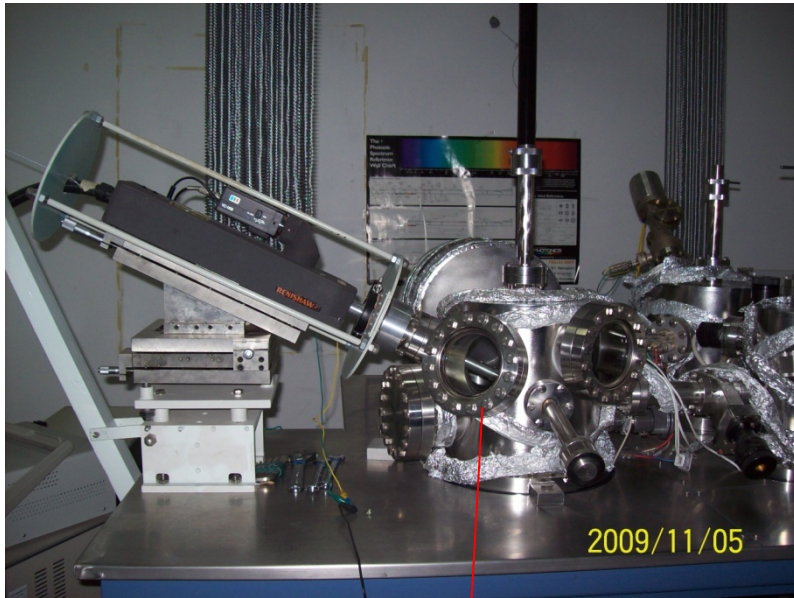
# surface catalyzed reaction in Ag nanoparticle- molecule-Ag/Au films



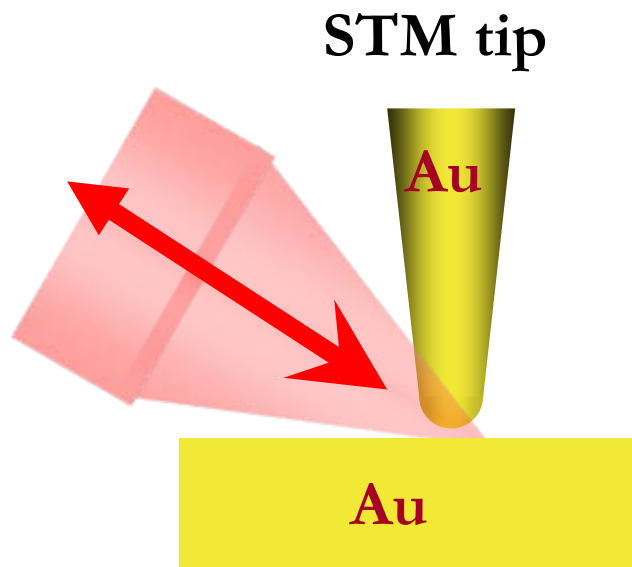
# From Plasmon Chemical Reactions to

## Surface catalyzed reaction on Au film in HV-TERS

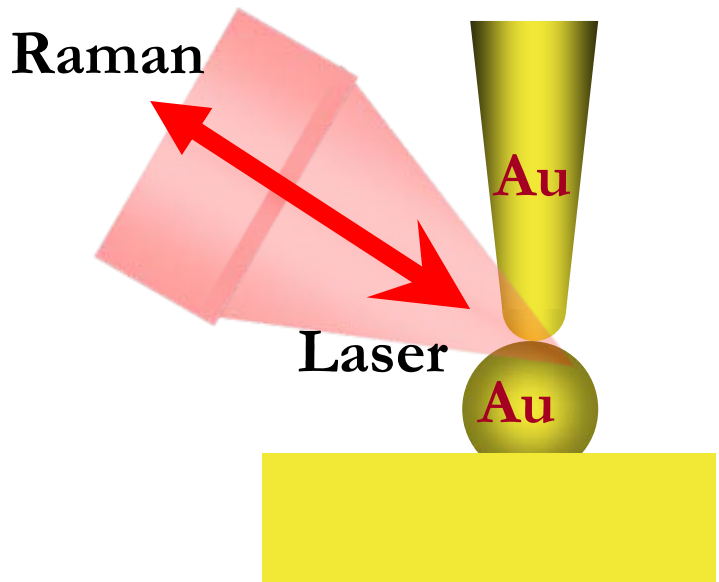
Institute of Physics, CAS



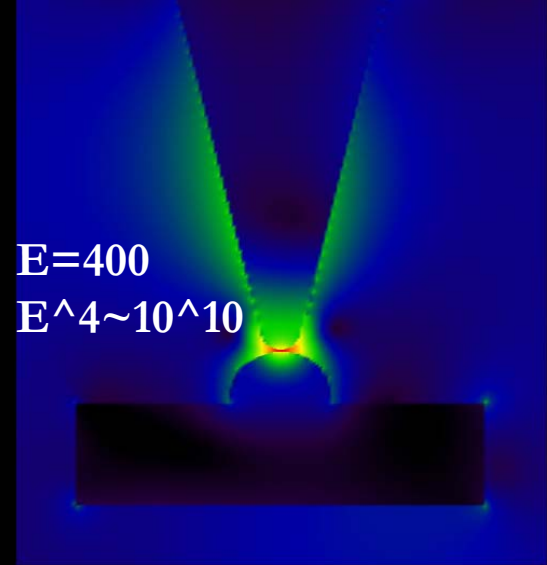
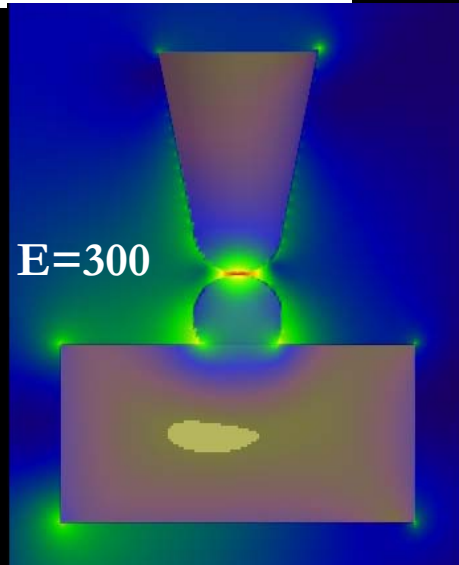
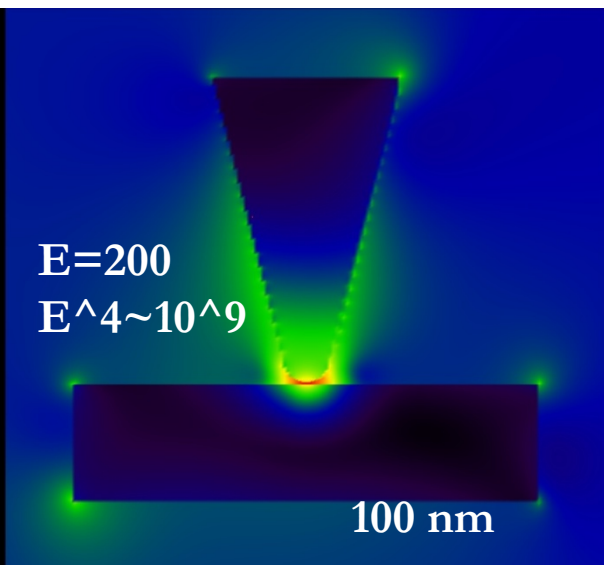




Normal TERS setup



Double-tip TERS setup

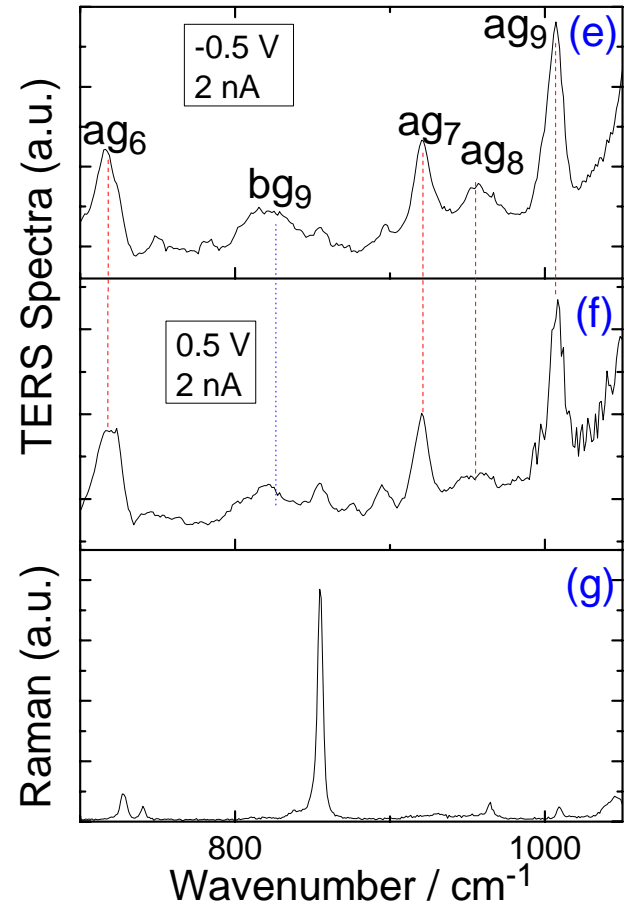
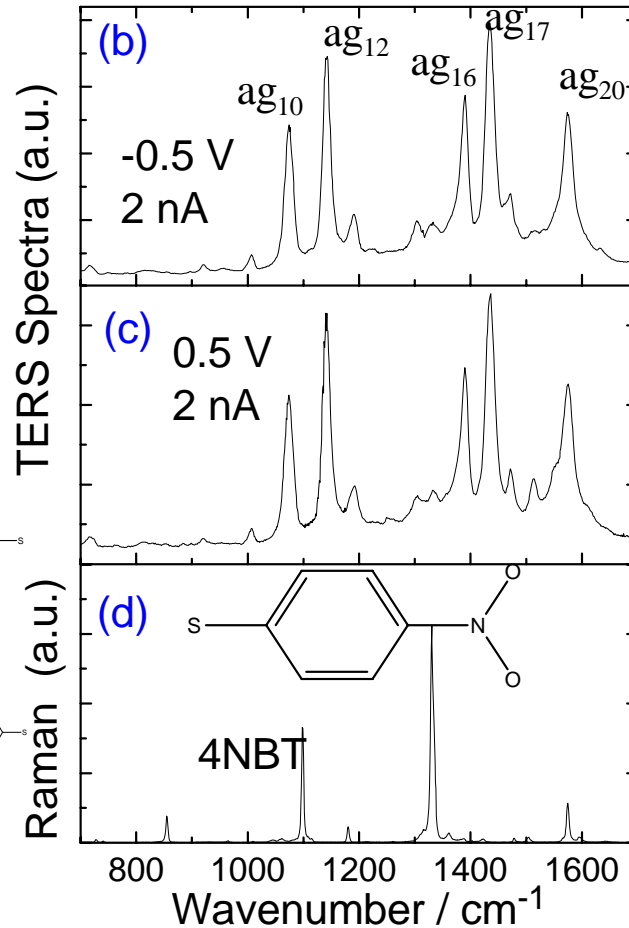
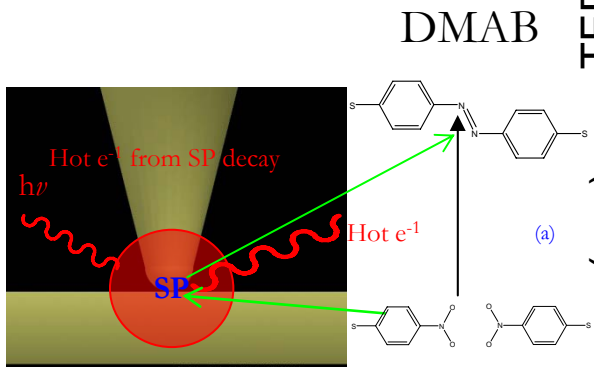


2.063e+002 V/m Mag EFM Displayed  
Spatial location (nm): [0.00, -0.00, 0.00]  
Cell location: [95, 72, 115] [?, -3] [2, -3] [?]  
MagEFM: 0.549[V/m] [-5.150e+001] [dB]

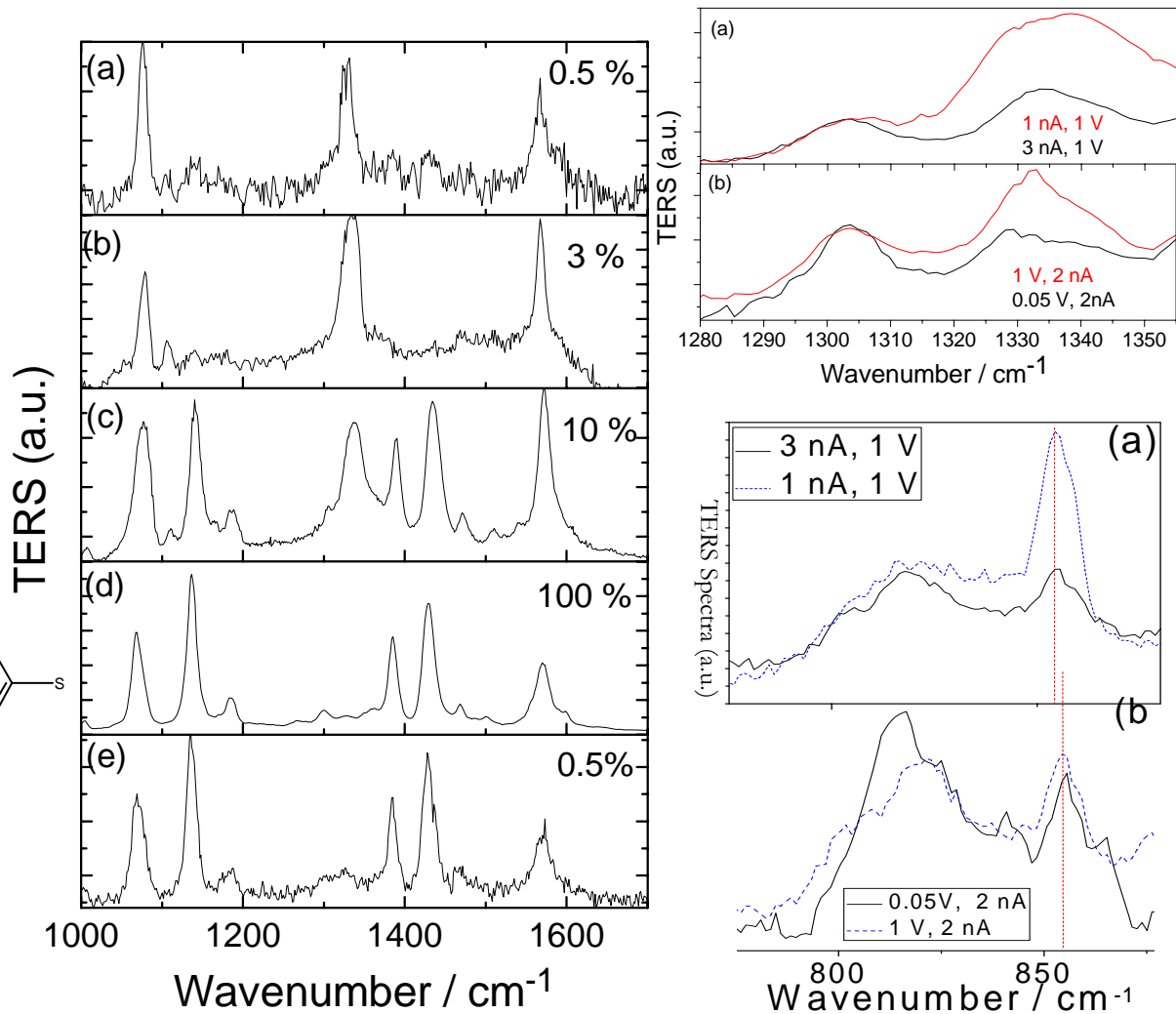
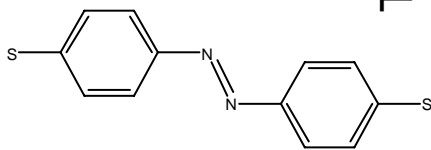
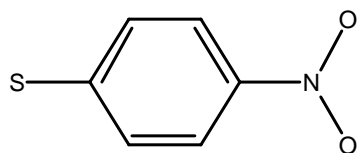
Mag EFM Displayed  
Spatial location (nm): [0.00, -0.00, 0.00]  
Cell location: [95, 82, 142] [?, -3] [?]  
MagEFM: 0.654[V/m] [-5.572e+001] [dB]

# Plasmon-driven chemical reaction on Silver film

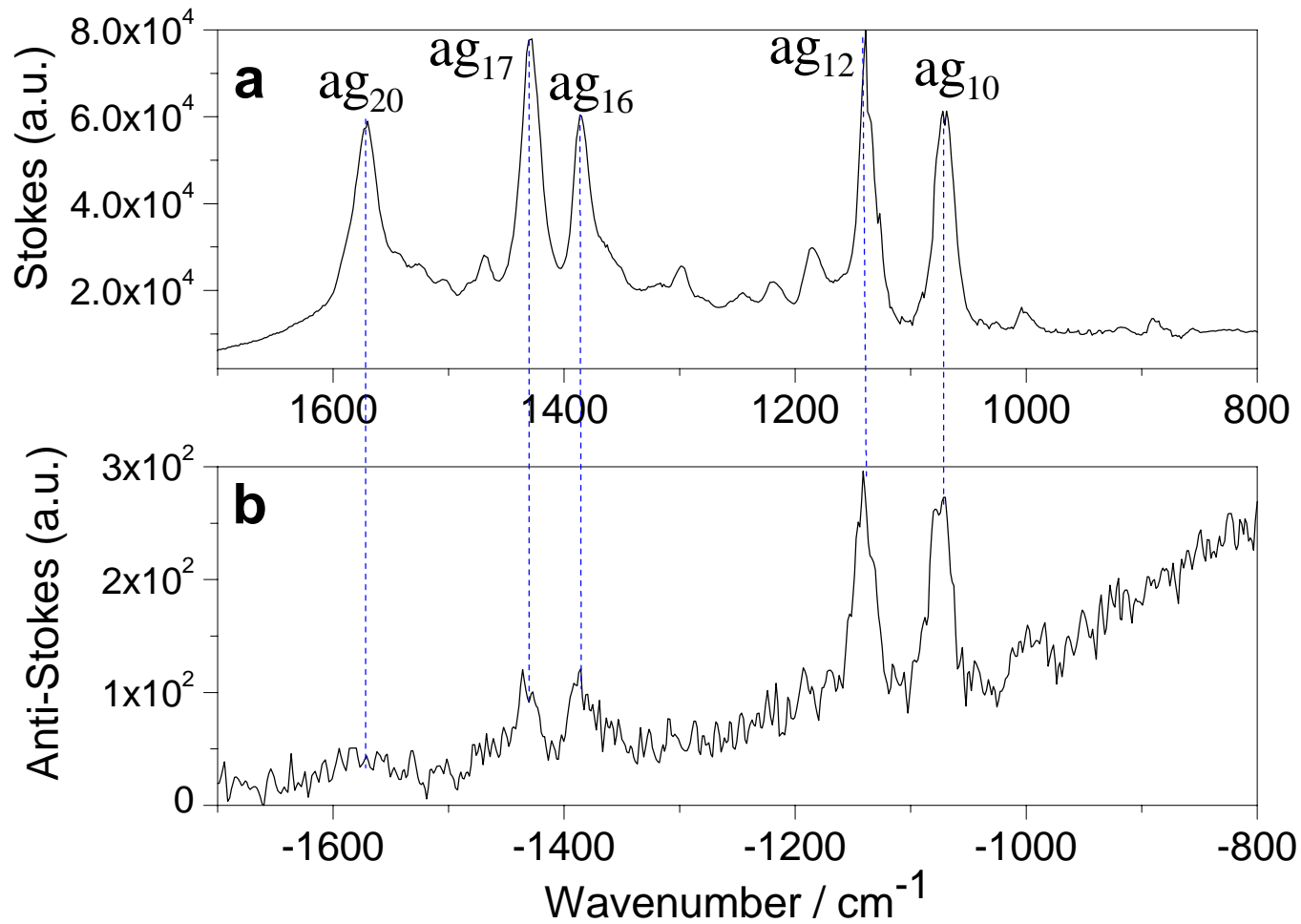
Motivations:  
Capturing “hot” electrons  
in HV-TERS



# Controlled dynamics of chemical reaction

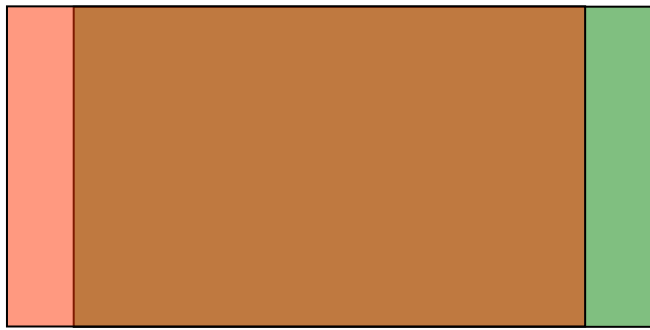




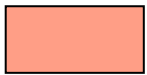


$$I_s / I_{as} = a \times e^{(\eta\omega / k_B T)}$$

$$T \sim 327 \text{ K}$$



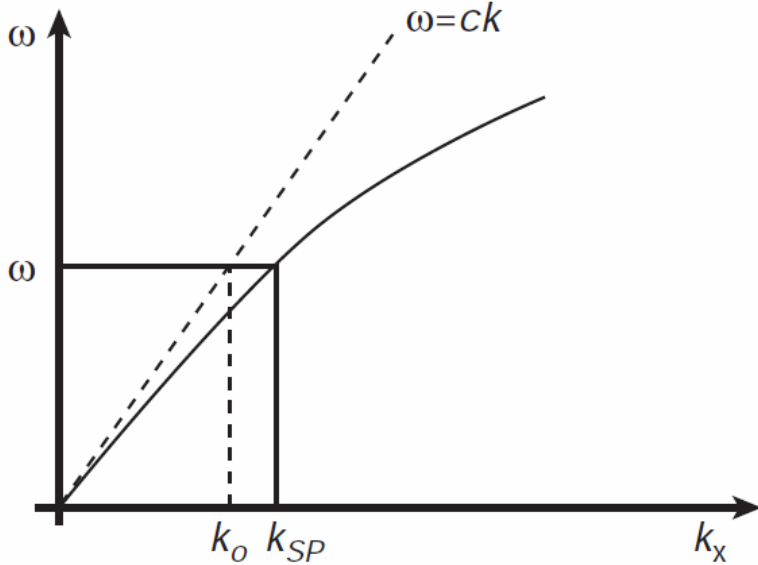
$E(t)$



+

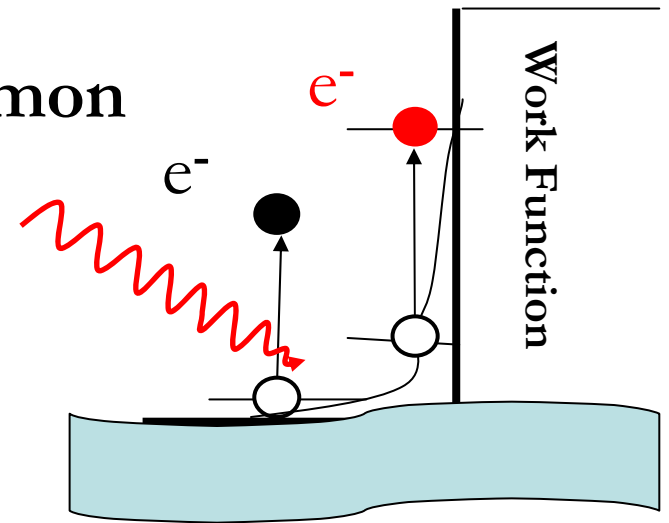


-



**Laser/Plasmon**

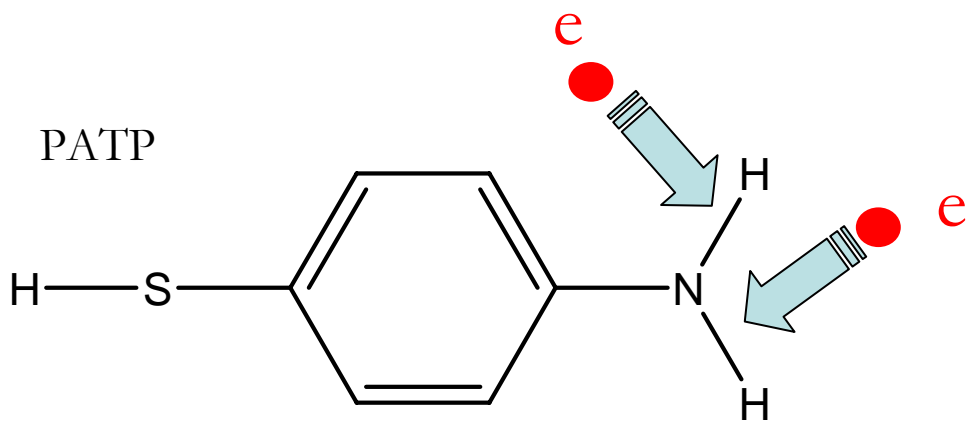
**Hot-electrons**



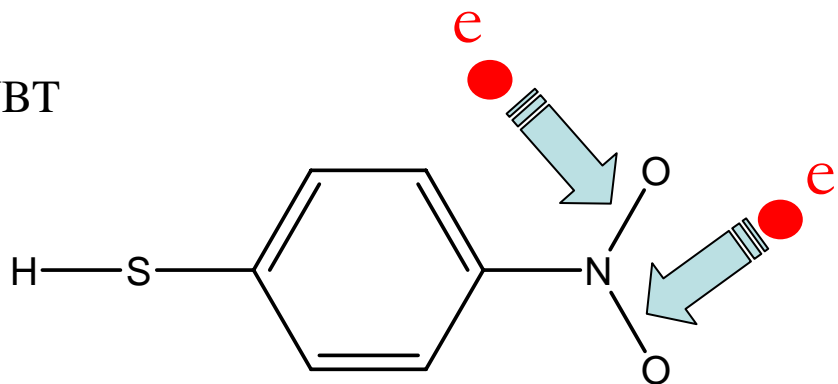
**Plasmon Sea**

$$N_e \propto \exp(E^2) * \exp(E_{\text{photon}}) / \exp(V_{\text{work}})$$

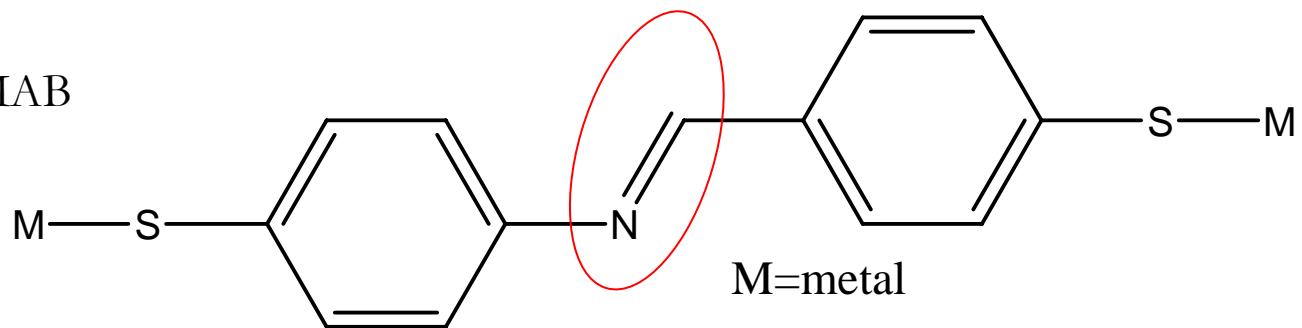
PATP



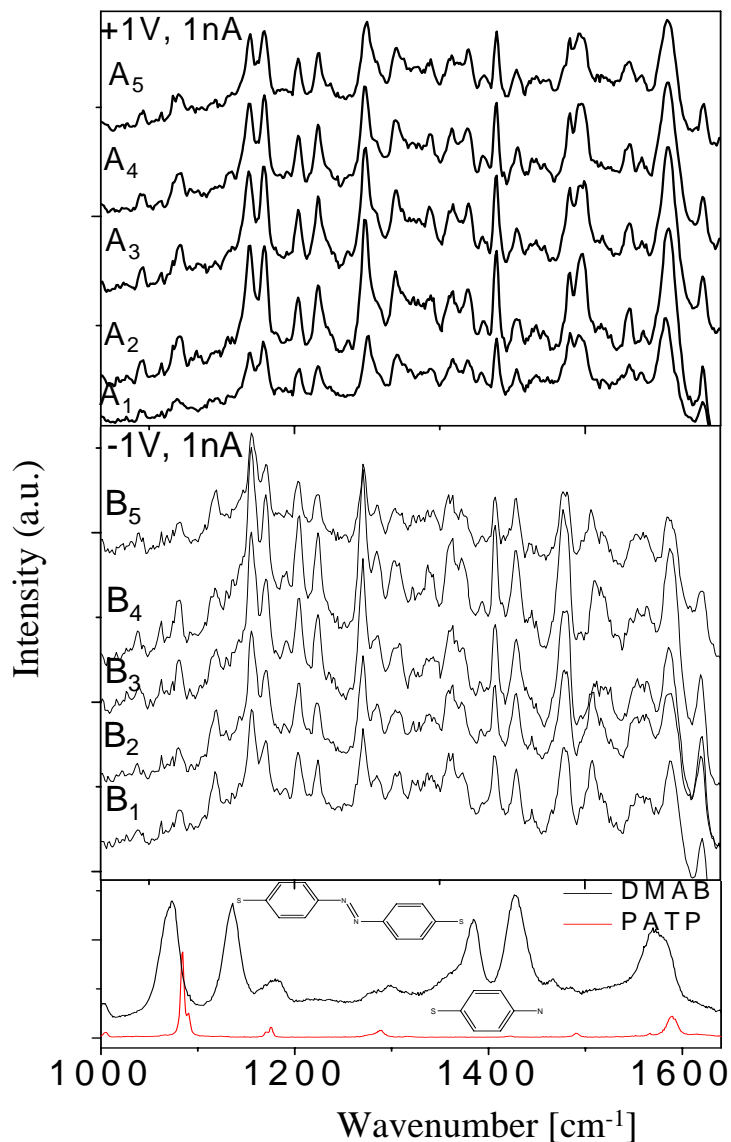
4NBT



DMAB



# More complex chemical reactions on Au film?



Fluctuation is weak

HV-TERS spectra is quite different from SERS spectra of DMAB and NRS spectrum PATP powder

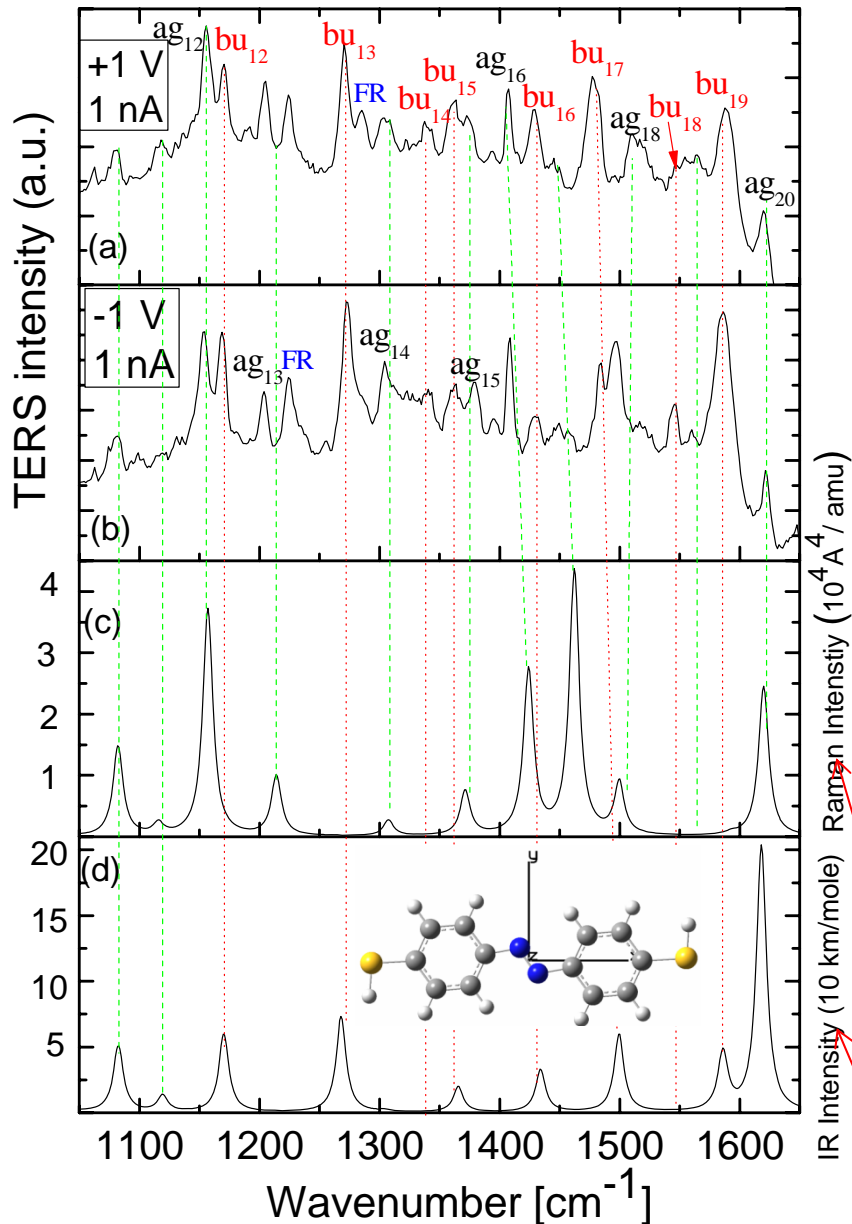
**First conclusion:**

Surface catalyzed reaction occurred on Au film, because above spectra

Why are they different ?

**Produced new molecules (not DMAB)?**

# Assignment of HV-TERS spectra



- (a) and (b) HV-TERS spectra of DMAB
- (c) Simulated Raman spectra
- (d) Simulated IR spectra of DMAB.

VOLUME 85, NUMBER 19

PHYSICAL REVIEW LETTERS

6 NOVEMBER 2000

## Electric Field Gradient Effects in Raman Spectroscopy

E. J. Ayars and H. D. Hallen

*Physics Department, North Carolina State University, Raleigh, North Carolina 27695-8202*

C. L. Jahncke

*Physics Department, St. Lawrence University, Canton, New York 13617*

(Received 15 February 2000)

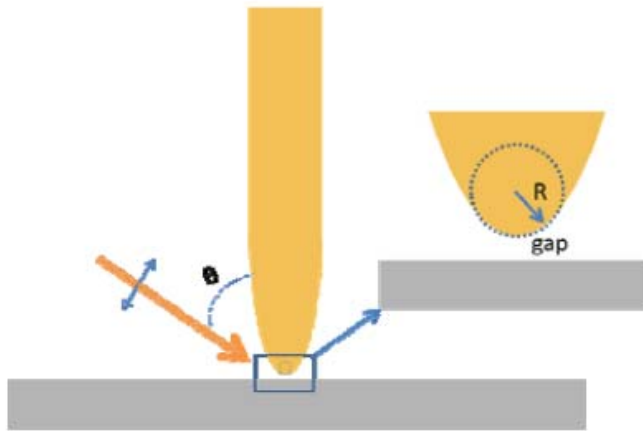
Raman spectra of materials subject to strong electric field gradients, such as those present near a metal surface, can show significantly altered selection rules. We describe a new mechanism by which the field gradients can produce Raman-like lines. We develop a theoretical model for this "gradient-field Raman" effect, discuss selection rules, and compare to other mechanisms that produce Raman-like lines in the presence of strong field gradients. The mechanism can explain the origin and intensity of some Raman modes observed in SERS and through a near-field optical microscope (NSOM-Raman).

PACS numbers: 78.30.-j, 33.20.Fb, 78.66.Vs, 82.80.Ch

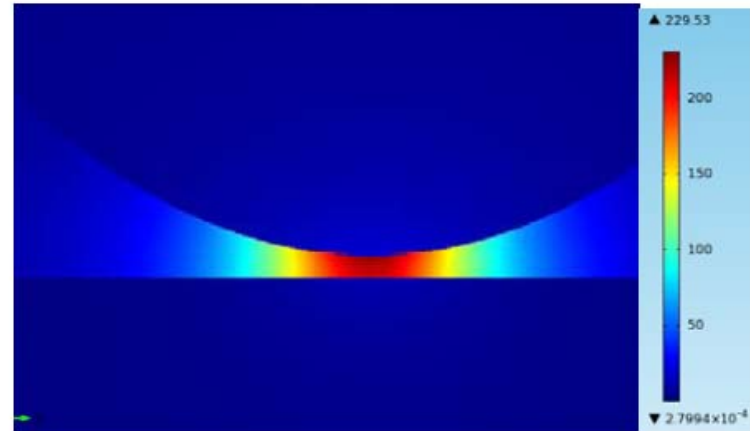
It was theoretically predicted that Raman-active and IR active modes could be observed simultaneously due to the enhanced electric field gradient effect in the nanocavity between tip and surface.

Our HV-TERS spectra realized their theoretical prediction 10 years ago

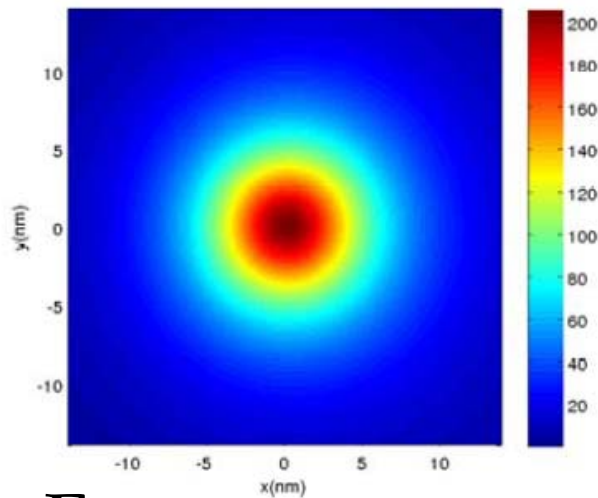
# Electric field intensity and gradient



(a)

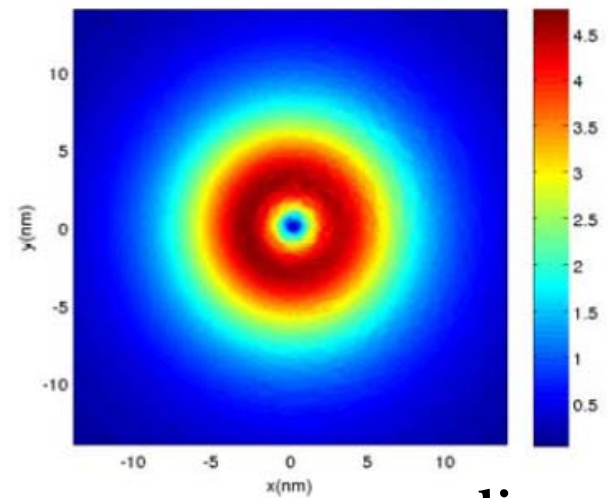


(b)



$E_z$

(c)



gradient

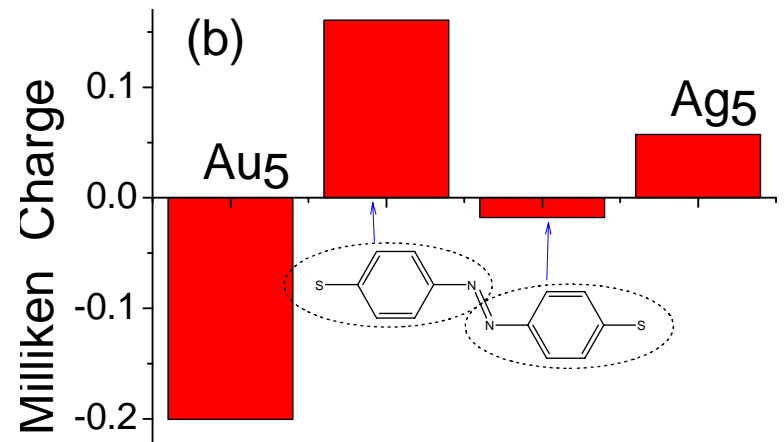
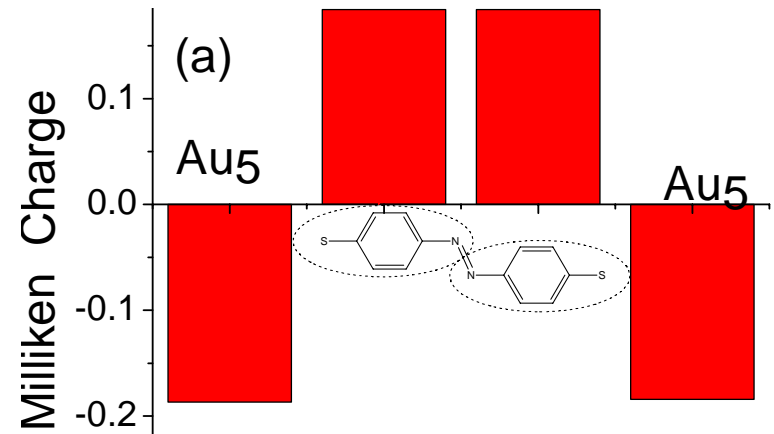
(d)

# Electric field gradient effect

$$\mu_\alpha = \alpha_{\alpha\beta} E_\beta + \frac{1}{3} A_{\alpha\beta\gamma} \frac{\partial E_\beta}{\partial r} + \Lambda$$

$$\alpha_{\alpha\beta} = \sum_j H(\omega) (\langle i | \mu_\alpha | j \rangle \langle j | \mu_\beta | f \rangle) / \eta.$$

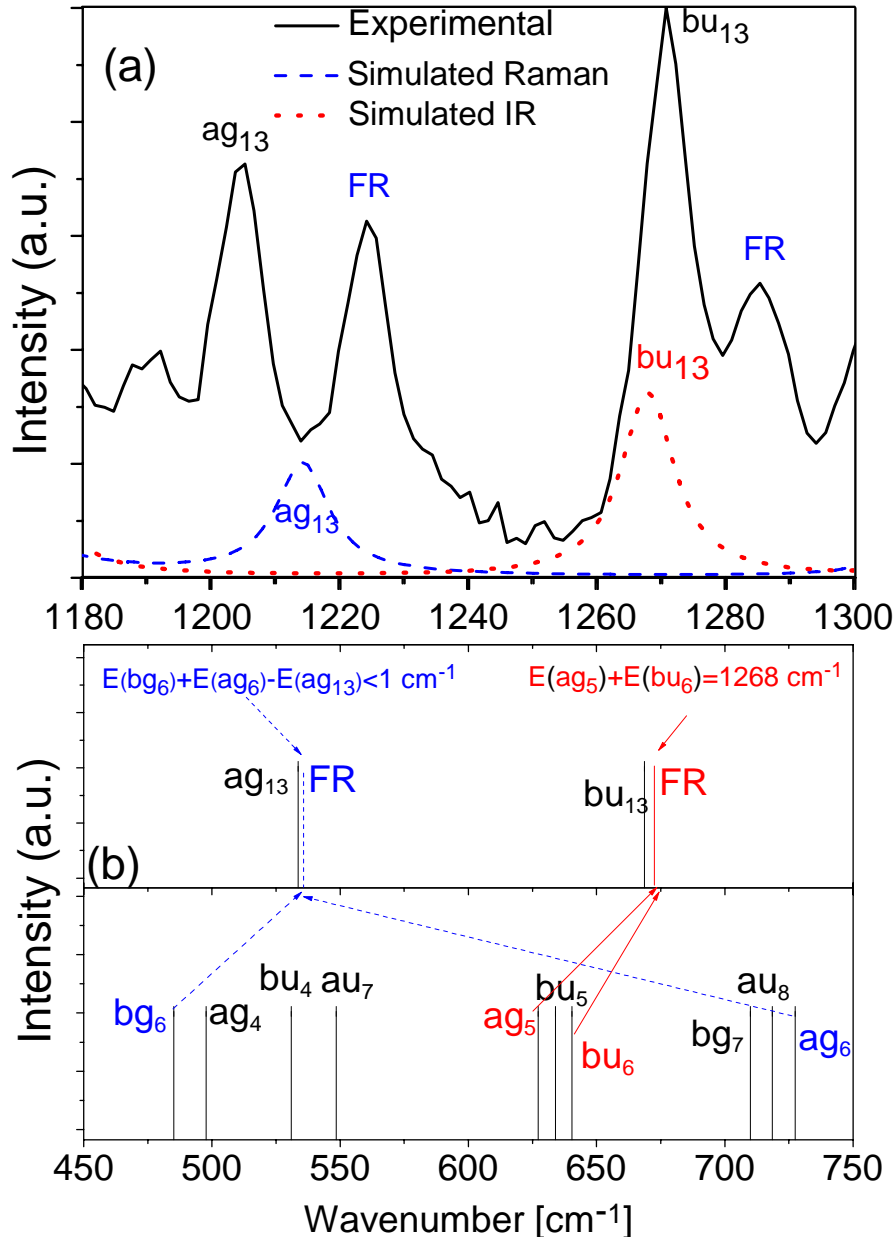
$$A_{\alpha\beta\gamma} = \sum_j H(\omega) (\langle i | \mu_\alpha | j \rangle \langle j | \theta_{\beta\gamma} | f \rangle) / \eta$$







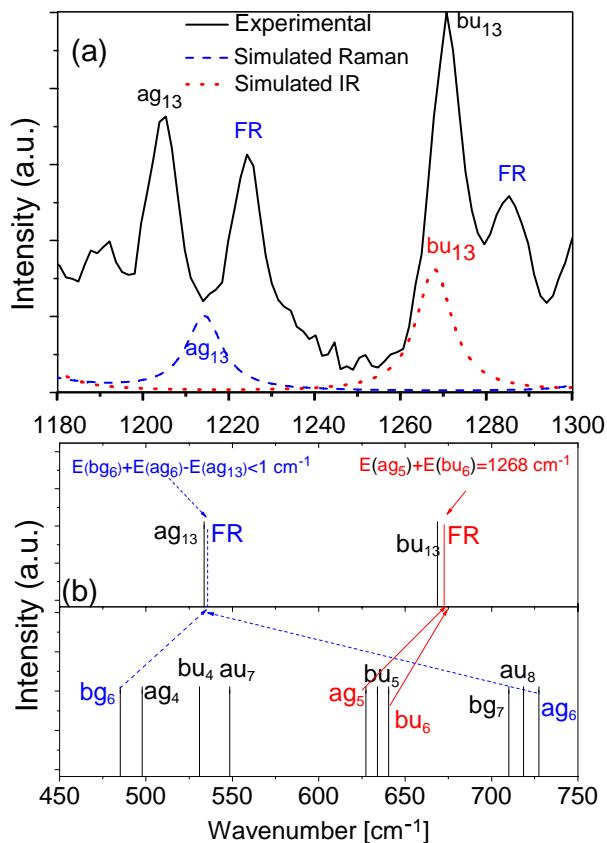
# Fermi Resonance



Fermi resonances:  
**overtone or a combination modes** appearing in the vibrational spectra by gaining intensity from a fundamental mode.

E. Fermi, Z. Phys. **71**, 250 (1931).

# Fermi Resonance



$$E_A = \frac{E_+ + E_-}{2} + \frac{E_+ - E_-}{2} \times \frac{I_+ - I_-}{I_+ + I_-}$$

$$E_B = \frac{E_+ + E_-}{2} - \frac{E_+ - E_-}{2} \times \frac{I_+ - I_-}{I_+ + I_-},$$

$$E_{\pm} = \frac{1}{2}(E_A + E_B) \pm \frac{1}{2}\sqrt{(E_A - E_B)^2 + 4\phi^2}$$

$\phi$  is the FR coupling coefficient

$$\phi(ag_{13}) = \frac{1}{2} \Delta E_{\pm}(ag_{13}) = 10.2 \text{ cm}^{-1}$$

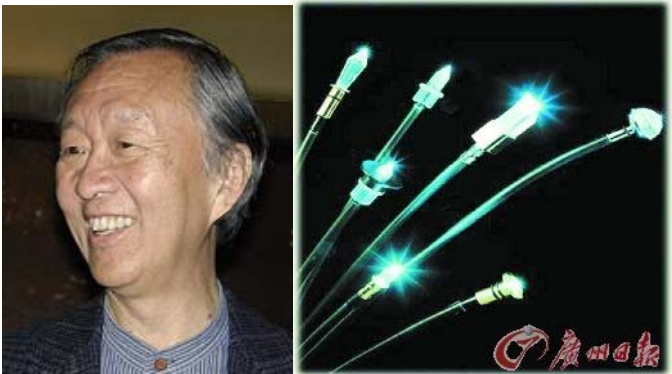
$$\phi = \frac{\sqrt{2}}{3} \Delta E_{\pm}(bu_{13}) = 6.88 \text{ cm}^{-1}$$

(a) The experimentally observed Fermi resonance and simulated IRKS spectra of DMAB for Raman-active symmetric  $ag_{13}$  and IR-active asymmetric  $bu_{13}$  modes. (b) The calculated vibrational modes and the combinational modes for Fermi resonance.

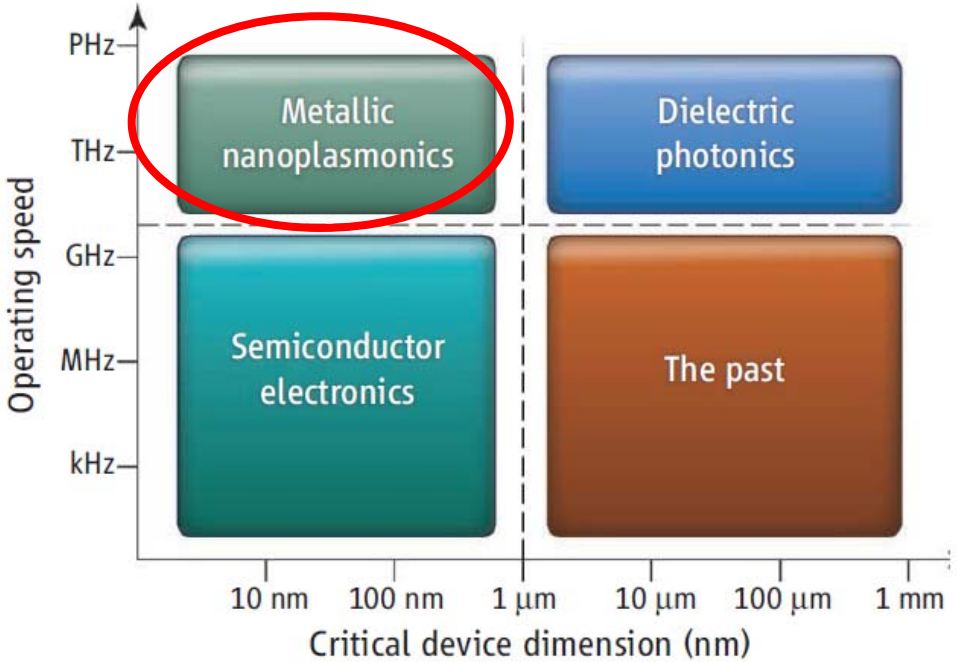
## **2.Nanophotonic Circuits**

### **纳米光芯片**

# Propagating Surface Plasmons: to build plasmonic circuits



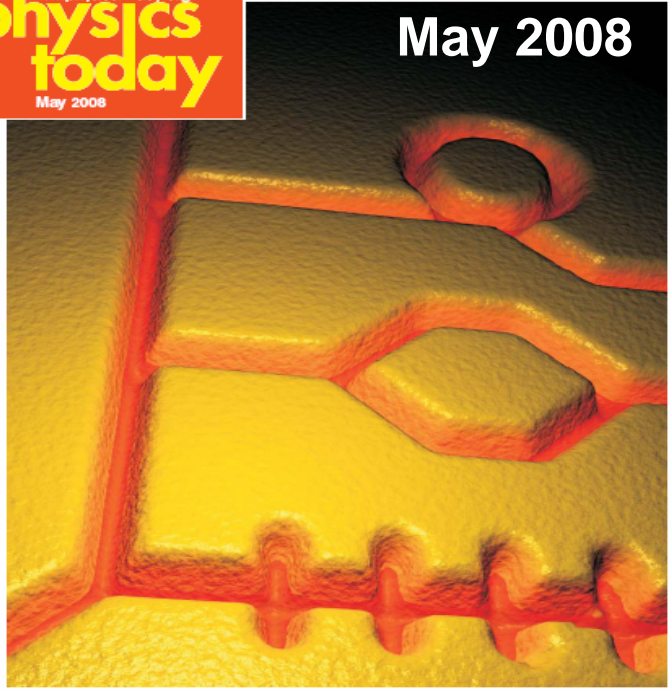
**Nobel Prize in Physics 2009—K Kurogi: "for groundbreaking achievements concerning the transmission of light in fibers for optical communication"**



Science 328, 440 (2010)



May 2008



**Surface-plasmon circuitry**



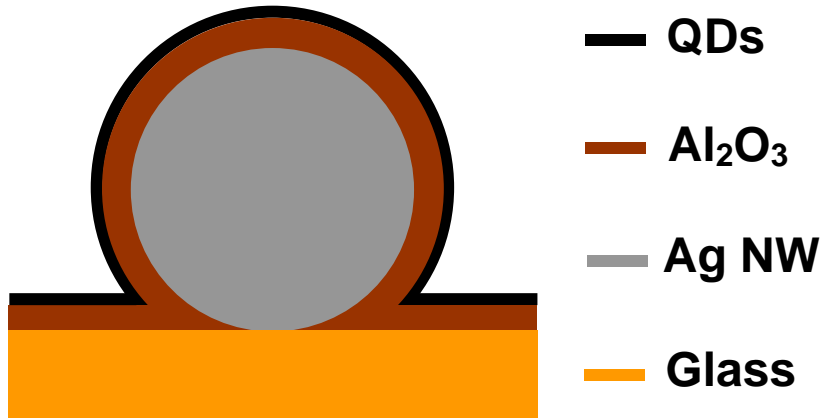
# Outline

- Near-field, Network and Logic
- Wire plasmon modes/Chiral wire plasmons
- Tunable wire plasmons
- Substrate-Mediated Plasmon
- Plasmon Amplification

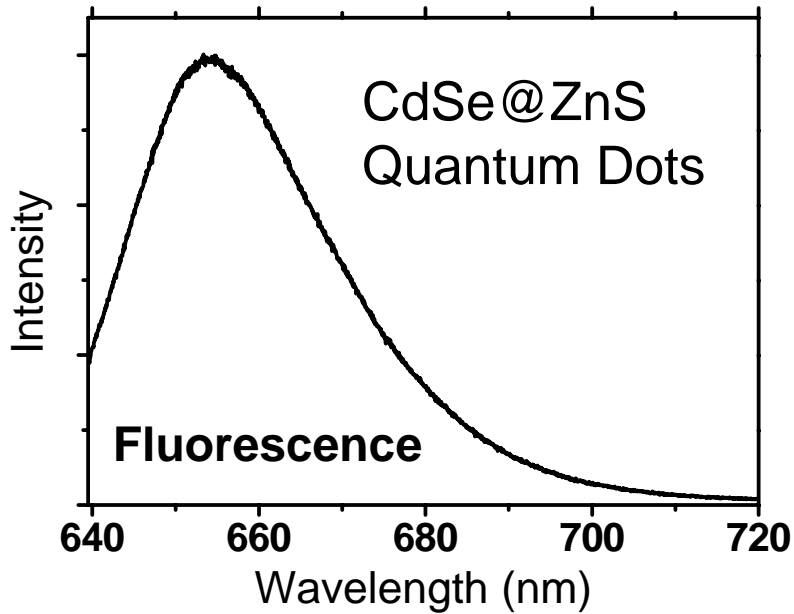
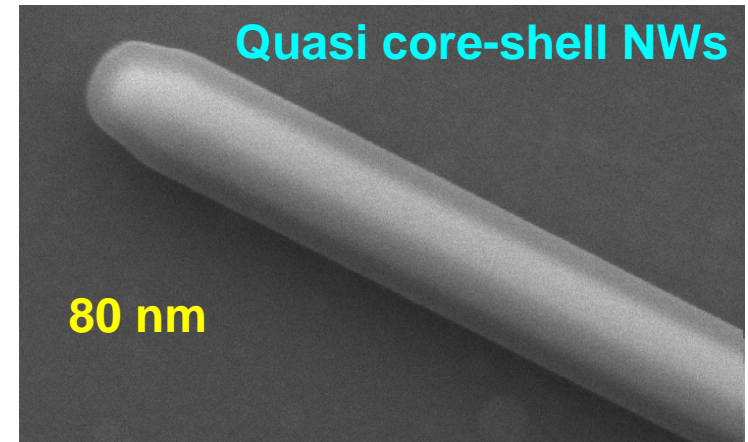
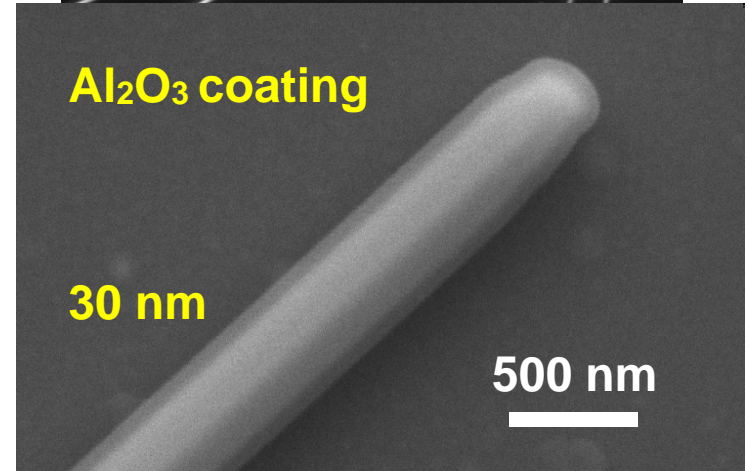
# Outline

- **Near-field, Network and Logic**
- Wire plasmon modes/Chiral wire plasmons
- Tunable wire plasmons
- Substrate-Mediated Plasmon
- Plasmon Amplification

# Sample Structure



Atomic Layer Deposition (ALD)

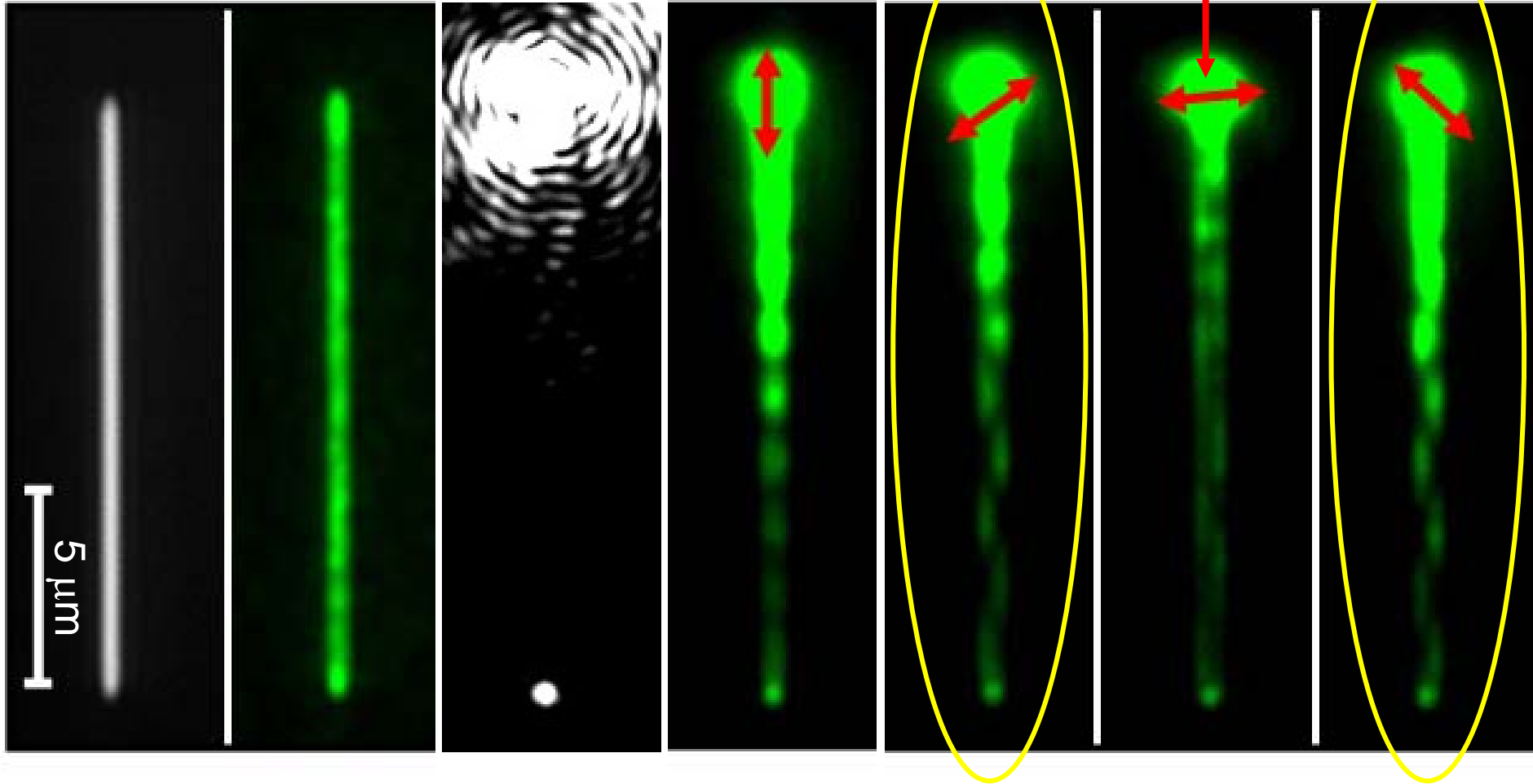


# Quantum dot fluorescence imaging the near-field distribution

Wide field  
excitation

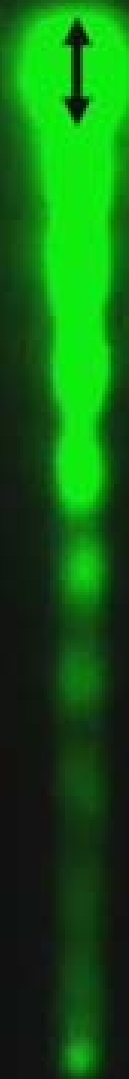
End  
excitation

Polarization



QD fluorescence images the near field of SPP.

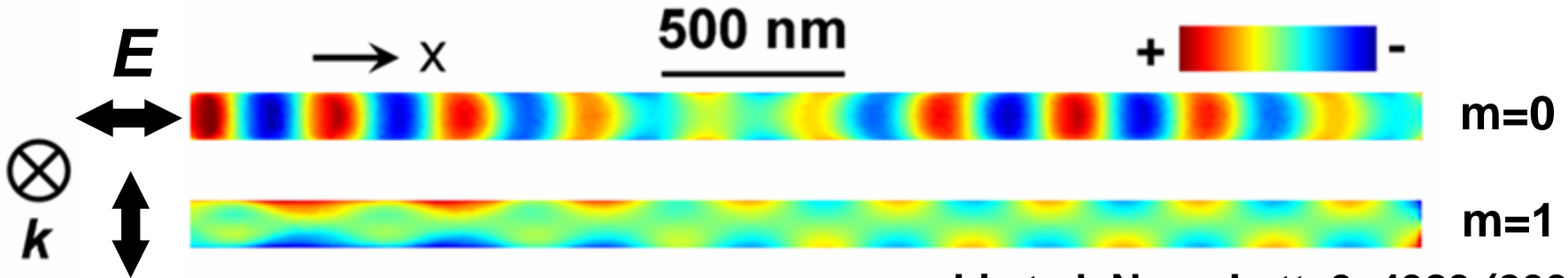
Increasing the polarization angle shifts the local field from one side to the other.



Hongxing Xu Lab, CAS

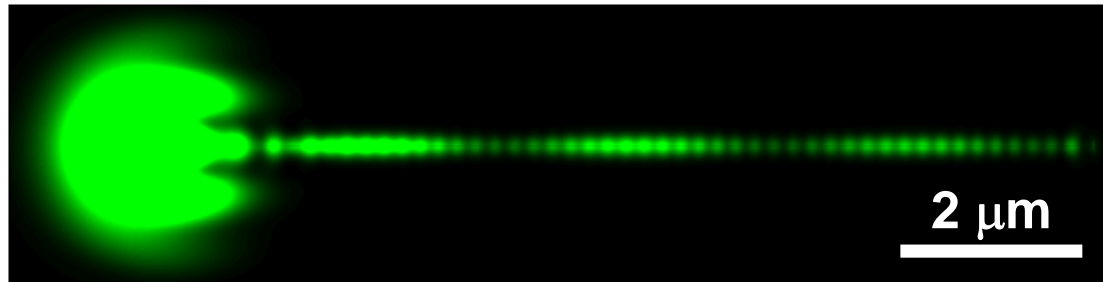


# Origin of plasmon nodes in Ag NW waveguide

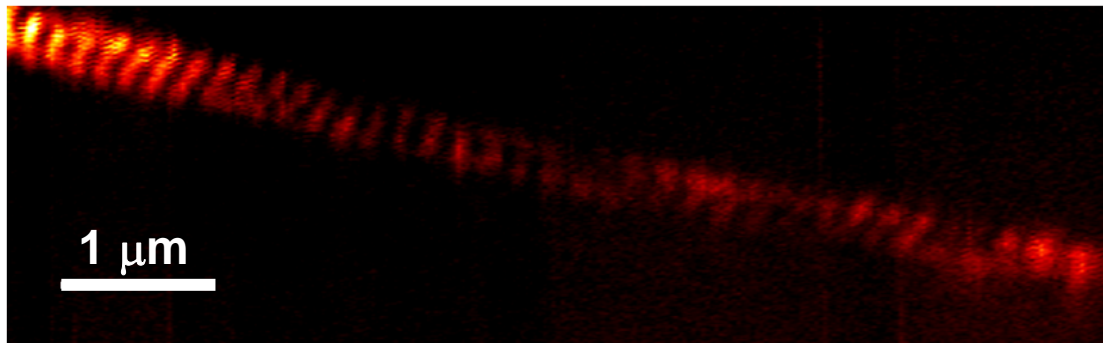


Li et al. Nano Lett. 9, 4383 (2009)

Interference of  $m=0$  and  $m=1$  plasmon modes result in large period near field modulation

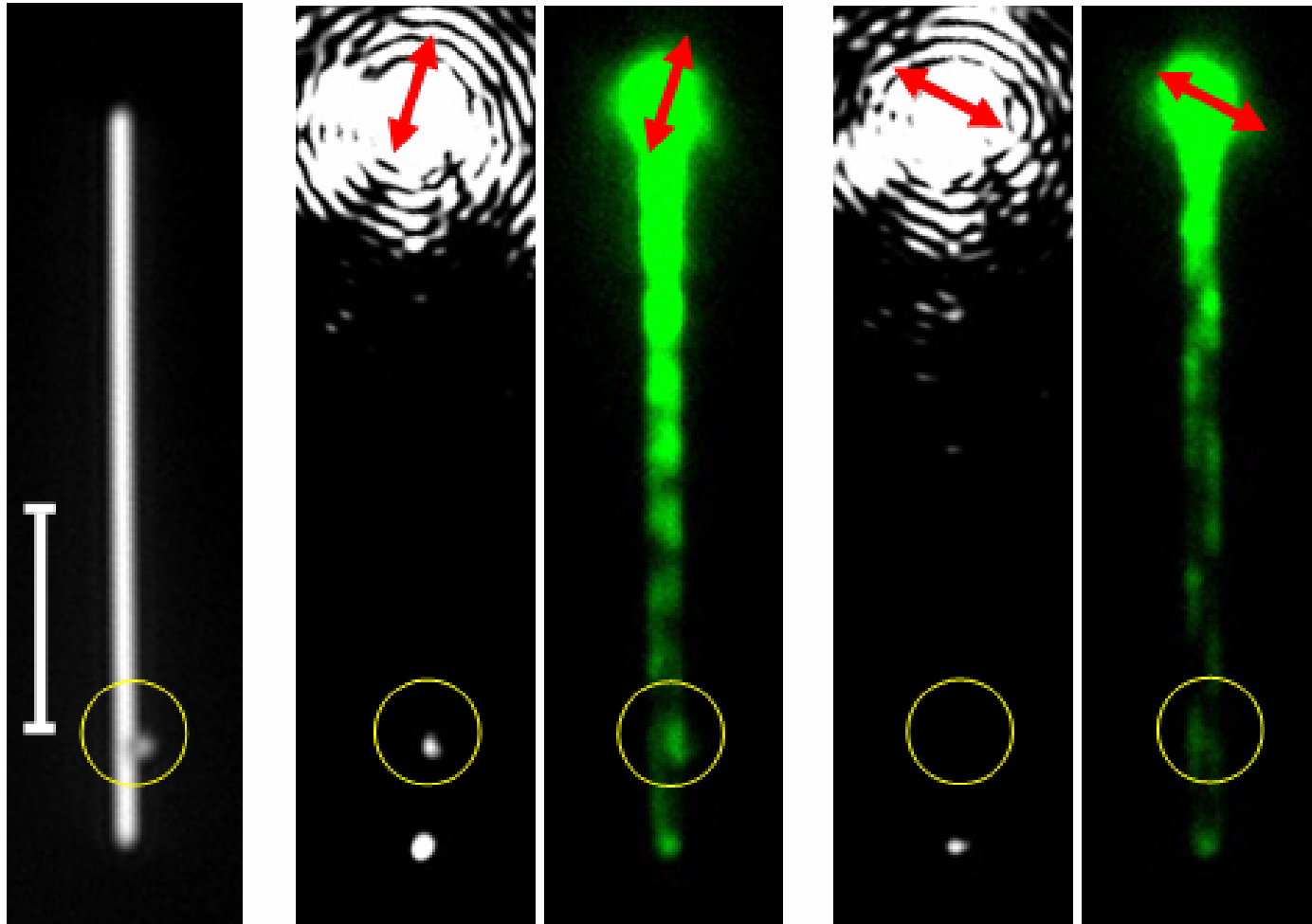


FDTD simulated  
E field intensity



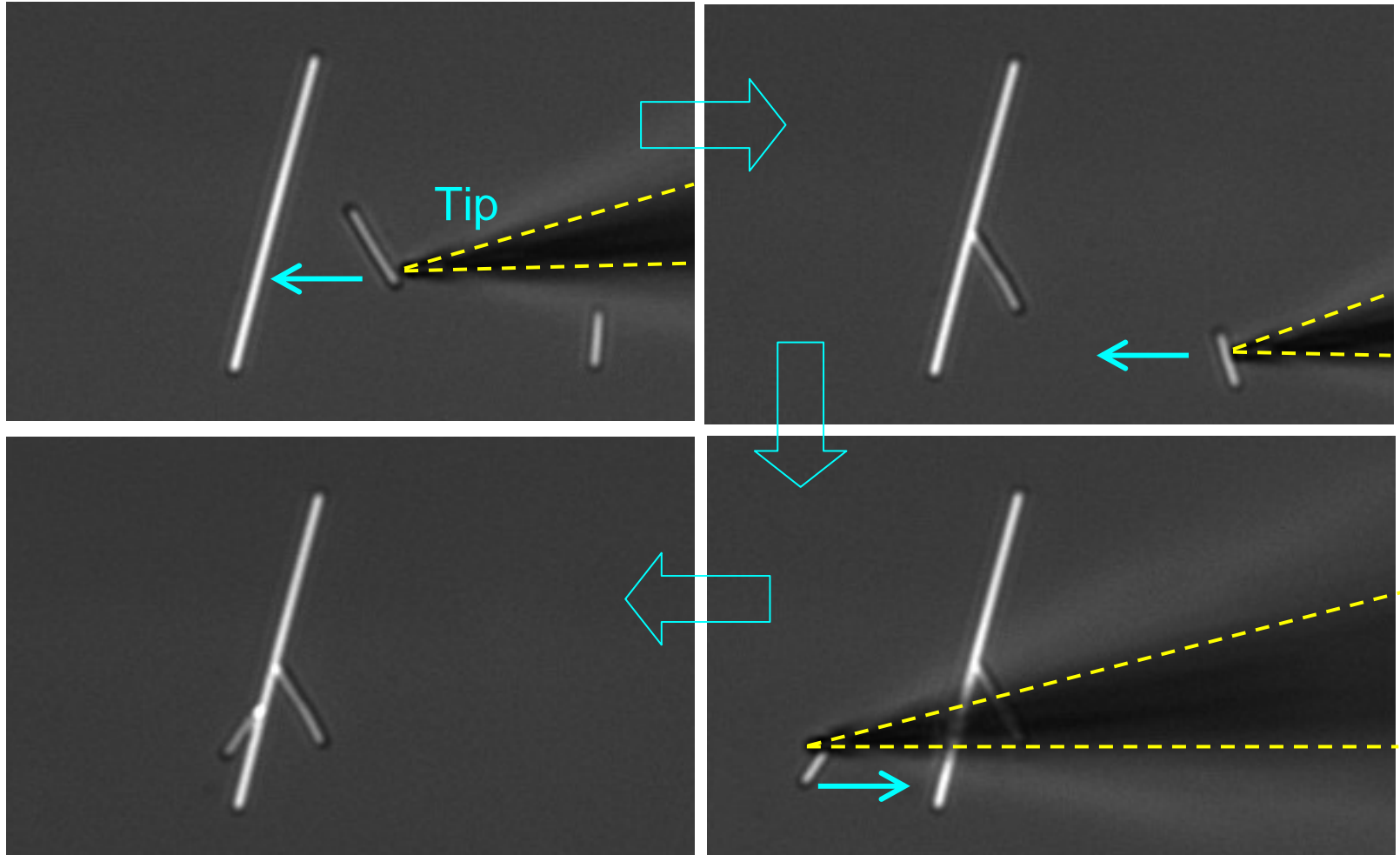
SNOM image

# Controlling scattering intensity by tuning near-field distribution

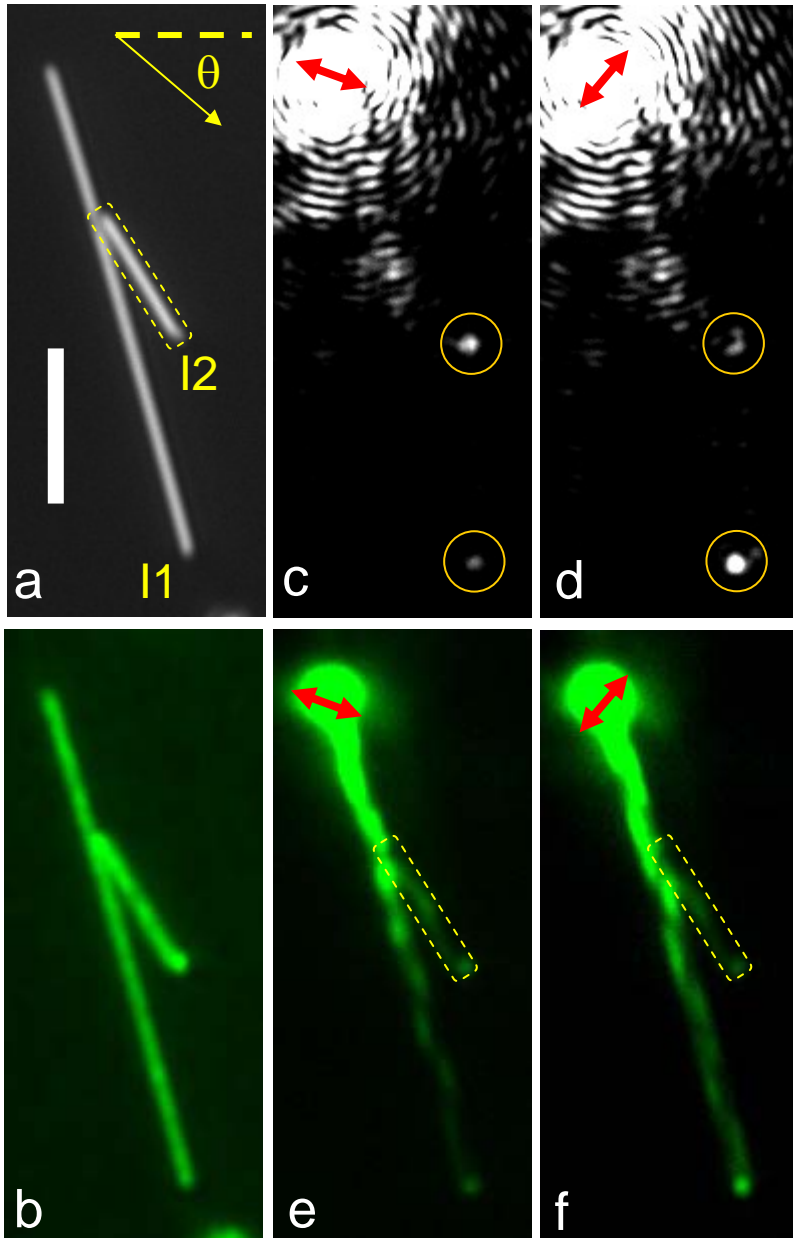


When the near-field intensity is large in the junction, plasmons can be efficiently transferred to connected structure.

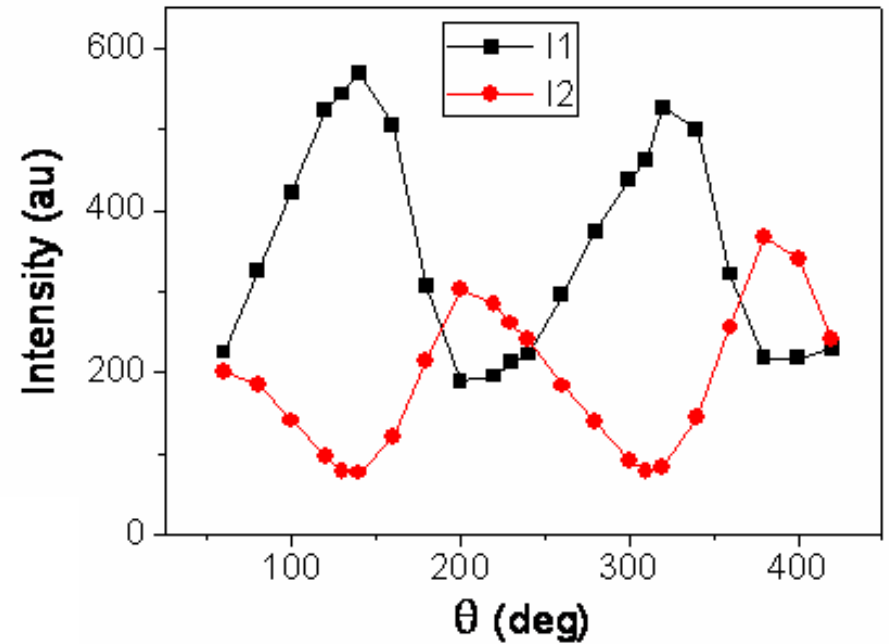
# Assembly of nanowire networks with a micromanipulator



# Plasmon Router/Splitter

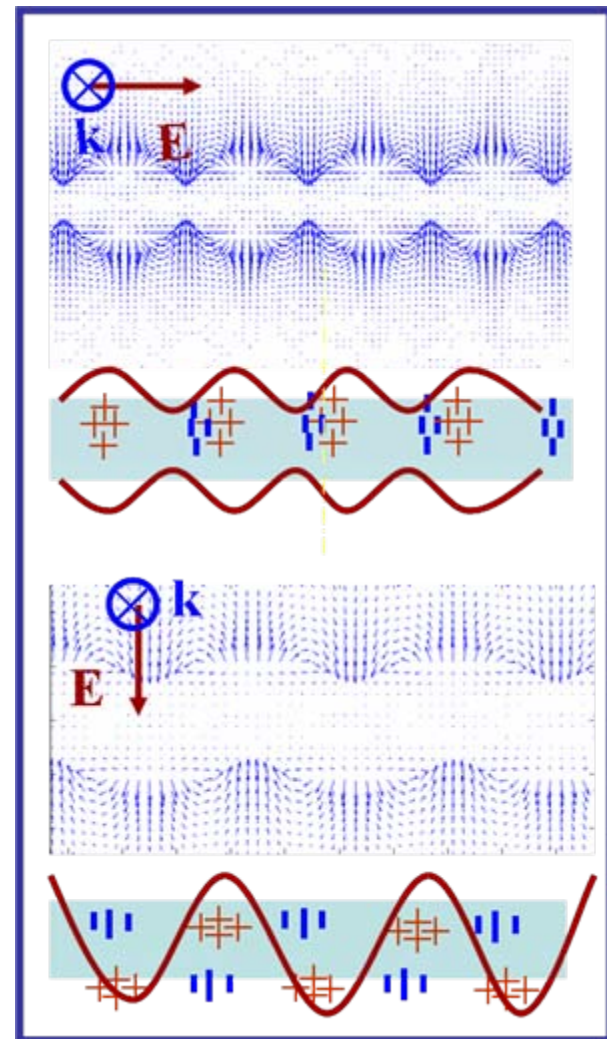
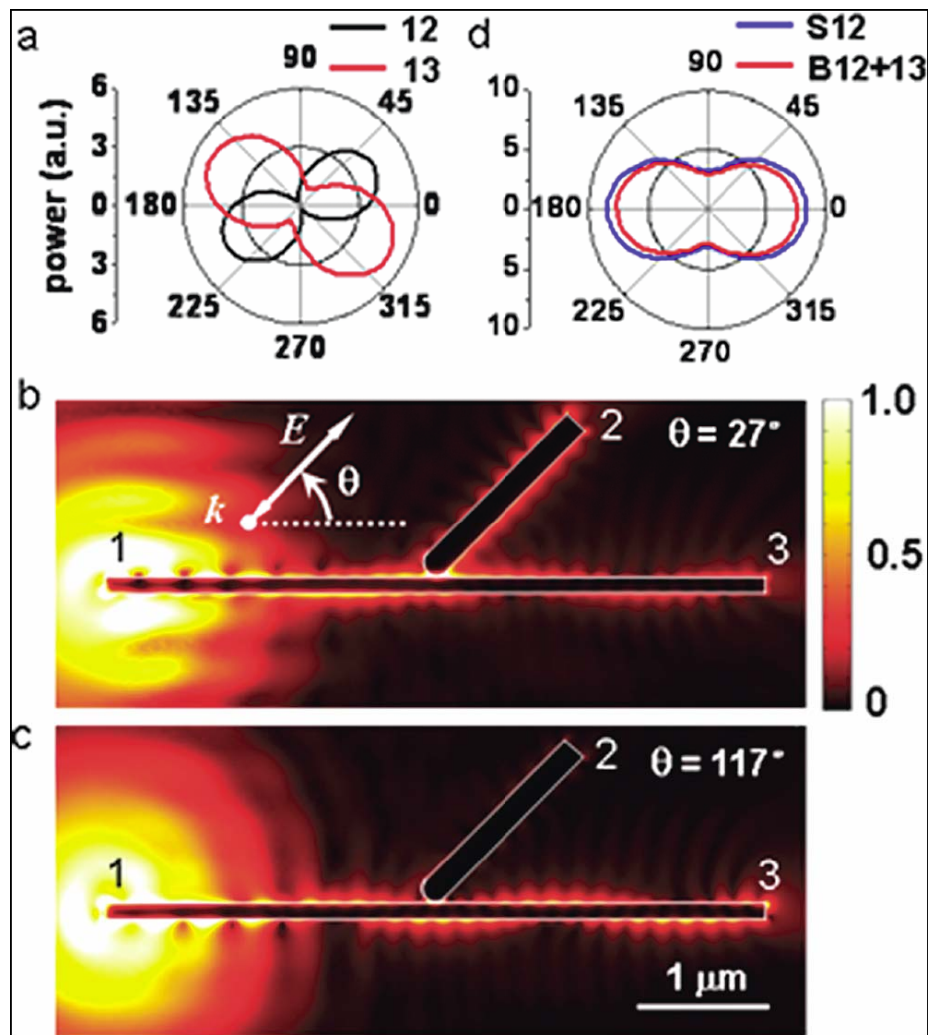


Output intensity as function of incident polarization angles I1 and I2



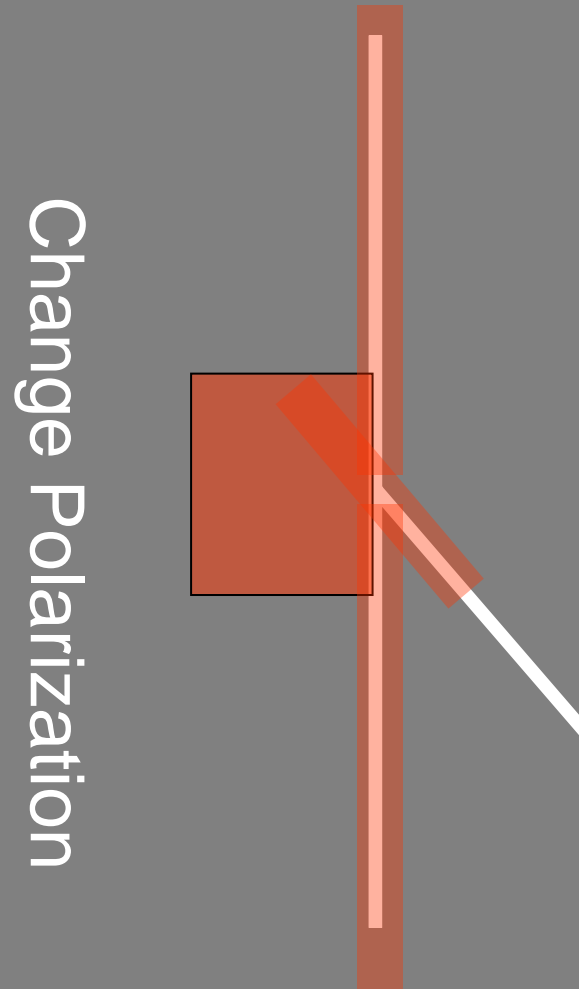
When the near field in junction is large, the energy will be routed to the branch NW.

# Controllable Plasmon Routers



Fang et al, Nano Lett 10, 1950 (2010)

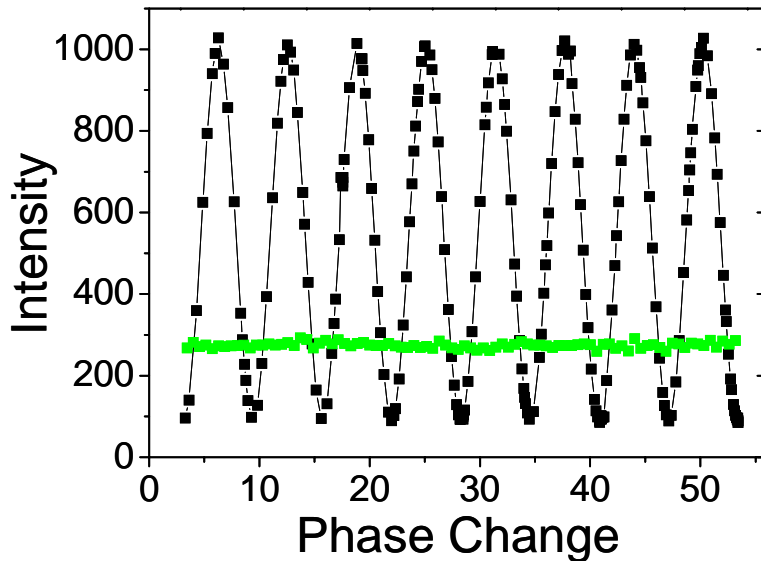
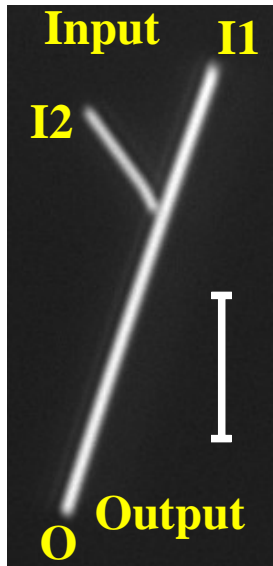
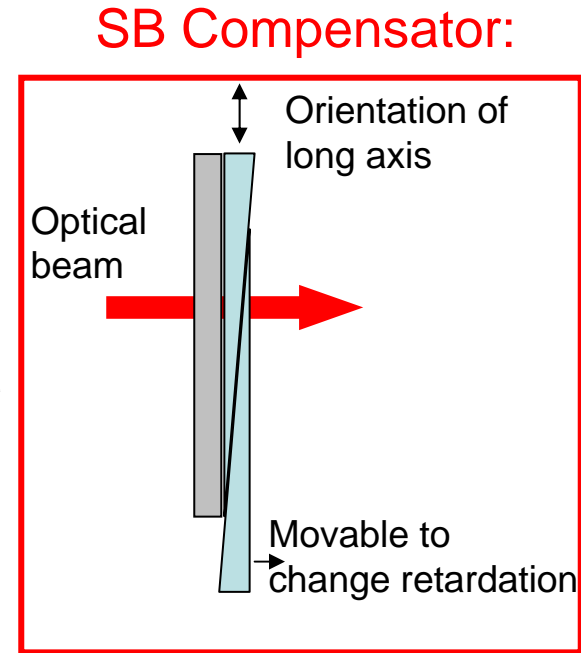
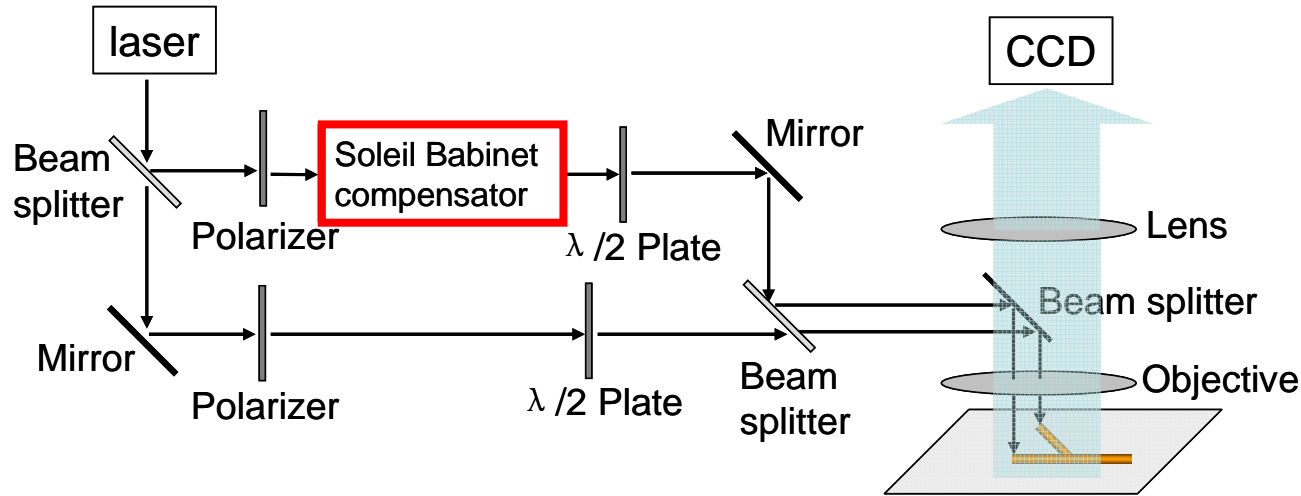
# *Plasmon Switchs in Plasmonic Network*



*Plasmon Switch #1*



### III. Plasmon interference and networks

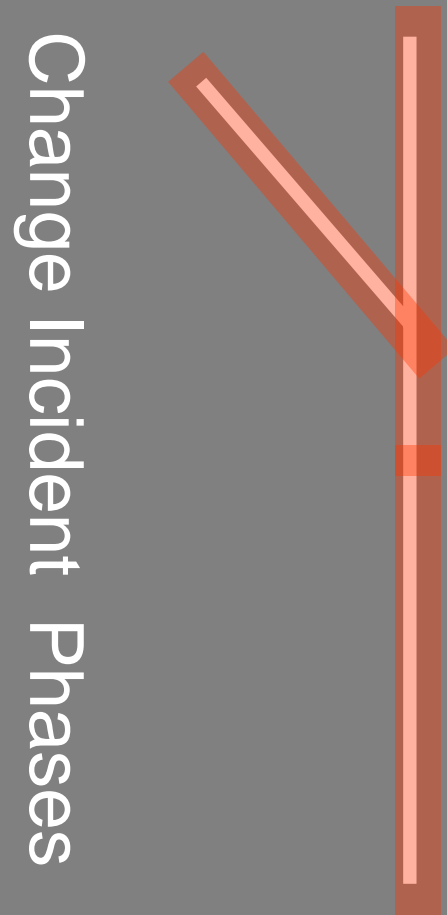


By changing the relative phase of I1 and I2 inputs, the output intensity oscillates.



Hongxing Xu Lab, CAS

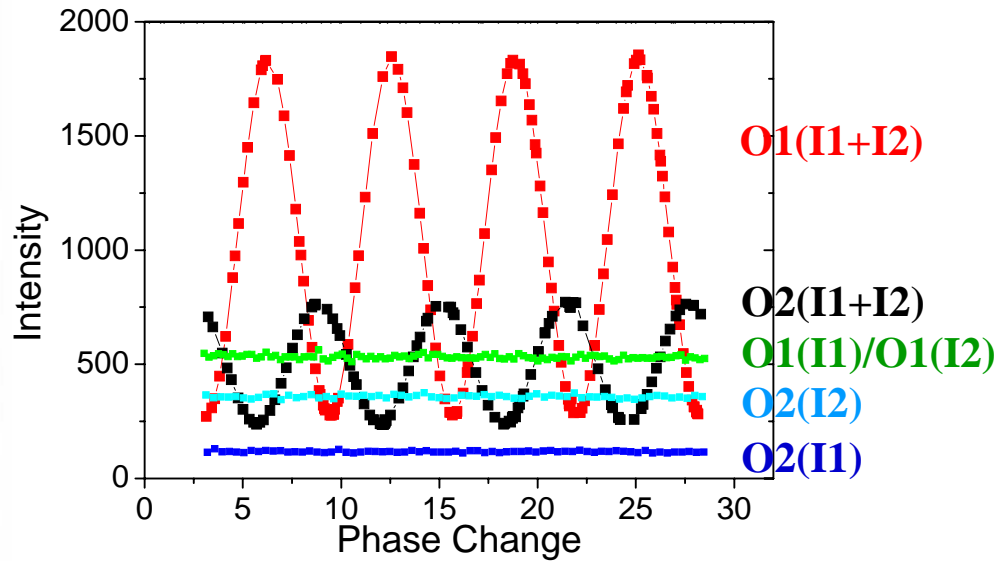
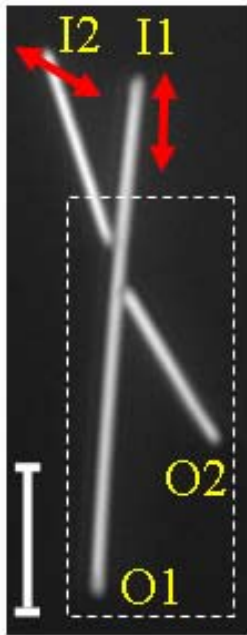
# *Plasmon Switchs in Plasmonic Network*



Change Incident Phases

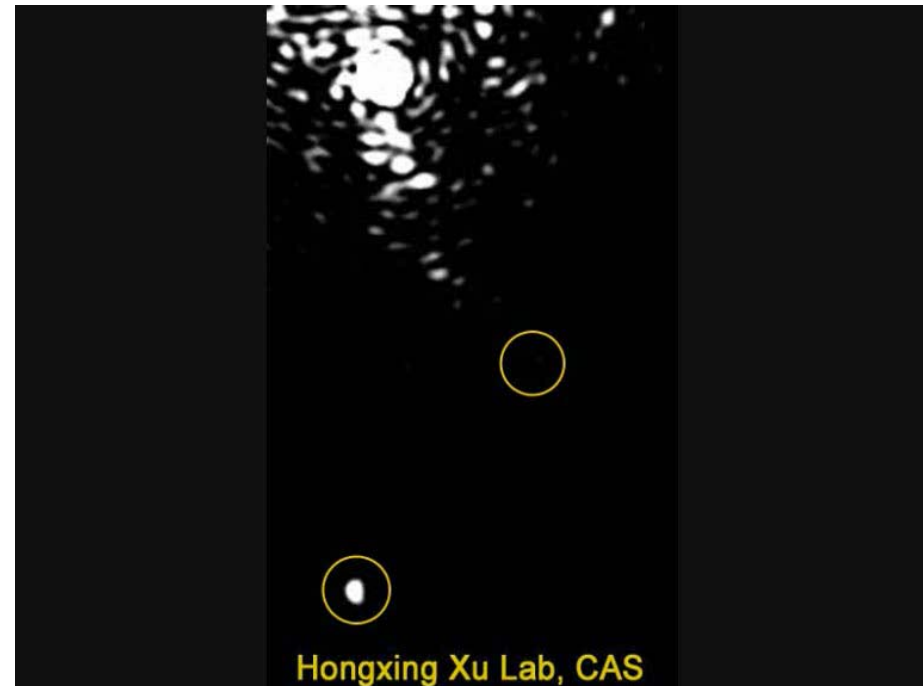
*Plasmon Switch #2*

# Plasmon interference and networks



**Red:** output at **O1** terminal for inputs at both I1 and I2  
**Black:** output at **O2** terminal for inputs at both I1 and I2

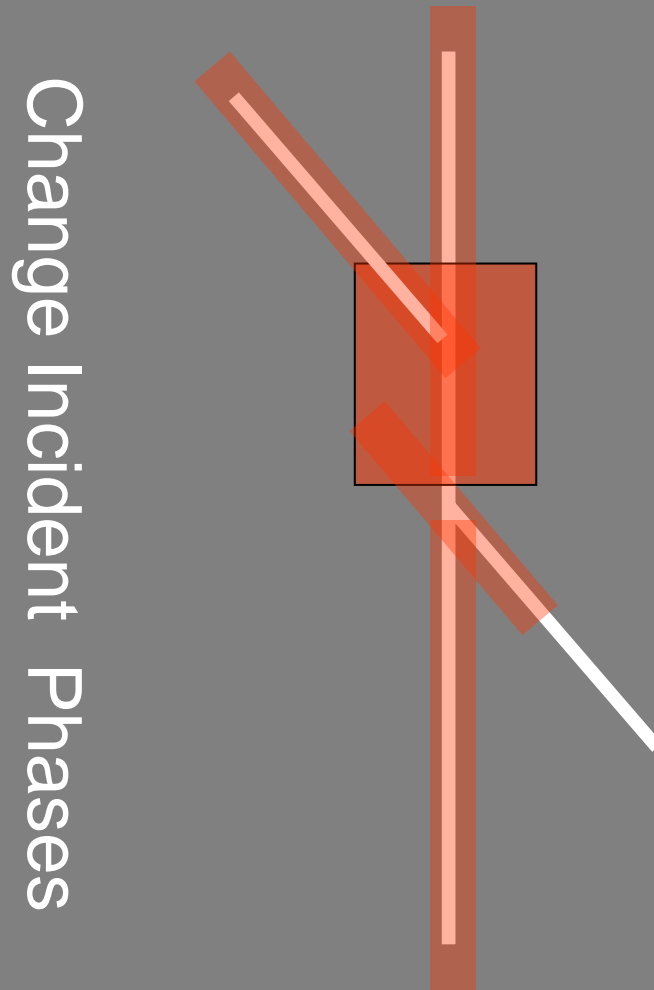
The interference between SPPs generated at inputs I1 and I2 determines output at O1 and O2.





Hongxing Xu Lab, CAS

# *Plasmon Switchs in Plasmonic Network*

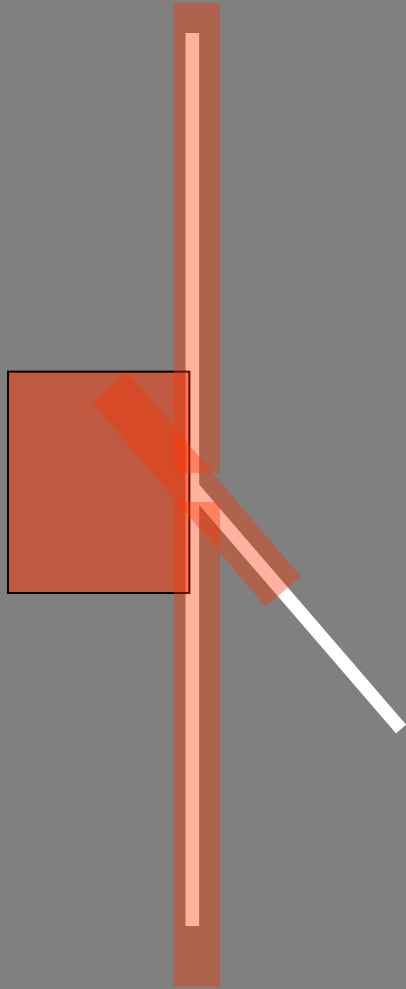


*Plasmon Switch # 3*



# Plasmon Switches in Plasmonic Network

Change Polarization

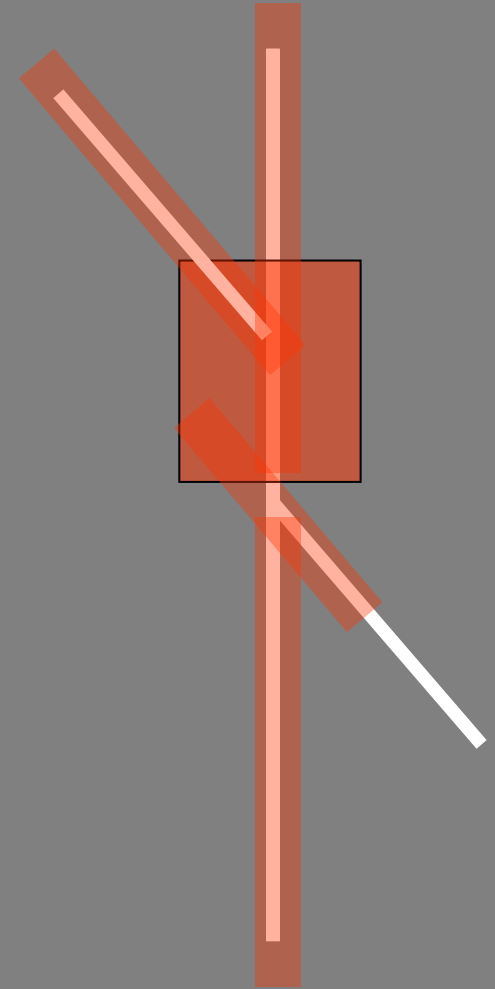


#1

Change Incident Phases



#2



#3

# Plasmon-Based Interferometric Logic and Computing

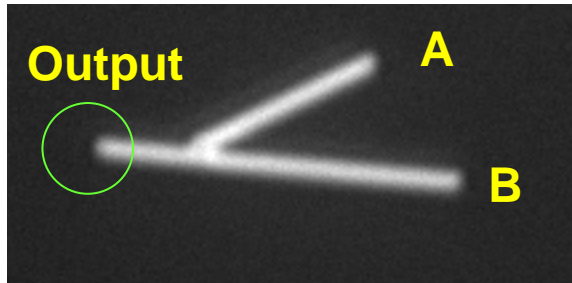
AND	 $0$ $0$ $0$ empty	 $0$ $1$ $0$	 $1$ $0$ $0$	 $1$ $1$ $1$
OR	 $0$ $0$ $0$	 $0$ $1$ $1$	 $1$ $0$ $1$	 $1$ $1$ $1$
XOR	 $0$ $0$ $0$	 $0$ $1$ $1$	 $1$ $0$ $1$	 $1$ $1$ $0$
NOT	 $1$ $0$ $1$ control	 $1$ $1$ $0$		
NAND	 $0$ $0$ $1$ empty	 $0$ $1$ $1$	 $1$ $0$ $1$	 $1$ $1$ $0$
Adder	 $0$ $0$ $0$ $0$ $0+0=(0\ 0)$	 $0$ $1$ $0$ $1$ $0+1=(0\ 1)$	 $1$ $0$ $0$ $1$ $1+0=(0\ 1)$	 $1$ $1$ $1$ $0$ $1+1=(1\ 0)$

Complete set of Boolean logic functions can be realized!

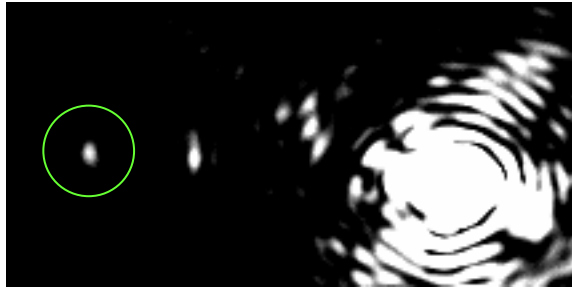
- **Examples of Boolean Logic**

# OR Gate

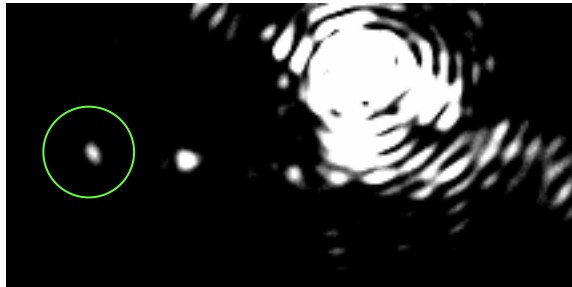
*Boolean logic*



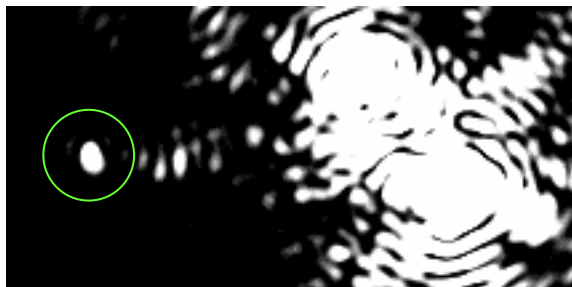
$(A, B) \rightarrow \text{Output}$



$(0, 1) \rightarrow 1$



$(1, 0) \rightarrow 1$

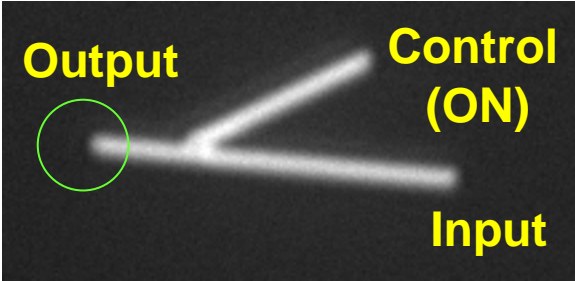


$(1, 1) \rightarrow 1$

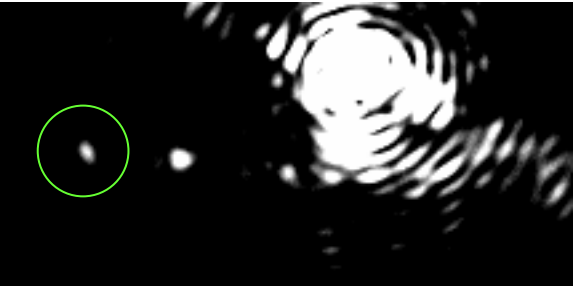
Input		Output
A	B	A OR B
0	0	0
0	1	1
1	0	1
1	1	1

# NOT Gate

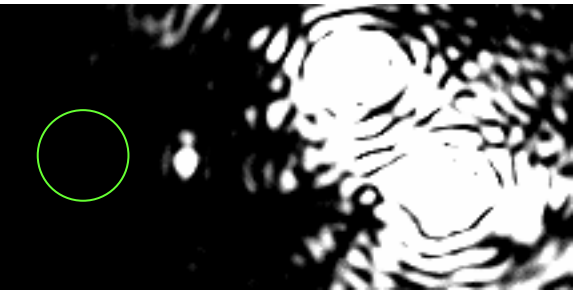
*Boolean logic*



Input → Output



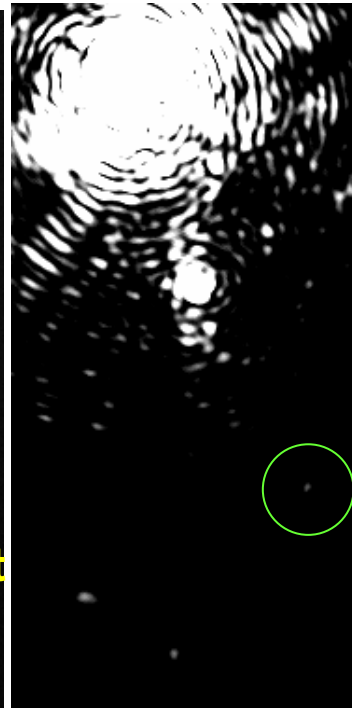
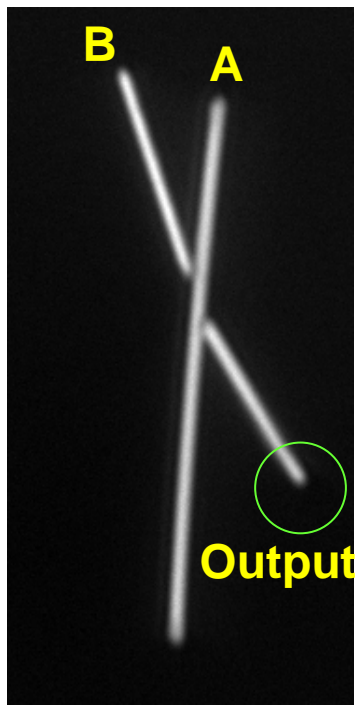
0 → 1



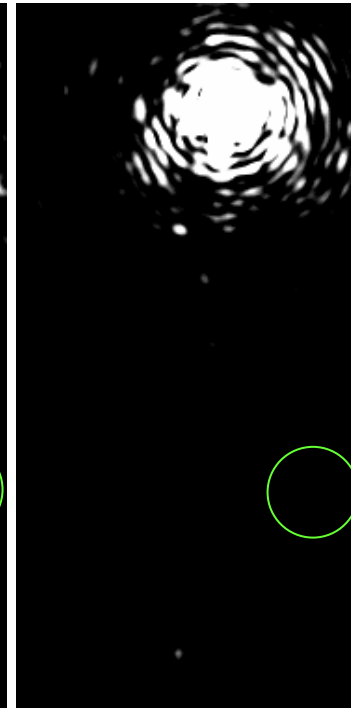
1 → 0

Input	Output
0	1
1	0

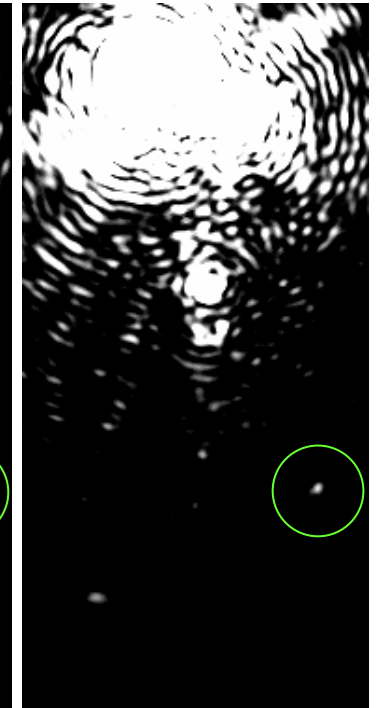
# AND Gate



$(0, 1) \rightarrow 0$



$(1, 0) \rightarrow 0$



$(1, 1) \rightarrow 1$

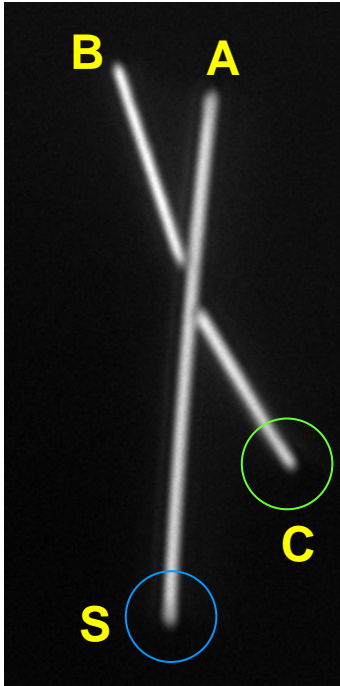
*Boolean logic*

Input		Output
A	B	A AND B
0	1	0
1	0	0
1	1	1



# Half Adder

*Beyond Boolean logic*

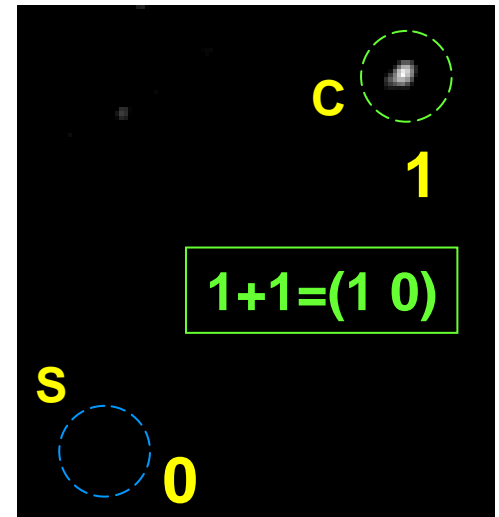
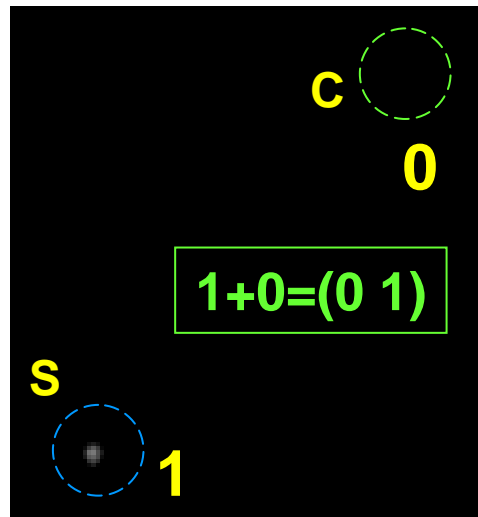
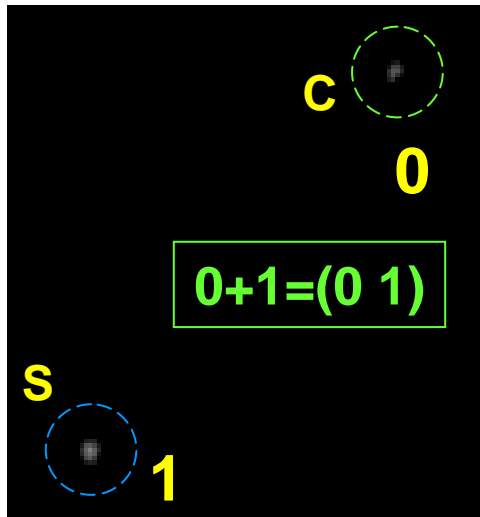
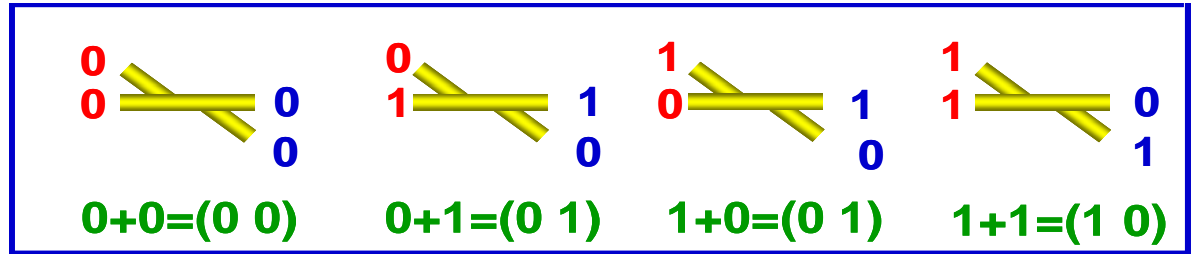


Half-adder:

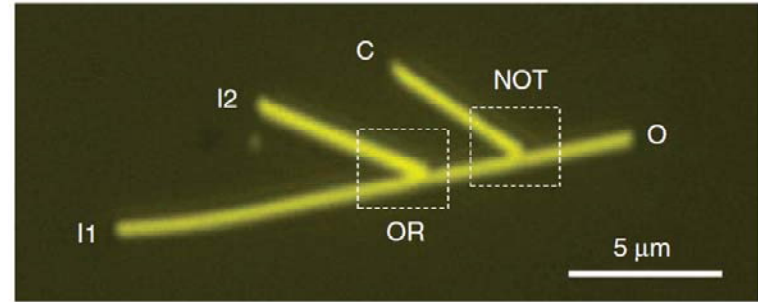
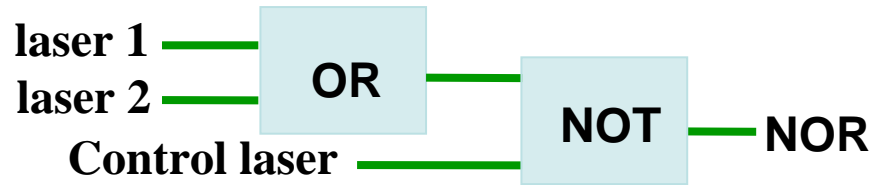
Add two one-bit binary number **A** and **B**.

**S** is the sum, **C** is the value carried on to the next addition.

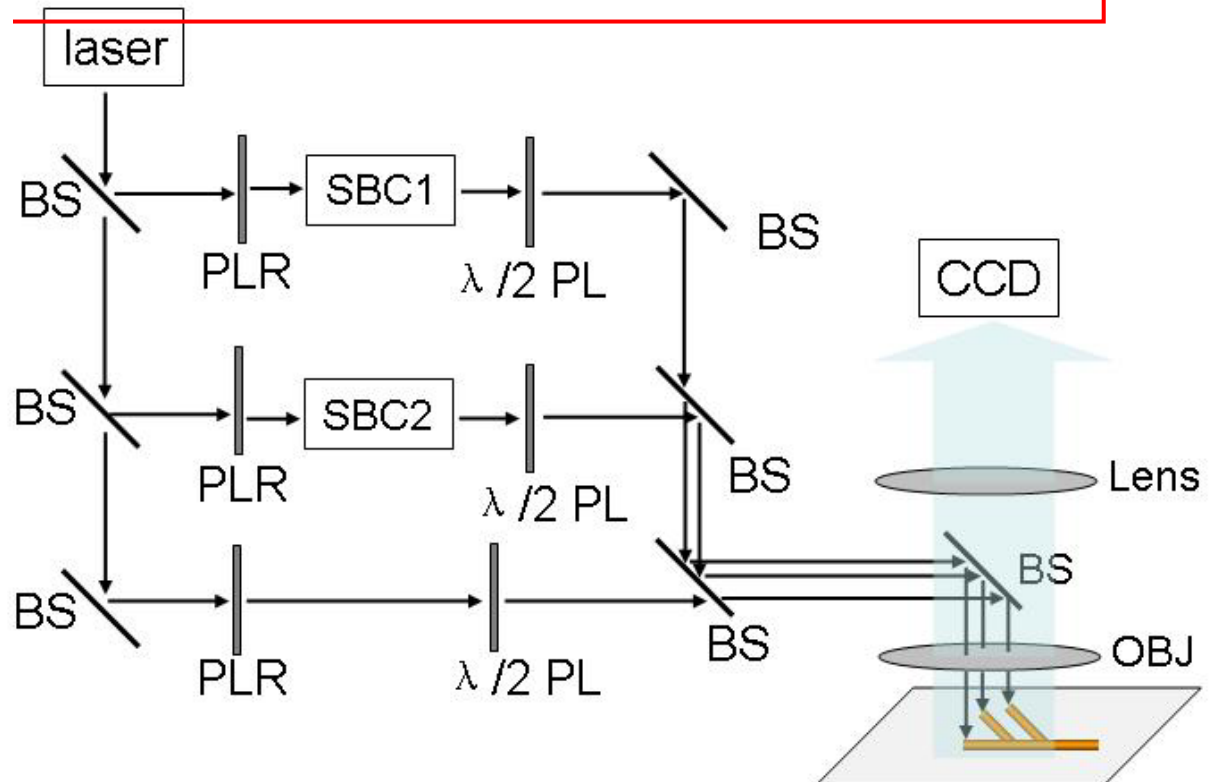
$$A+B=(C S)$$



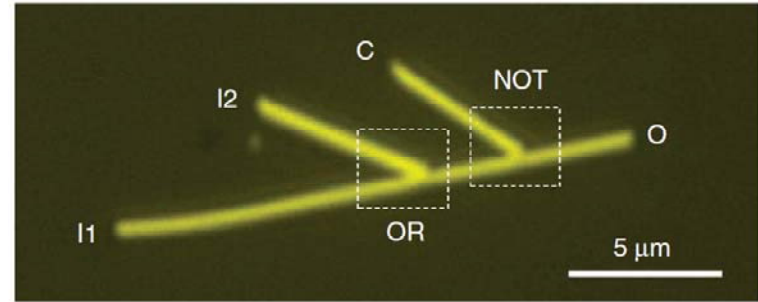
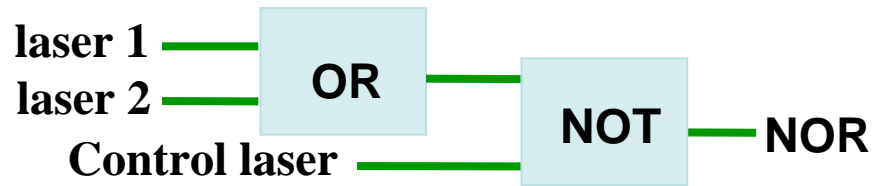
# Cascaded Plasmonic Logic Gates



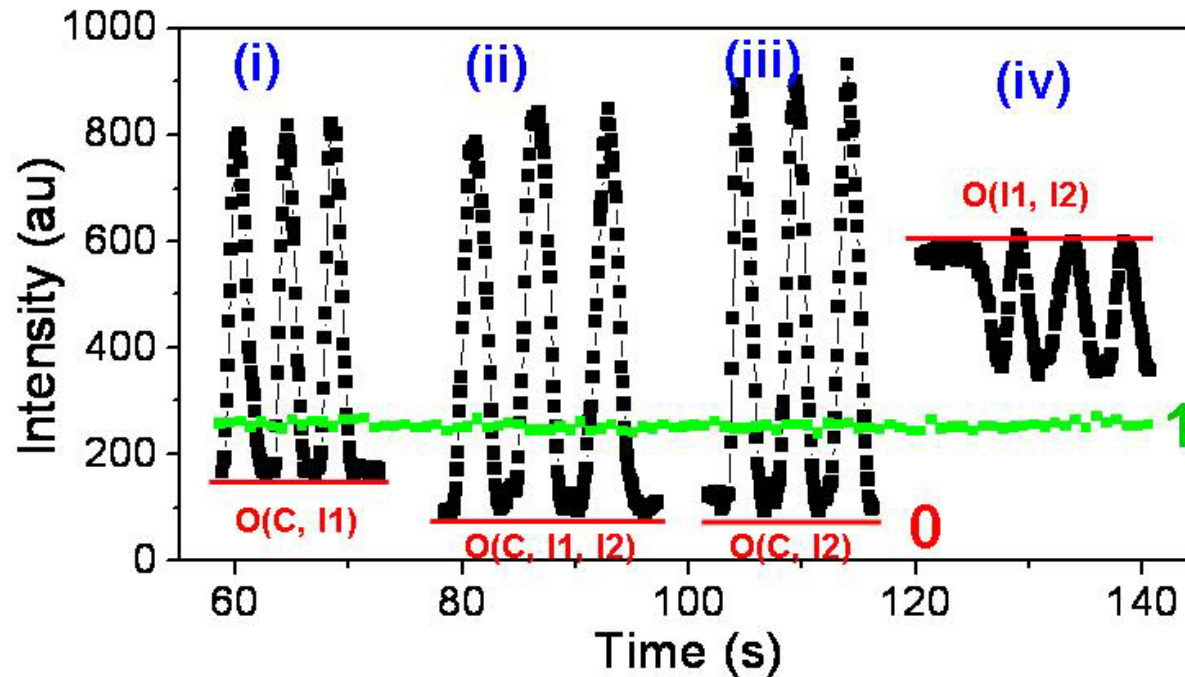
The control signal inverts the output of the *OR* gate, resulting in the *NOR* operation.



# Cascaded Plasmonic Logic Gates



The control signal inverts the output of the *OR* gate, resulting in the *NOR* operation.



# Cascaded Plasmonic Logic Gates

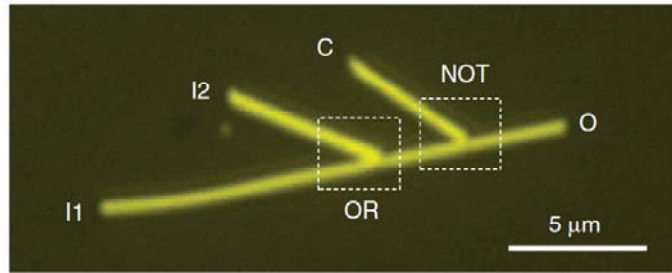
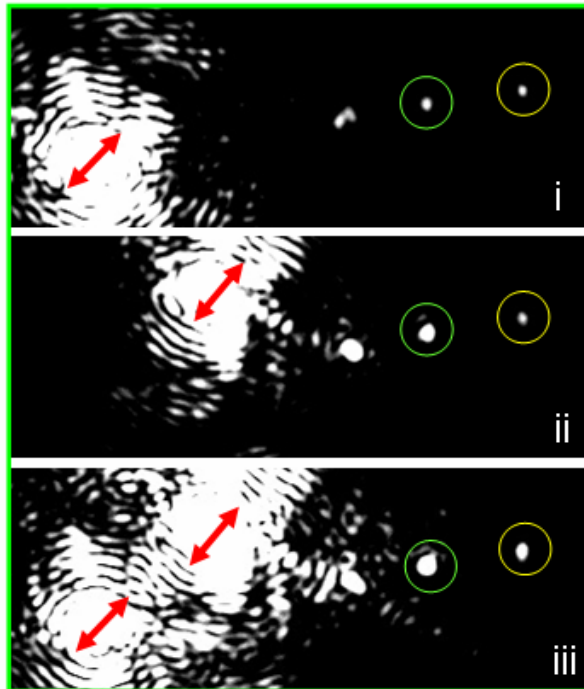


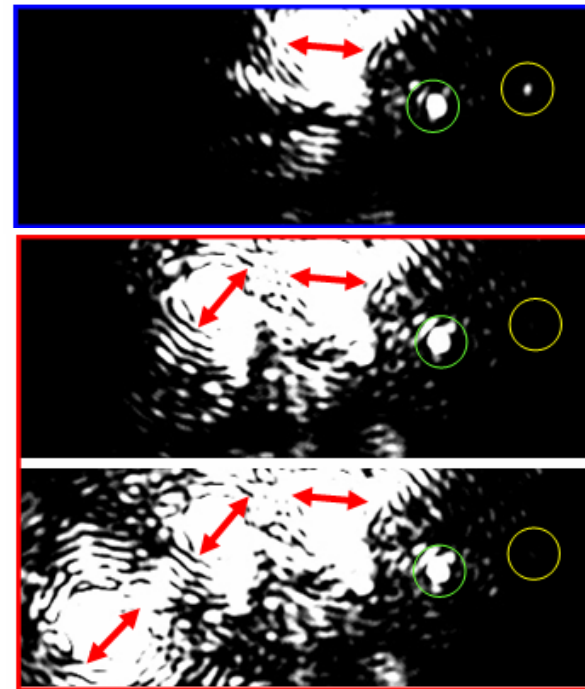
Table 1 | Outputs of logic gates.

Input			Output		
I1	I2	C	O1=I1 OR I2	(O1, C)=NOT O1	O=I1 NOR I2
0	0	1	0	1	1
0	1	1	1	0	0
1	0	1	1	0	0
1	1	1	1	0	0

**OR**



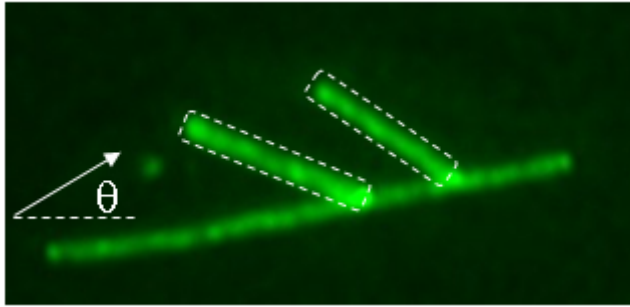
**NOT**



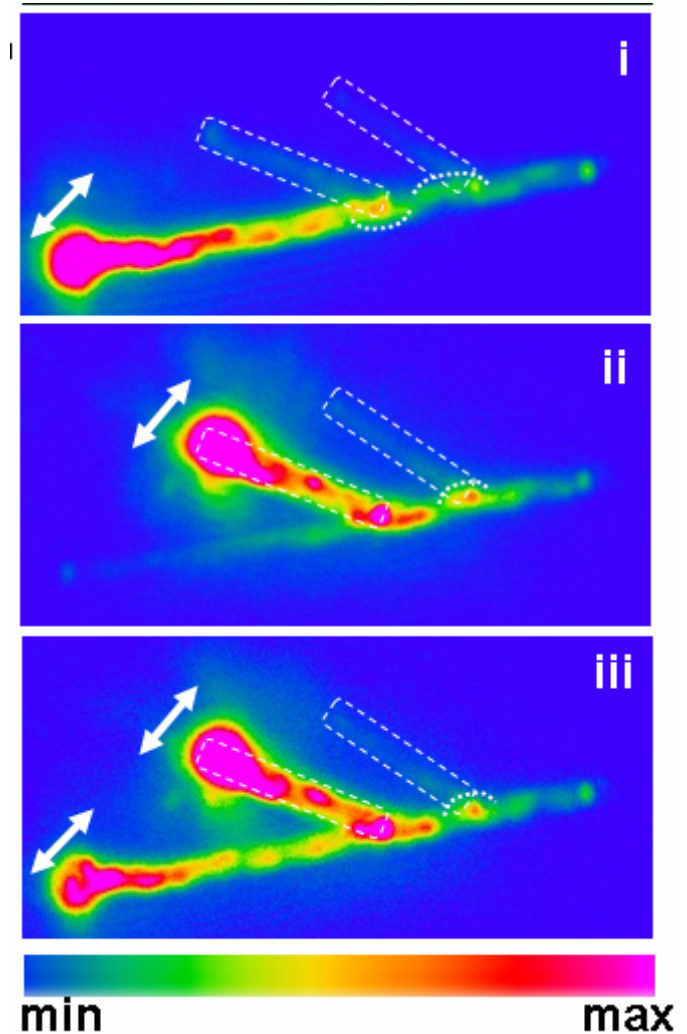
**NOR**

The control signal inverts the output of the *OR* gate, resulting in the *NOR* operation.

# Mechanism



The local field intensity at the C branch junction determines how well the interference can be, i.e., determines if the *OR* operation can be inverted by the control beam.

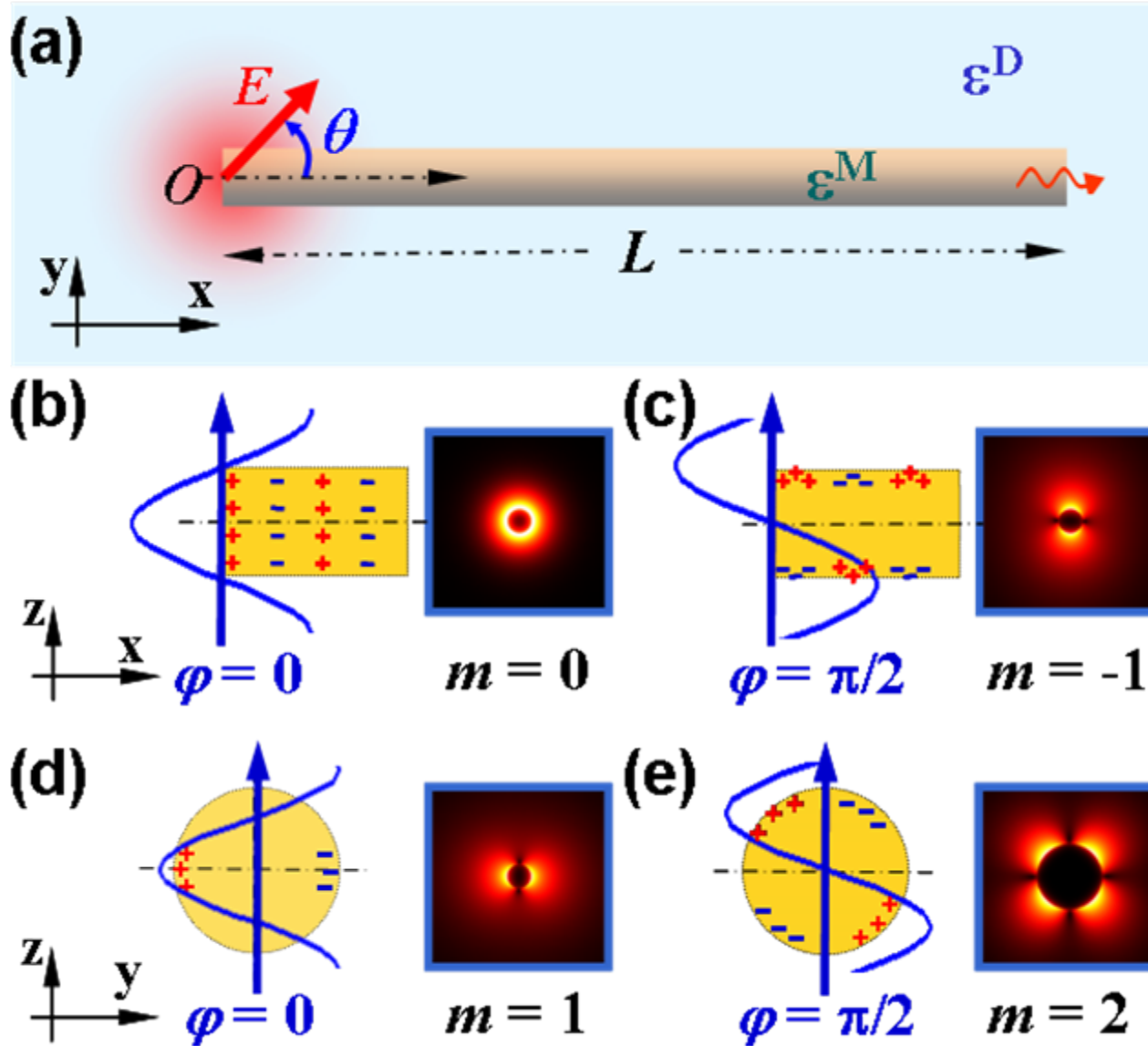


# Outline

- Near-field, Network and Logic
- **Wire plasmon modes/Chiral wire plasmons**
- Tunable wire plasmons
- Substrate-Mediated Plasmon
- Plasmon Amplification



# Plasmon modes excited in metal nanowire



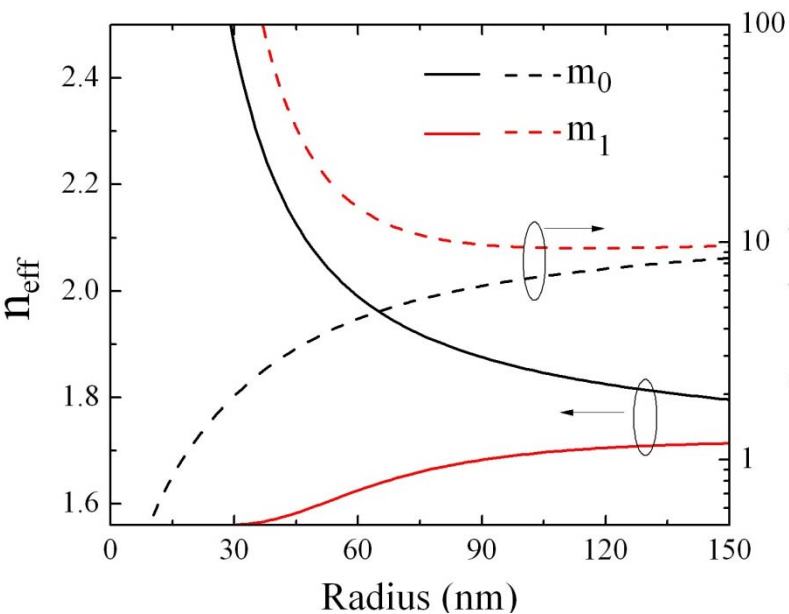
# Mode characteristic

Field distribution outside Ag nanowire:

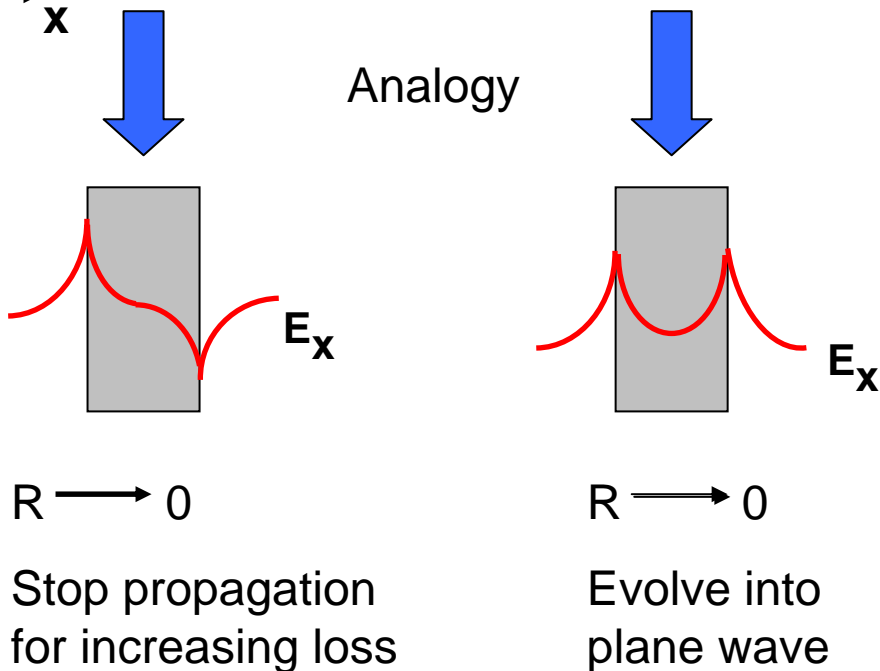
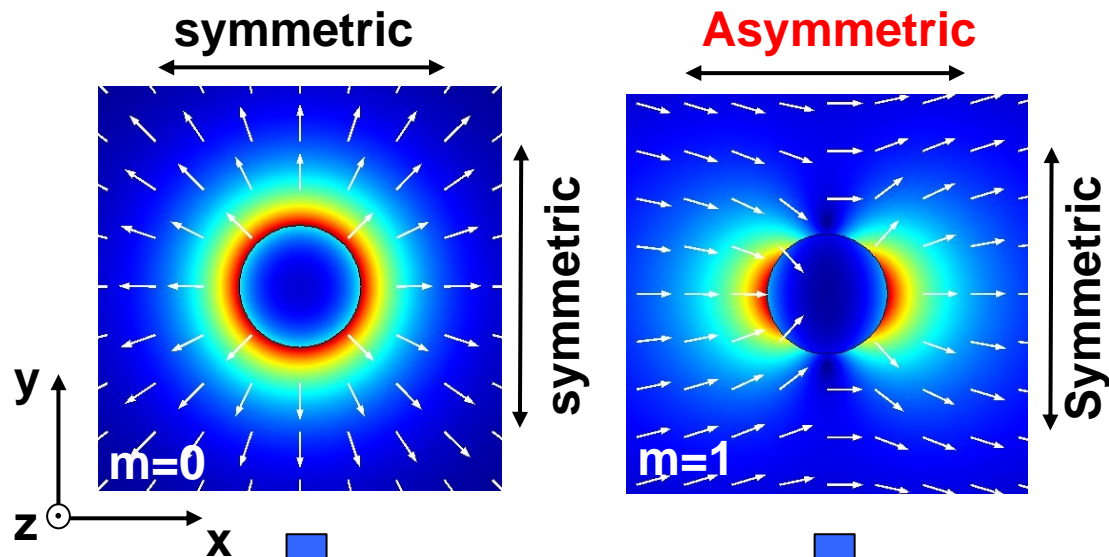
$$E_m(\mathbf{r}) = A_m K_m(k_{\perp} r) \exp(ik_p z)$$

Effective refractive index:

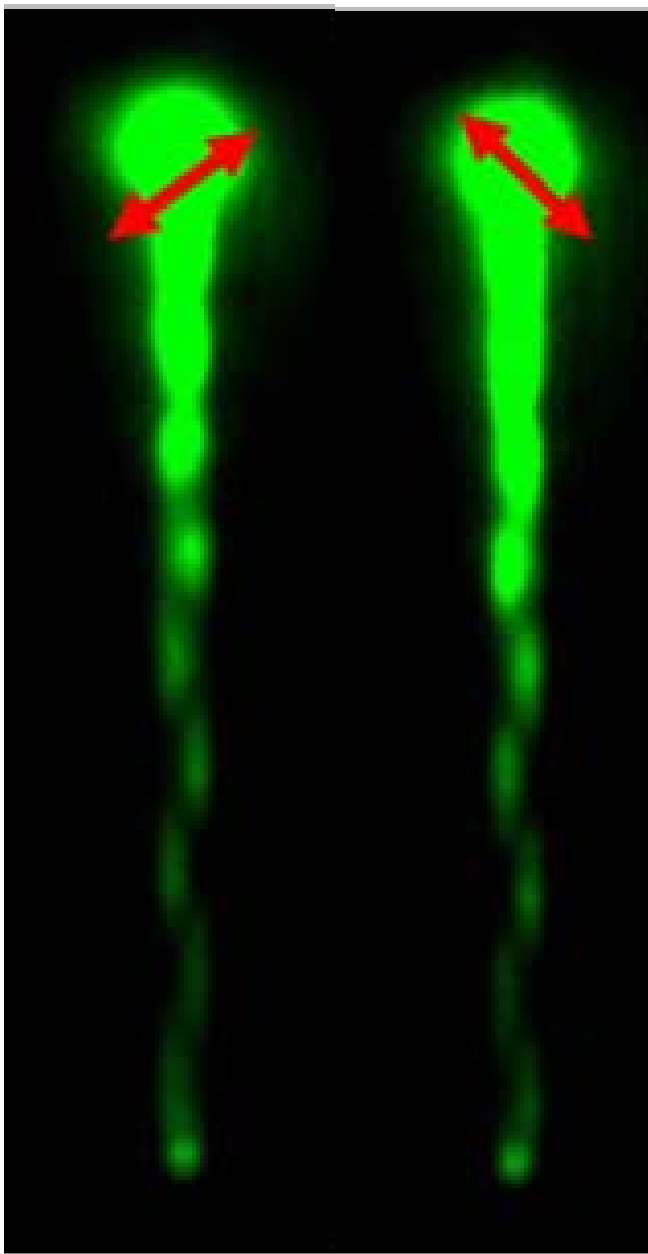
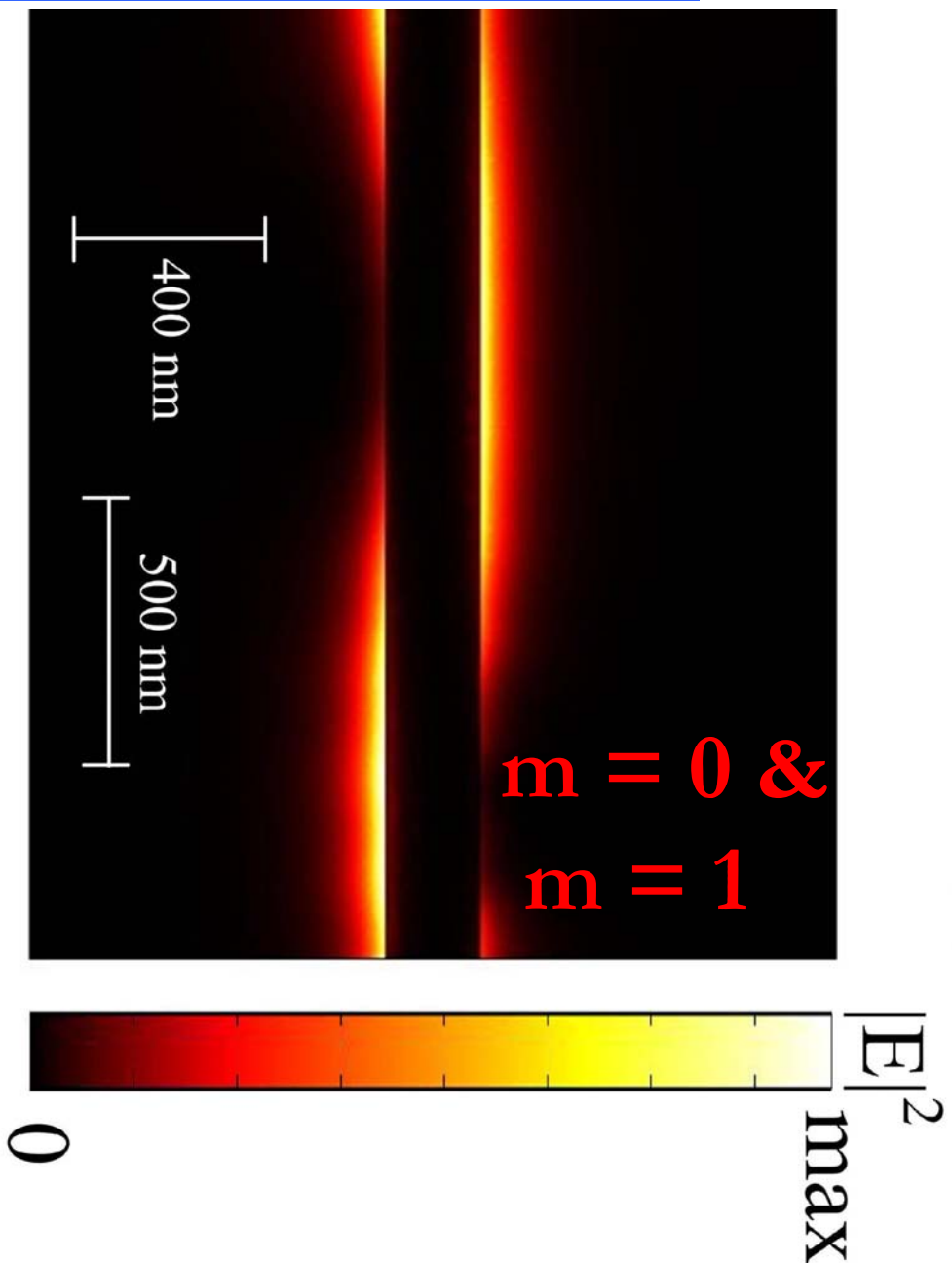
$$n_{eff} = k_p / k_0$$



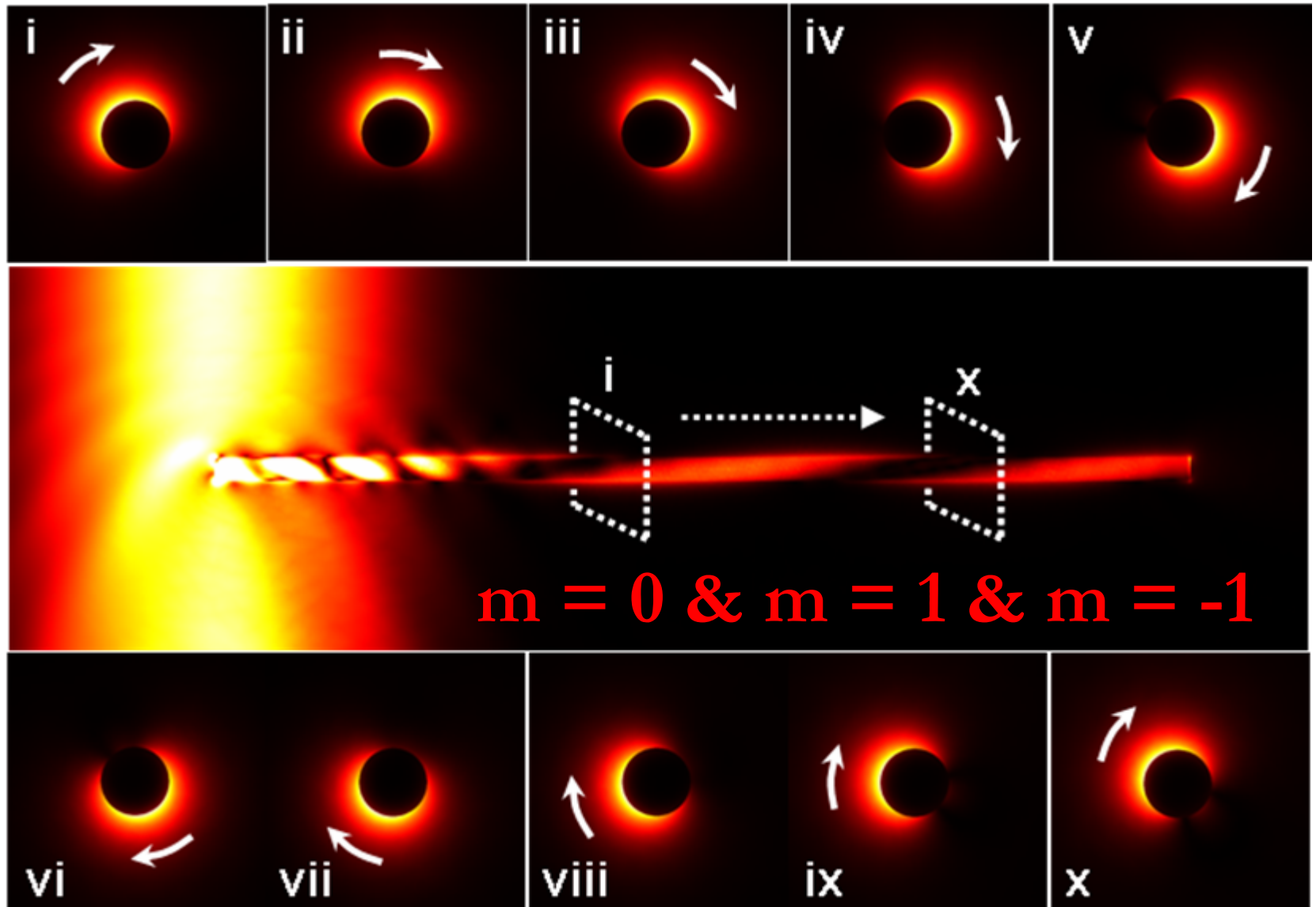
$\lambda = 633\text{nm}$   $n_d = 1.56$



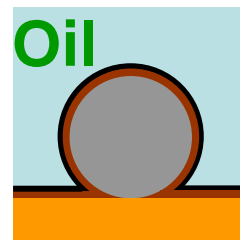
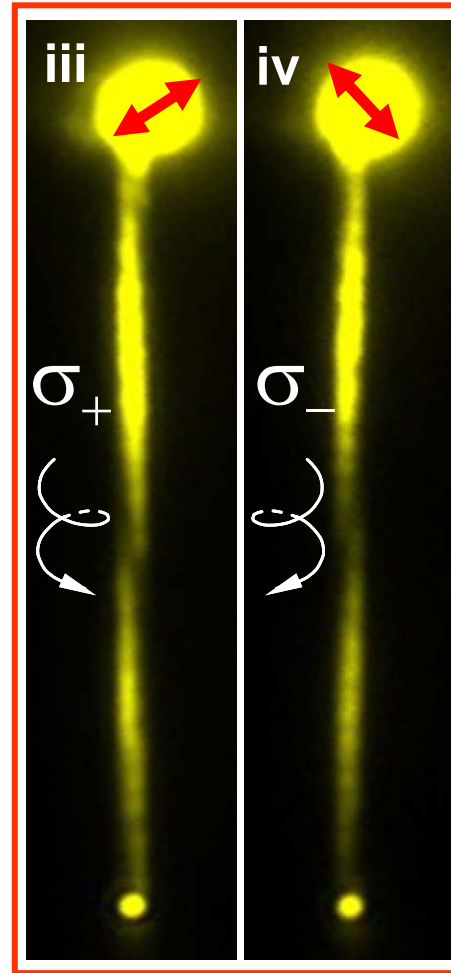
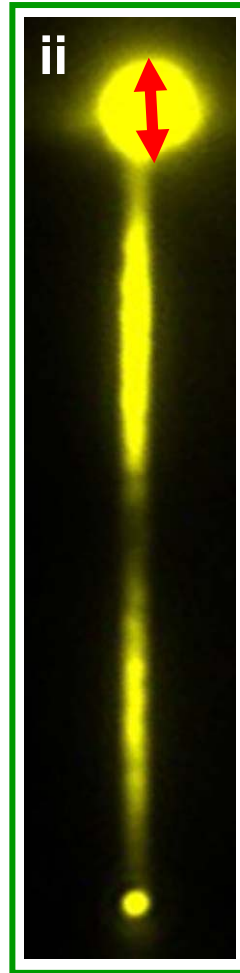
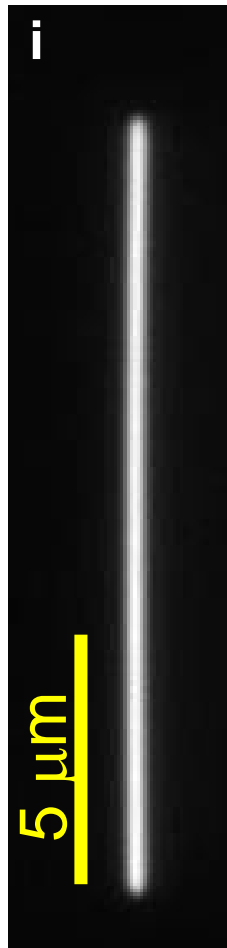
# Mode superposition



# Chiral surface plasmon polaritons

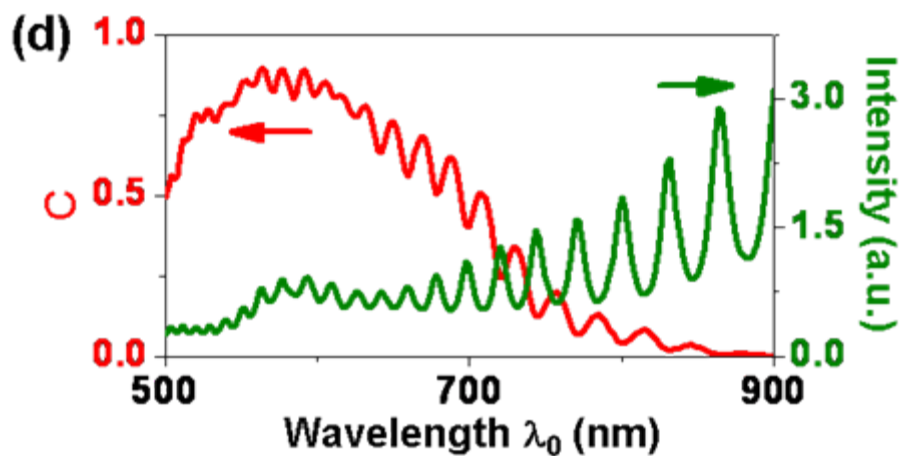
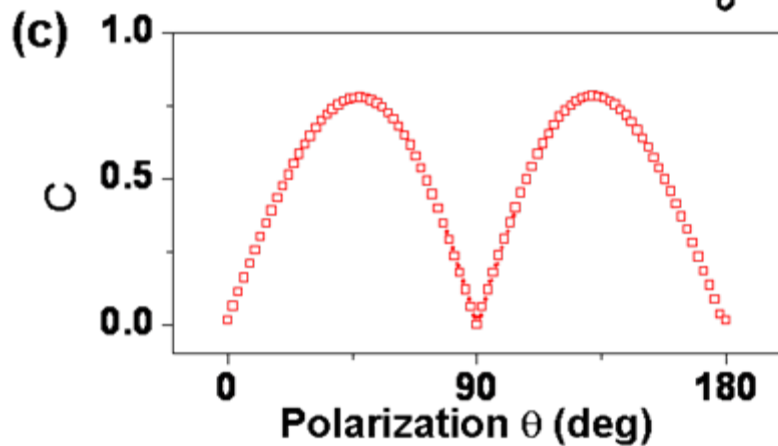
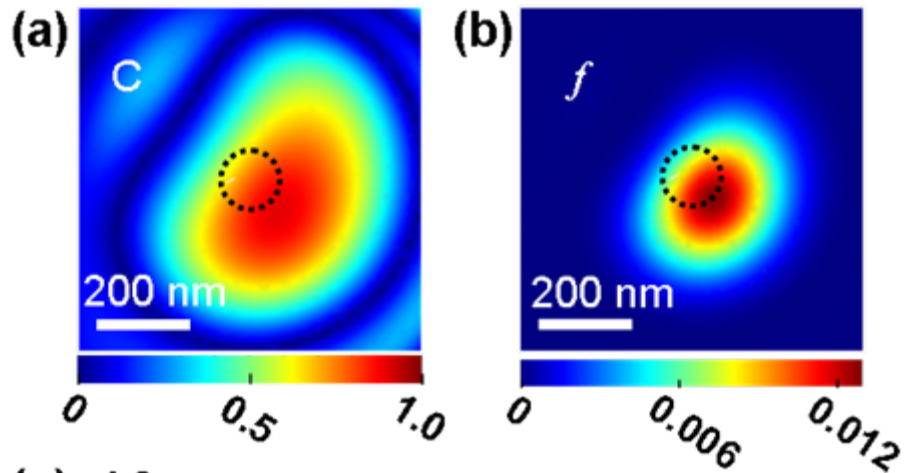
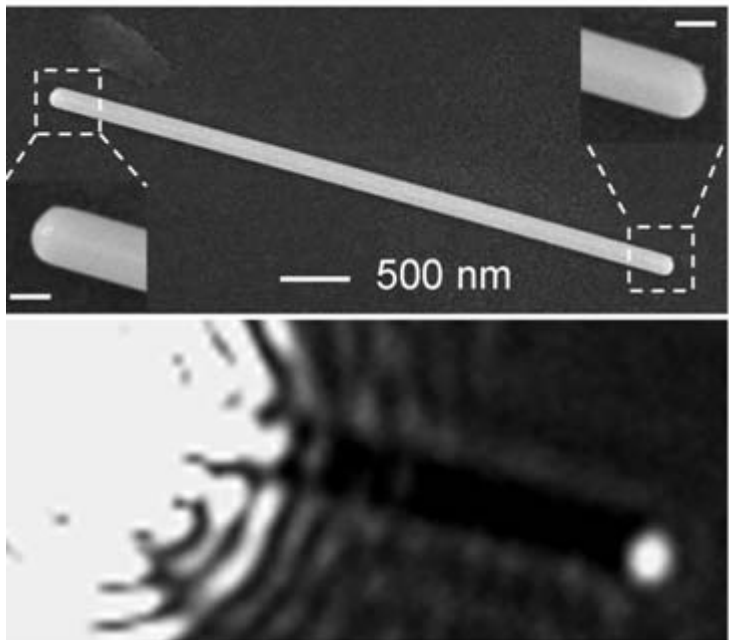


# Chiral surface plasmon polaritons



Helically propagating  
chiral SPPs

Zhang et al., PRL 107, 096801 (2011)



**Degree of circular polarization  $C$**

$$C = \frac{2\langle E_y(t)E_z(t) \sin(\delta_y - \delta_z) \rangle}{\langle E_x^2(t) \rangle + \langle E_y^2(t) \rangle + \langle E_z^2(t) \rangle}$$

**Figure of merit  $f$**

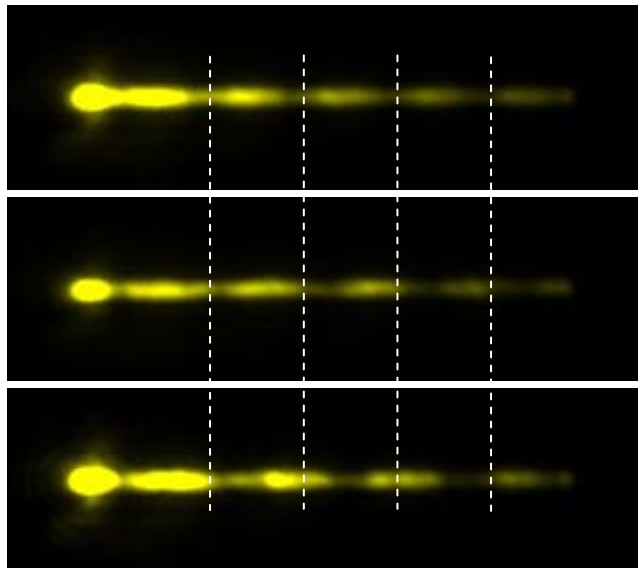
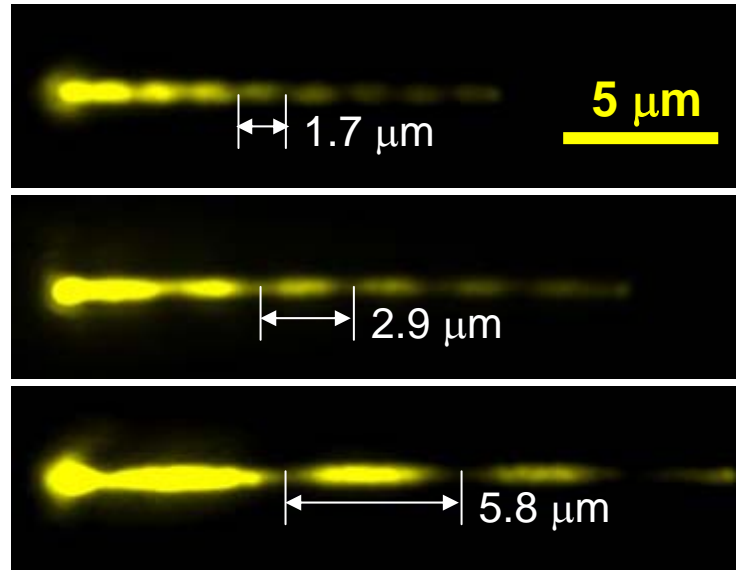
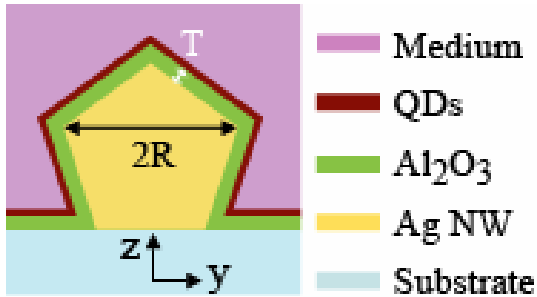
$$f = I \times C^2$$

# Outline

- Near-field, Network and Logic
- Wire plasmon modes/Chiral wire plasmons
- **Tunable wire plasmons**
- Substrate-Mediated Plasmon
- Plasmon Amplification



# 等离子激元传播的调控— Controlling near field beating period



Ag NW of radius  
155 nm coated  
with 30 nm Al<sub>2</sub>O<sub>3</sub>

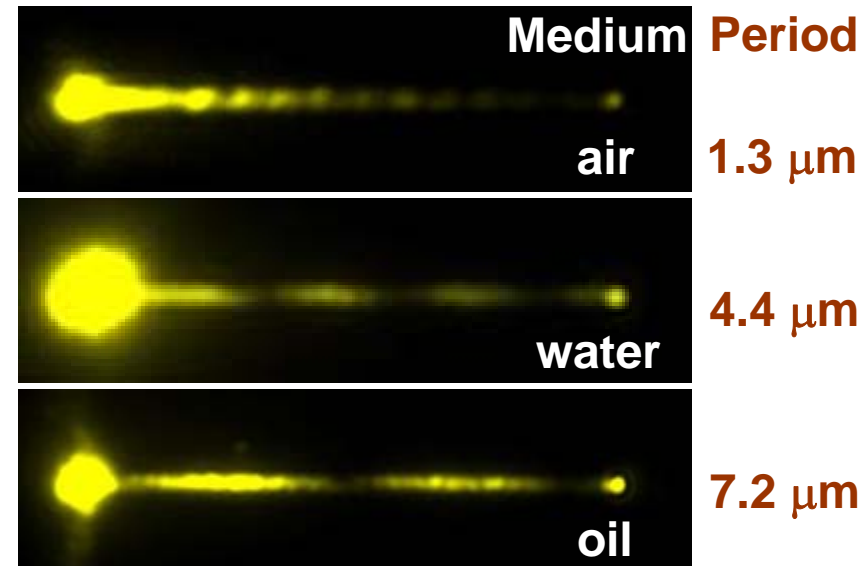
2.9 μm

+ 5 nm Al<sub>2</sub>O<sub>3</sub>

3.3 μm

+ 10 nm Al<sub>2</sub>O<sub>3</sub>

3.8 μm



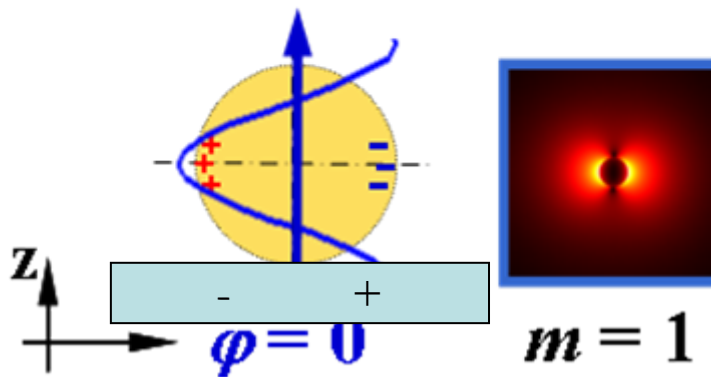
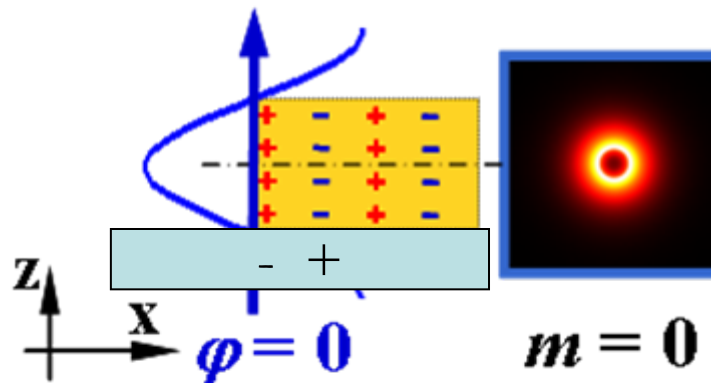
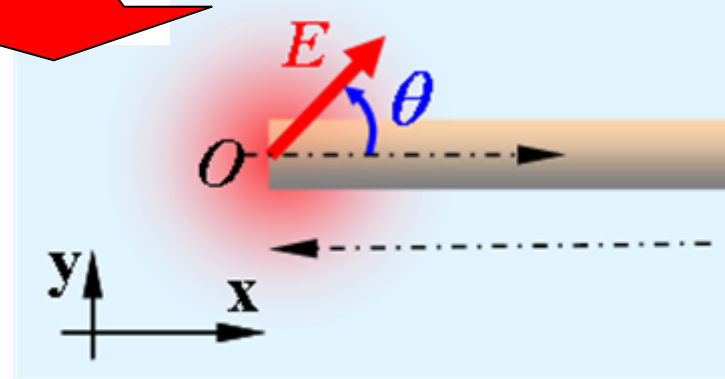
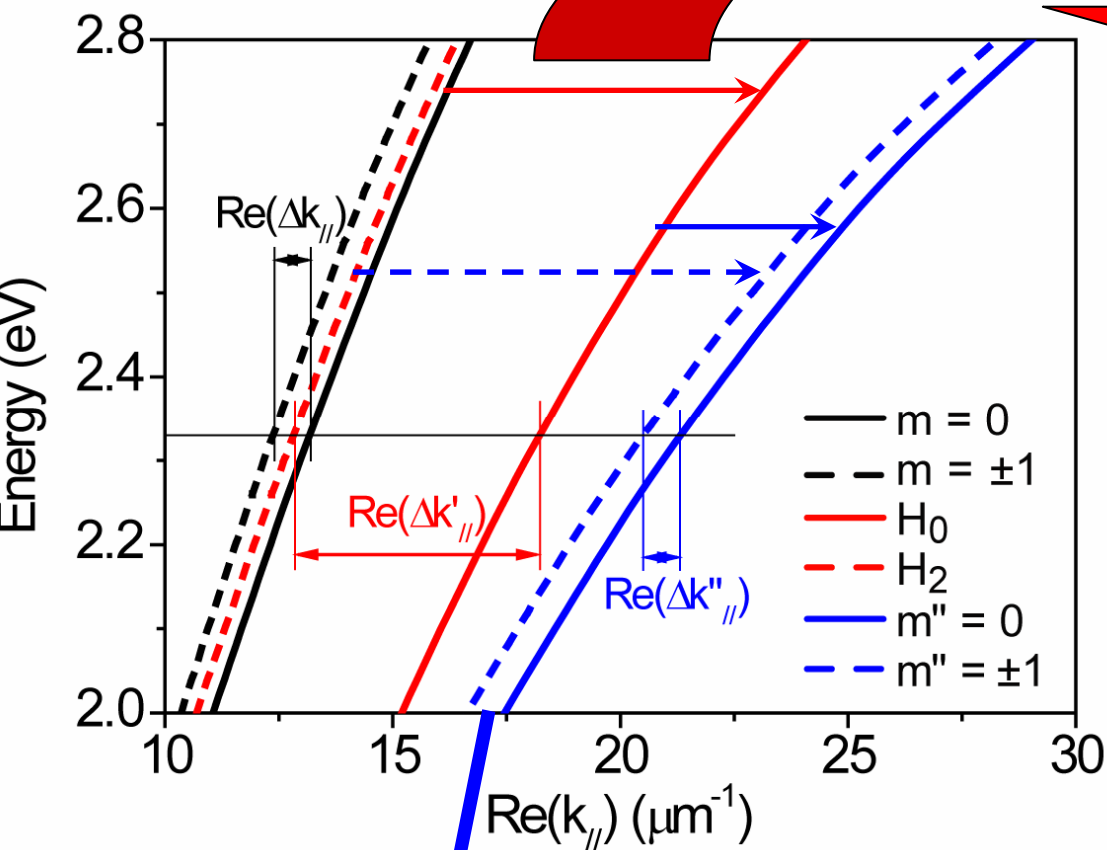
Period

1.3 μm

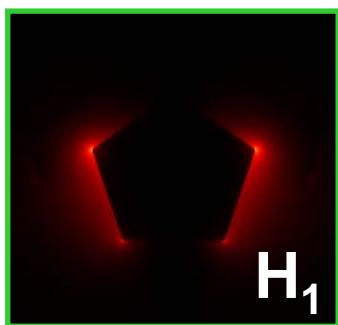
4.4 μm

7.2 μm

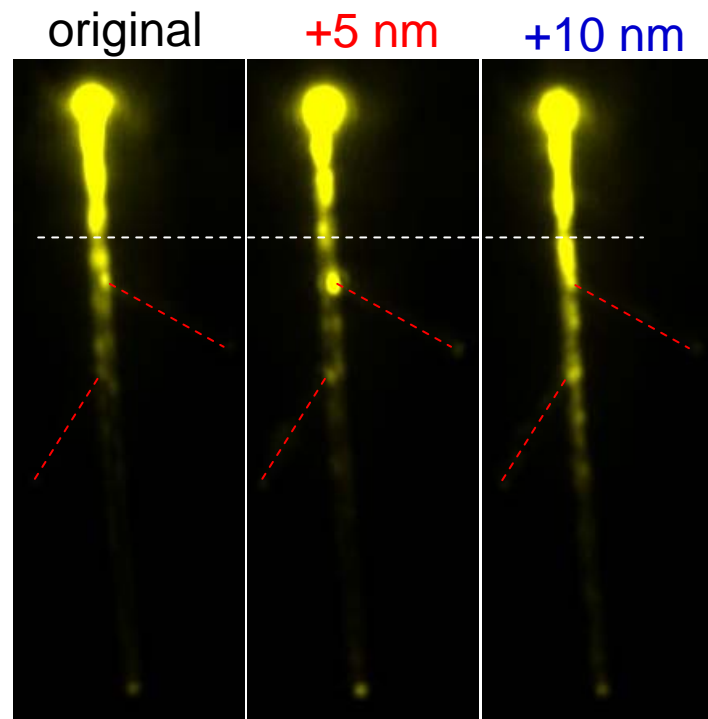
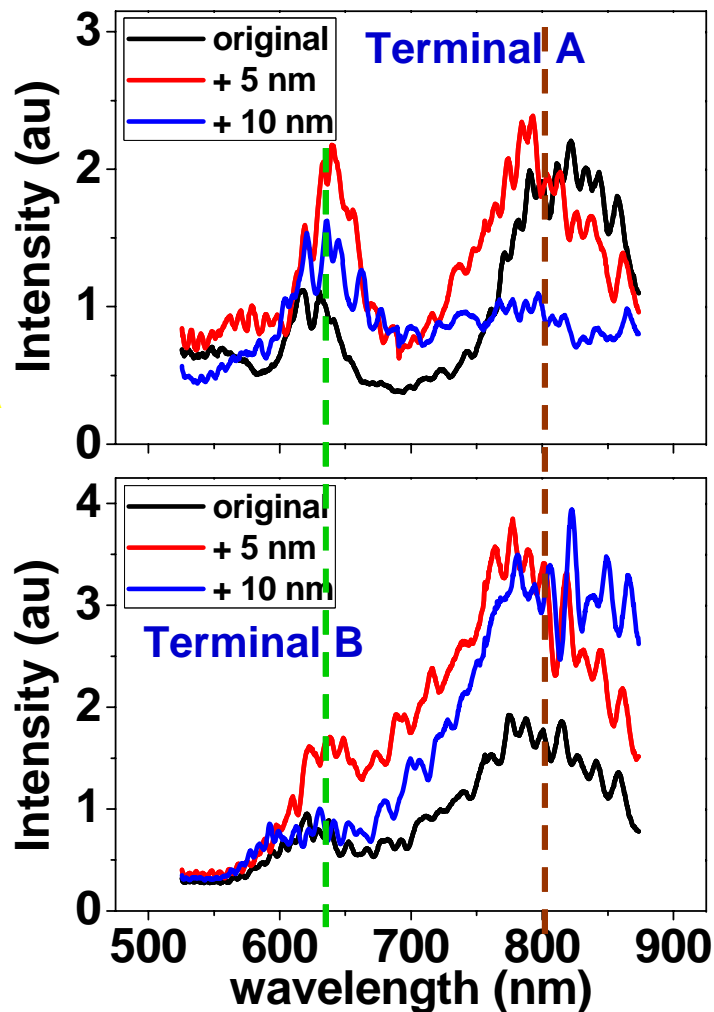
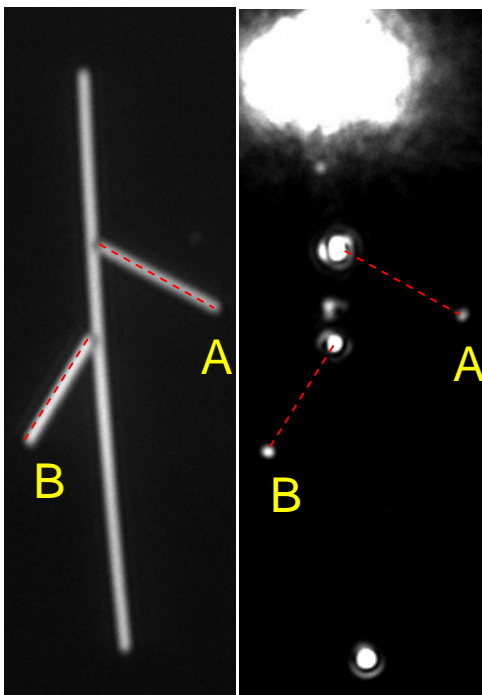
# I. Substrate Effect



# II. Coating Effect



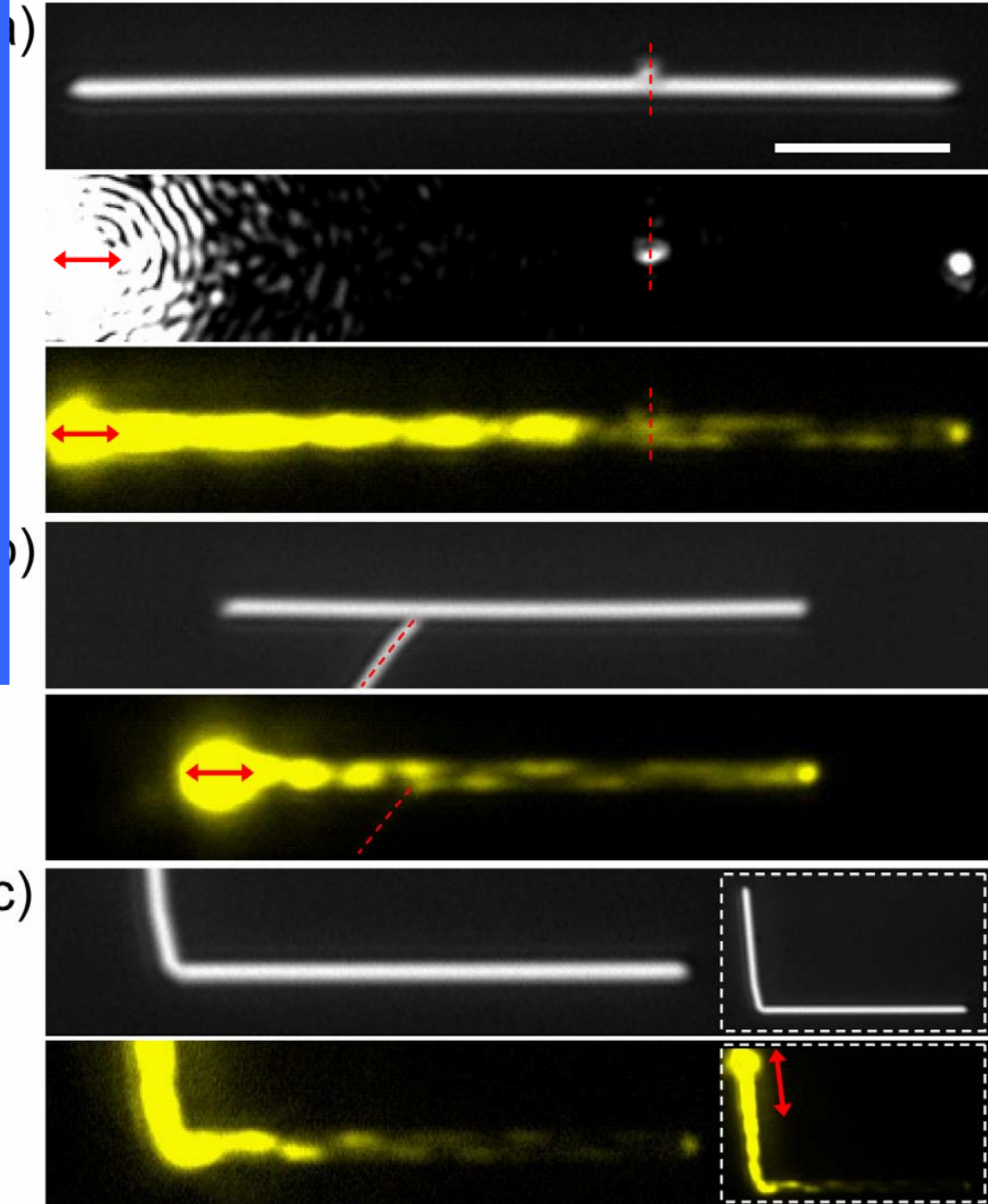
# Controlling plasmon transmission in NW networks



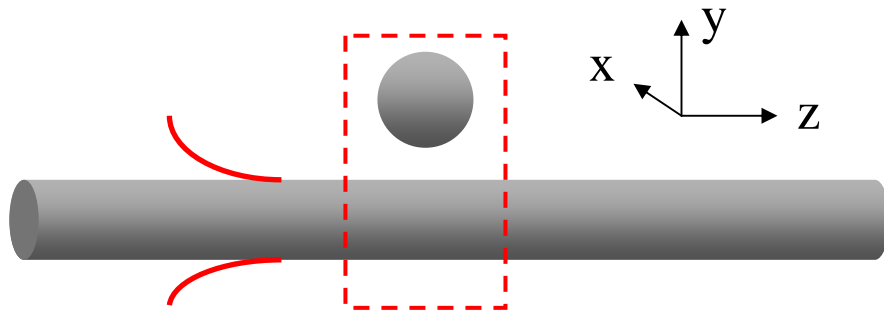
By controlling the dielectric coating thickness, plasmons of certain wavelengths can be routed to different branches.

# Mode conversion

Induced by  
Structure  
Symmetry  
Broken



# Particle-mediated mode conversion



$$\hat{S} \begin{bmatrix} I_{m0} \\ I_{m1} \end{bmatrix}^T = \begin{bmatrix} I'_{m0} \\ I'_{m1} \end{bmatrix}$$

Symmetry:

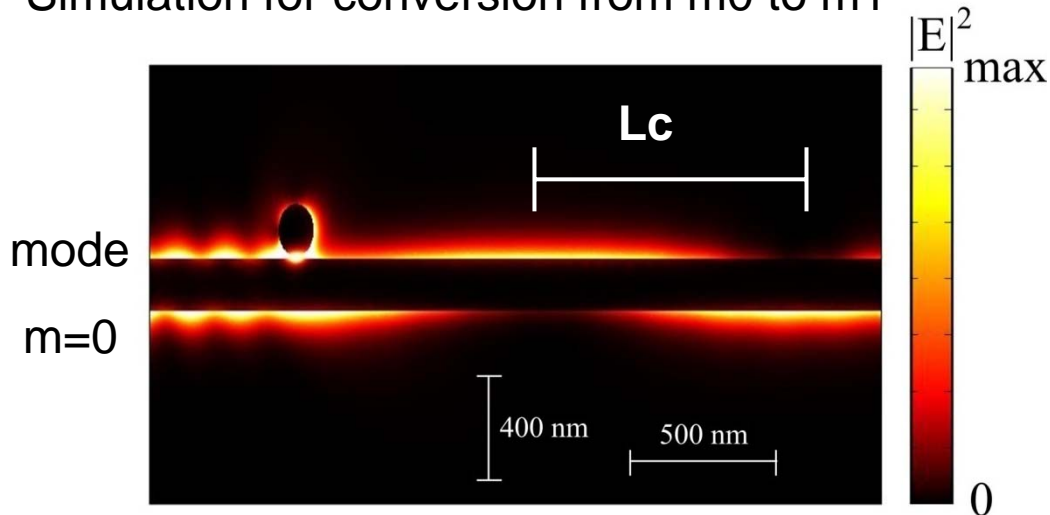
y direction: broken

x direction: preserved

$\hat{S}$  is Hermitian matrix

Off-diagonal element is conversion efficiency

Simulation for conversion from m0 to m1



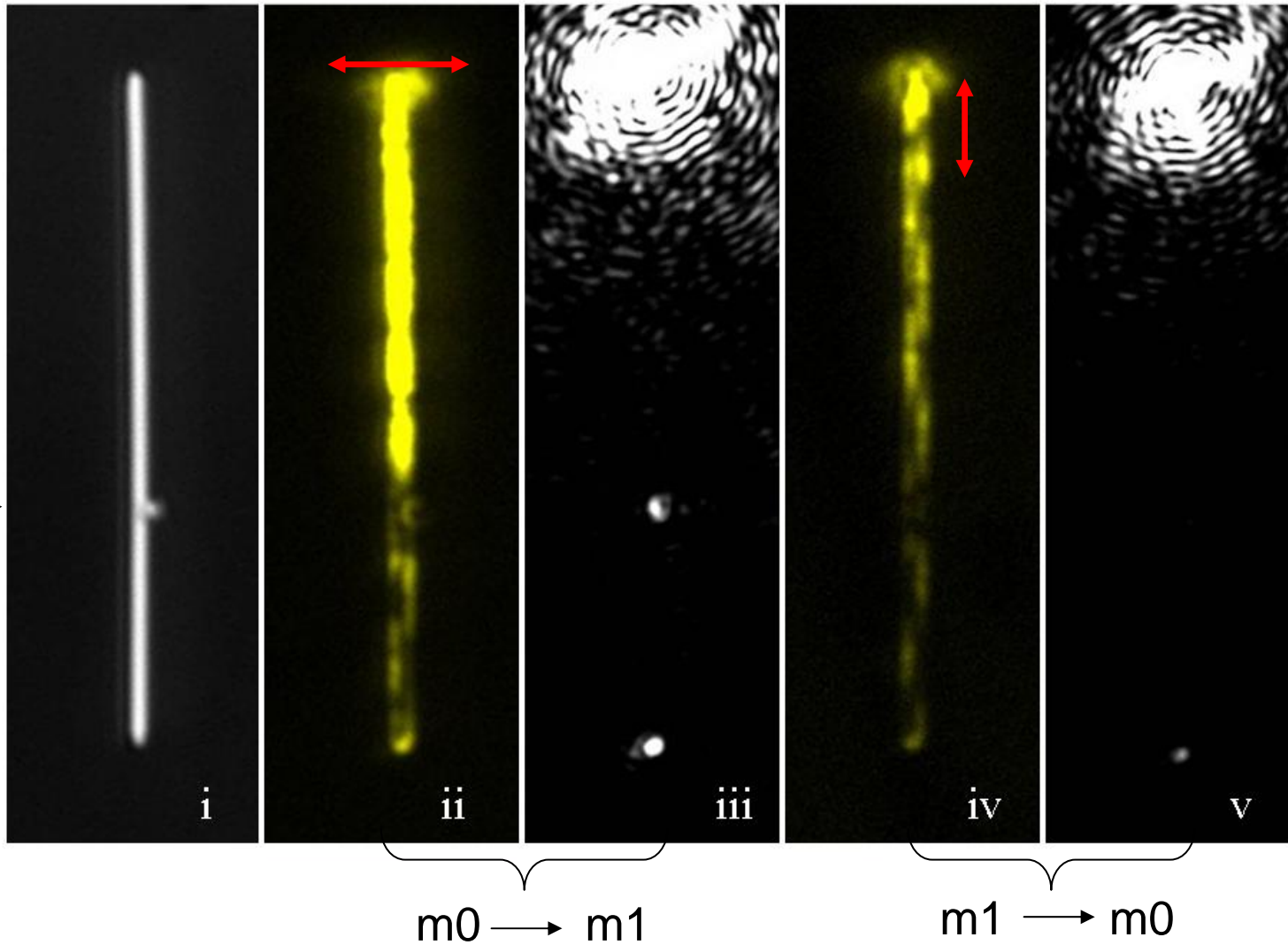
$$(n_{eff,m0} - n_{eff,m1}) \frac{2\pi}{\lambda} L_C = \pi$$

$$\hat{S} \begin{bmatrix} I_{m0} \\ 0 \end{bmatrix}^T = \begin{bmatrix} S_{11} I_{m0} \\ S_{21} I_{m1} \end{bmatrix}$$

# Experiment proof

nanowire radius: 150nm

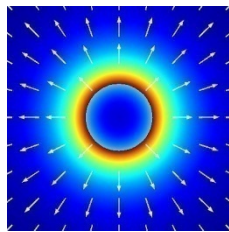
particle →



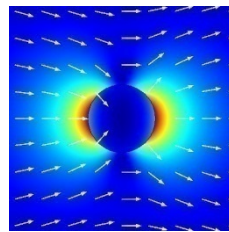
# Theoretical description

## ◆ Expression of plasmon modes

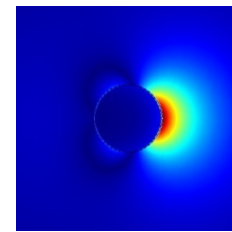
$$|\varphi_0\rangle = \{-E \quad E\} \quad |\varphi_1\rangle = \{E \quad E\}$$



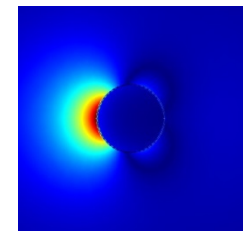
$$+ e^{i\phi}$$



$$=$$



or

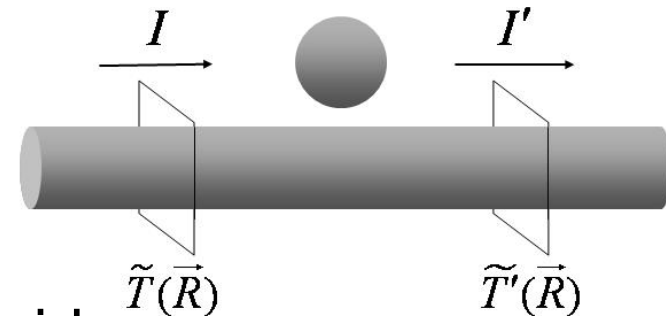


Power of the two modes:  $I_0 \approx I_1$

## ◆ TM<sub>0</sub> as incident: $\vec{T}^0 = |\varphi_0\rangle = \{-E \quad E\}$

scattering mainly influence field on one side

$$\vec{T}' = \{-\ell E \quad E\} = (\ell+1)/2 |\varphi_0\rangle - (\ell-1)/2 |\varphi_1\rangle$$



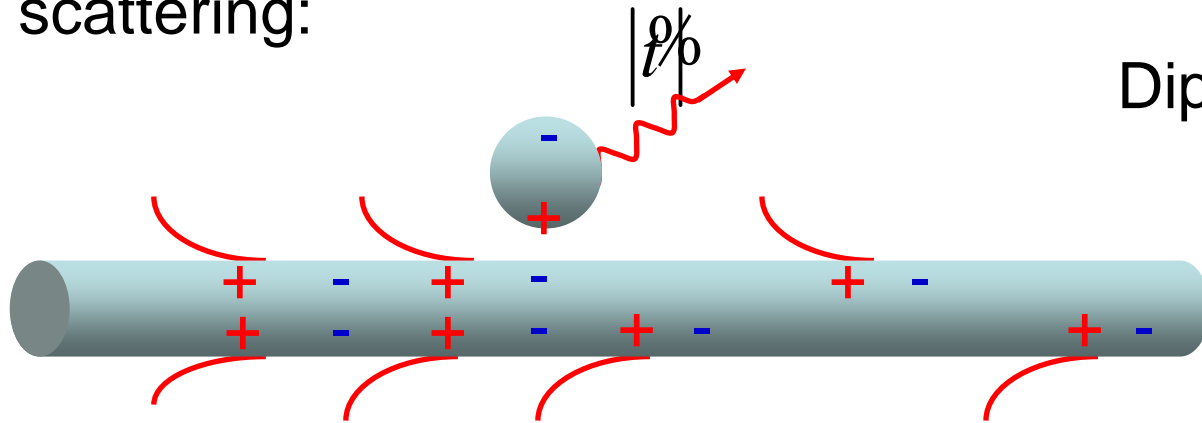
$$I' = (|\ell|^2 + 1) I_0 / 2$$

$$S_{11} = (\ell+1)^2 / 4 \quad S_{21} = (\ell-1)^2 / 4$$

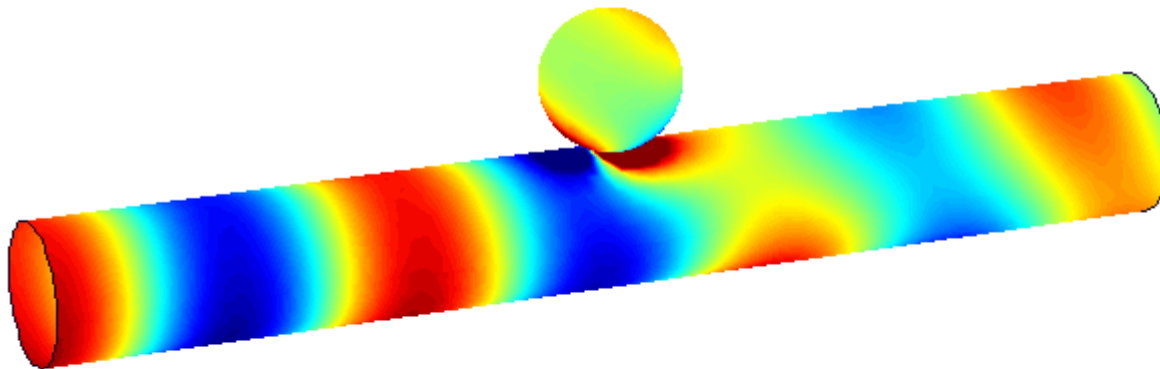


# Two conversion processes

I Direct scattering:



Dipole: radiative



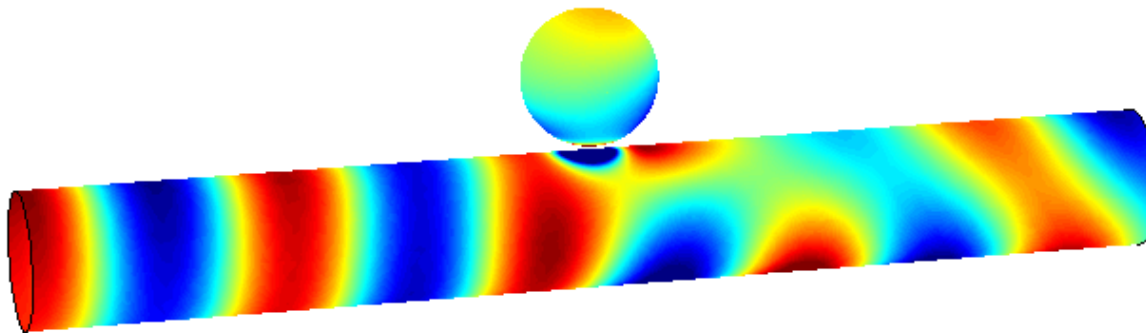
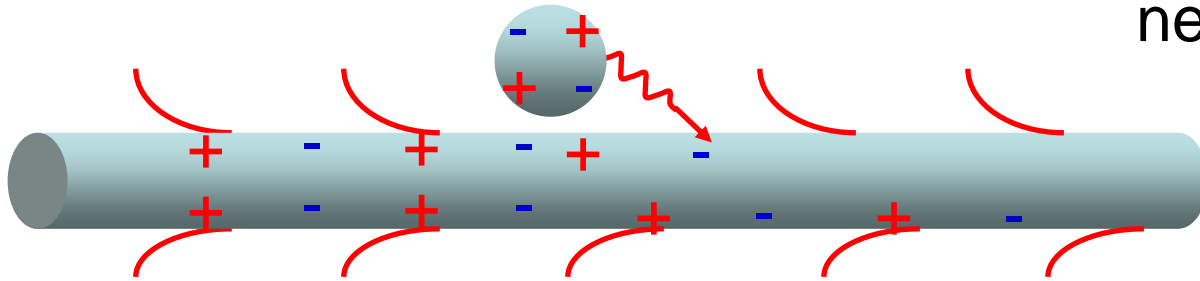
$\lambda = 633 \text{ nm}$   
Off Resonance

# Two conversion processes

II Recollection:

$$\arg(\rho)$$

Quadrupole:  
near field coupling

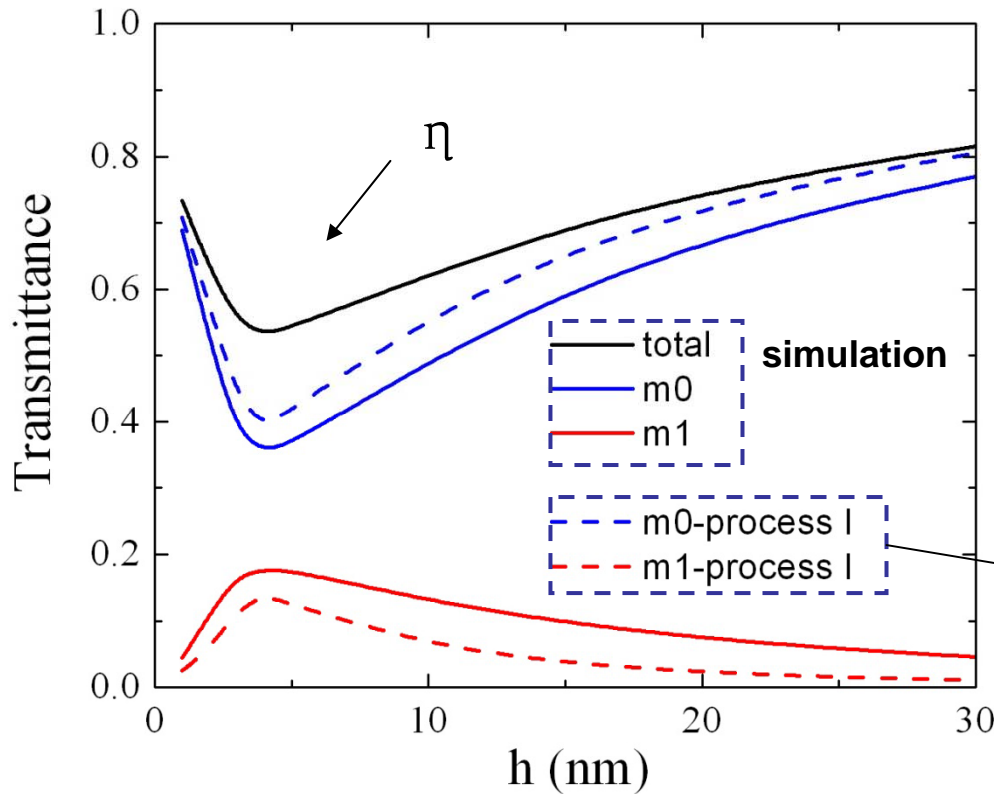
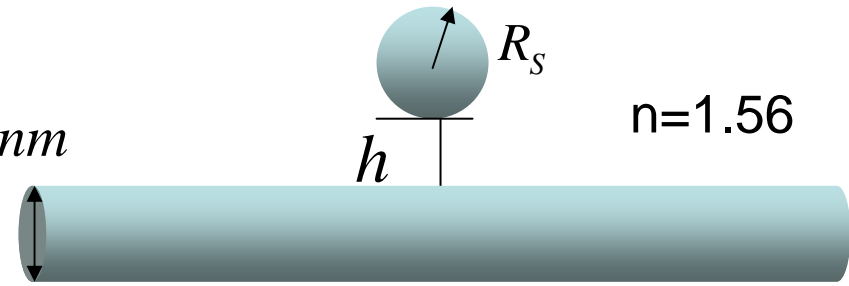


$\lambda = 500 \text{ nm}$   
Phase retardation

# Process I dominant region:

Power of two modes at output for varying  $h$ . (Normalized by input power)

120nm



1. Get simulation result
2. Coefficient  $|t|$ :

$$|t| = \sqrt{2\eta - 1}$$

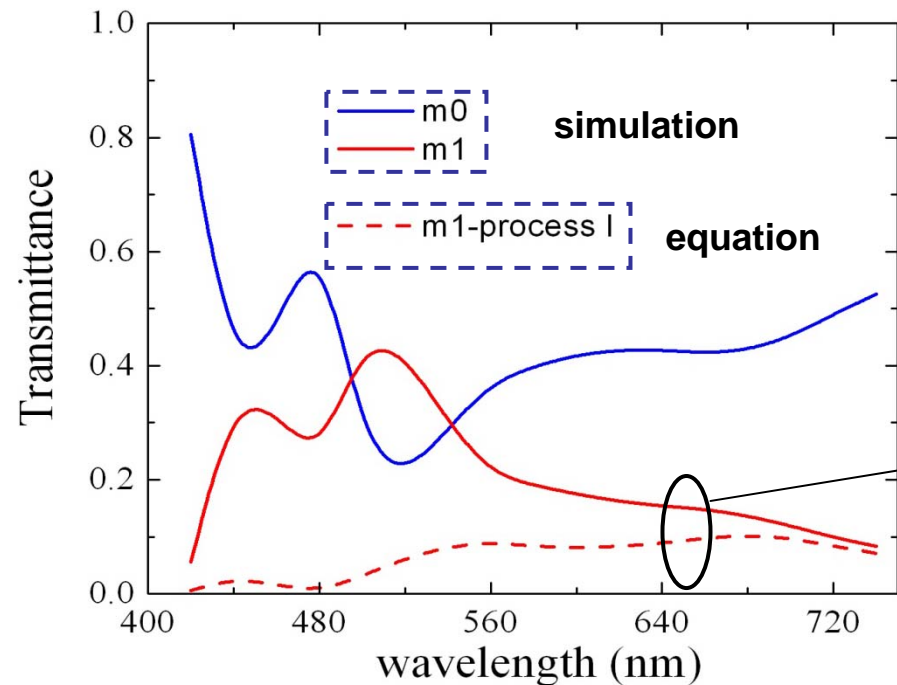
3. Conversion efficiency of through process I

$$\left(\frac{|t| \pm 1}{2}\right)^2$$

$\lambda = 633nm$   $R_s = 60nm$  far away from quadrupole resonance  $\omega_{quad}$

# Process II dominant region:

Power of two modes at output for varying wavelength ( $h=7\text{nm}$ )



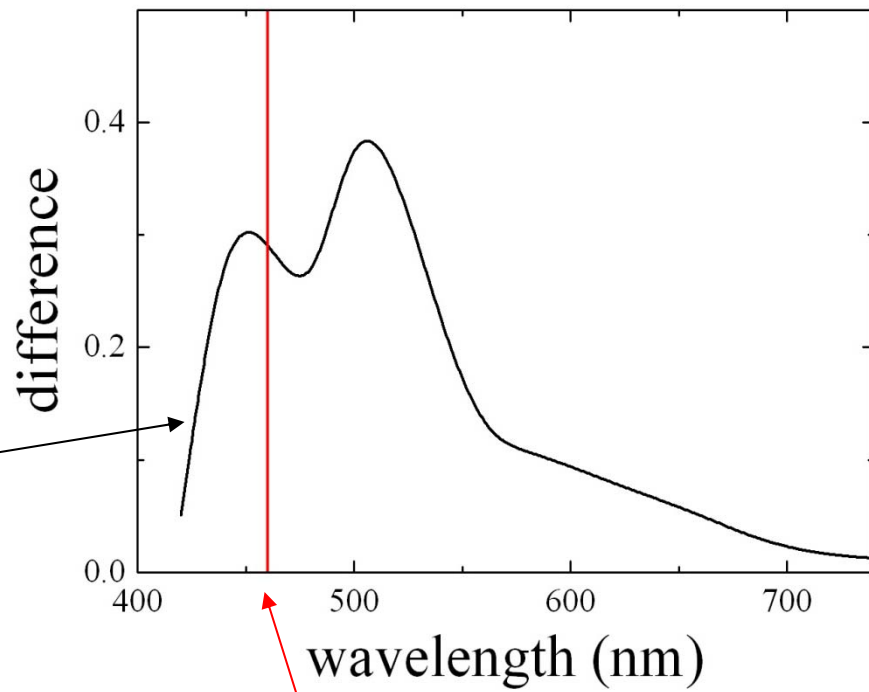
Process II dominant:

Far from  $\omega_{quad}$

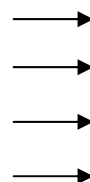
Process I dominant:

Far from  $\omega_{quad}$

Conversion efficiency for Process II

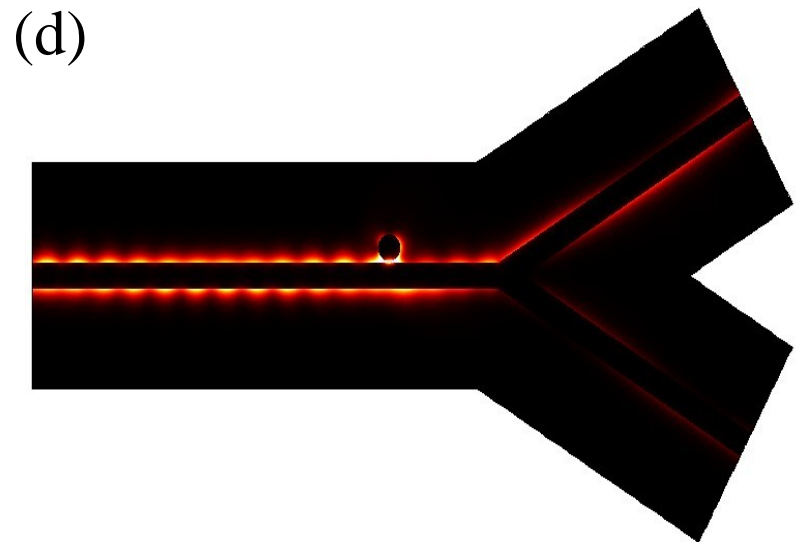
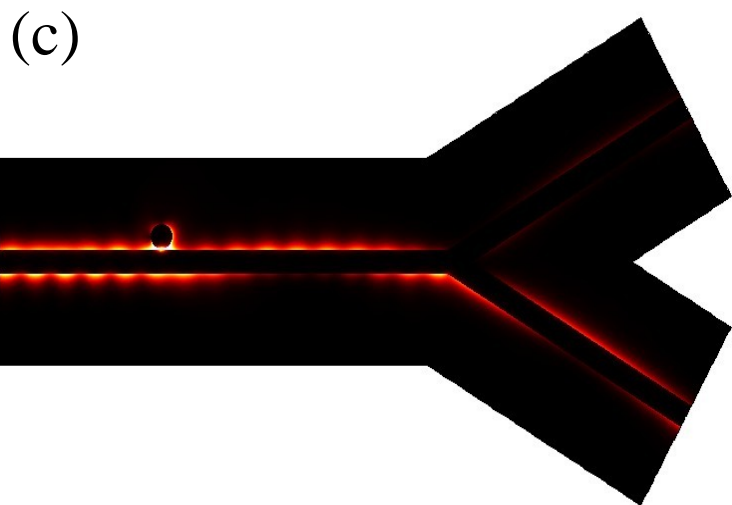
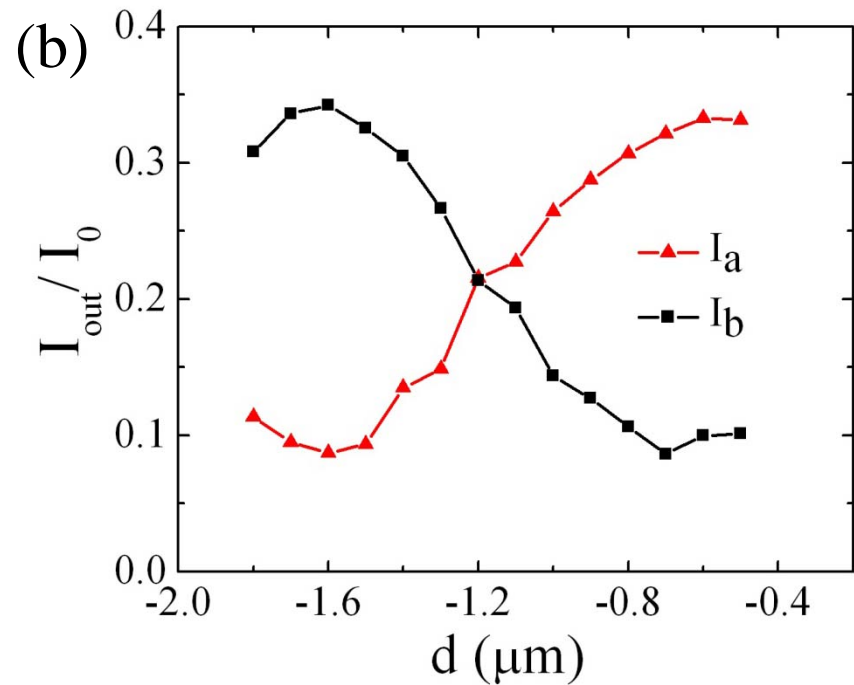
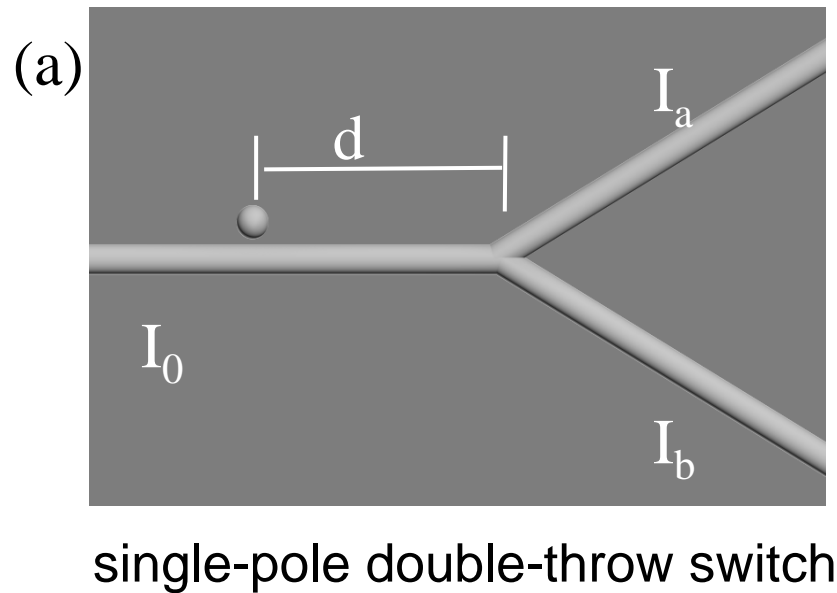


Quadrupole resonance



$n_{eff, m0}$

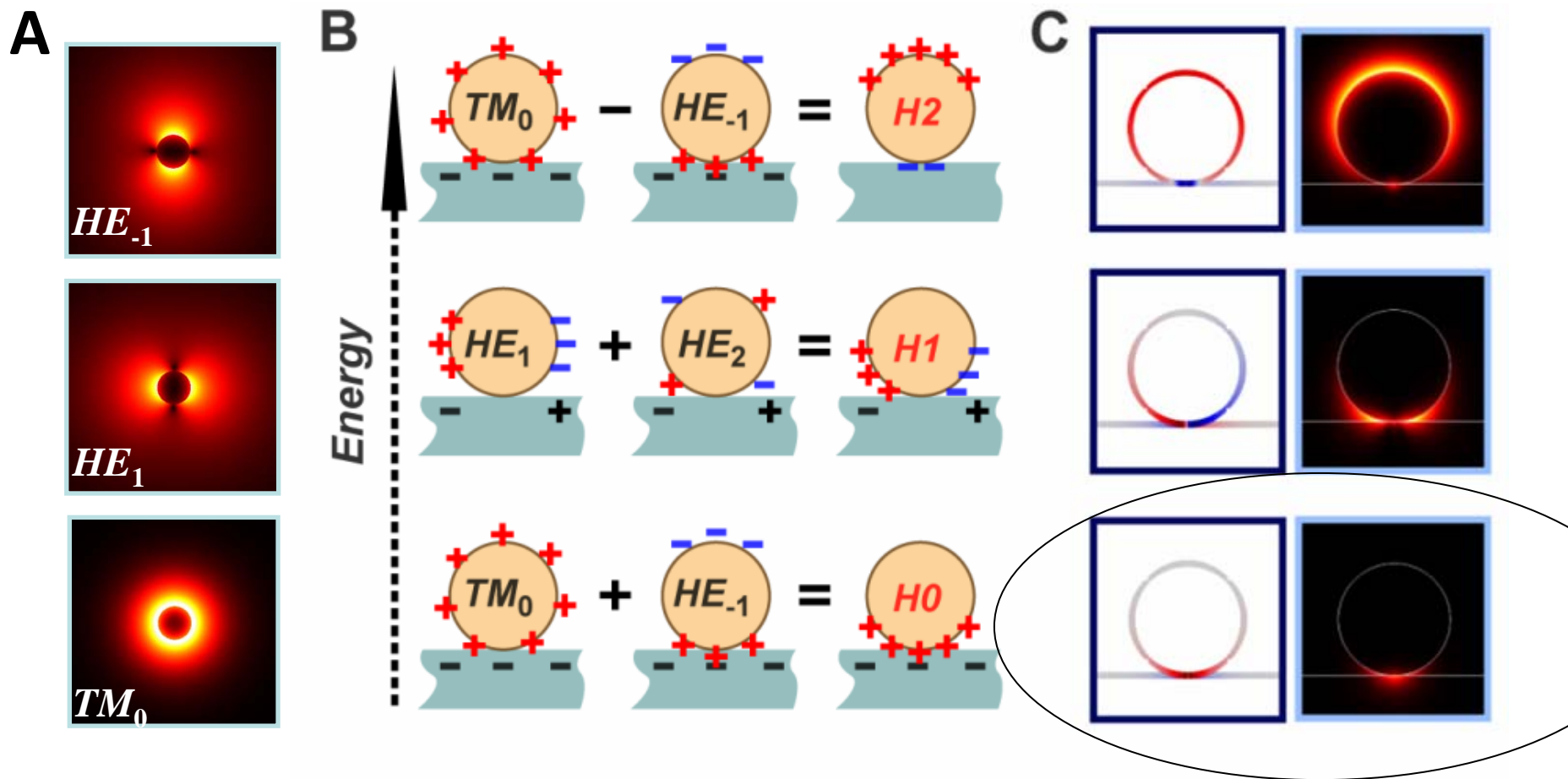
# Application for switch



# Outline

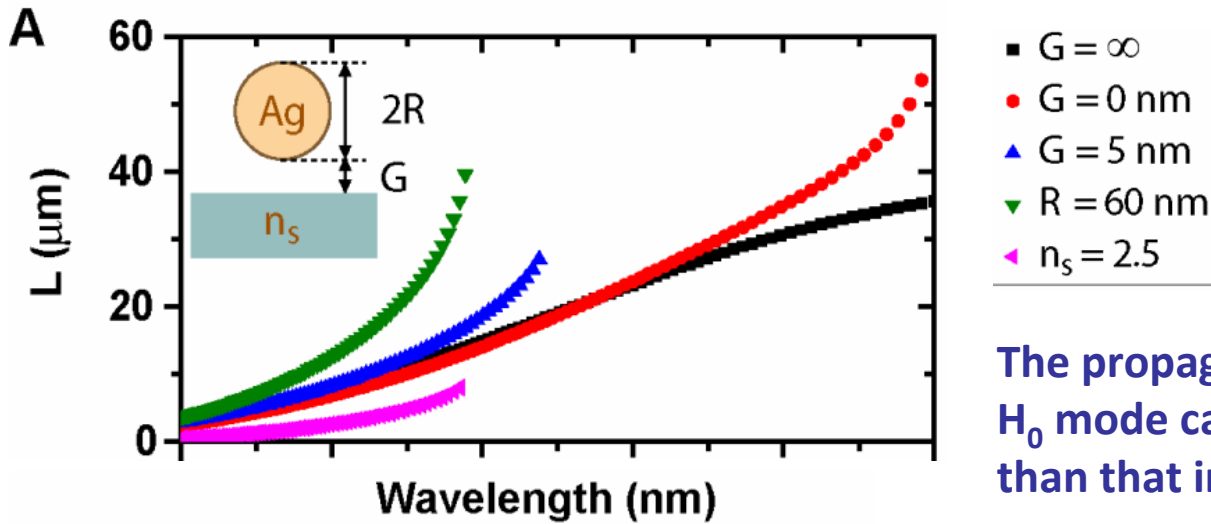
- Near-field, Network and Logic
- Wire plasmon modes/Chiral wire plasmons
- Tunable wire plasmons
- **Substrate-Mediated Plasmon**
- Plasmon Amplification

# Substrate-Mediated Plasmon Coupling



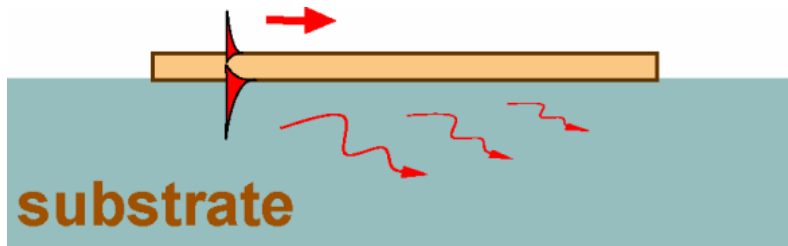


# Leaky radiation into substrate



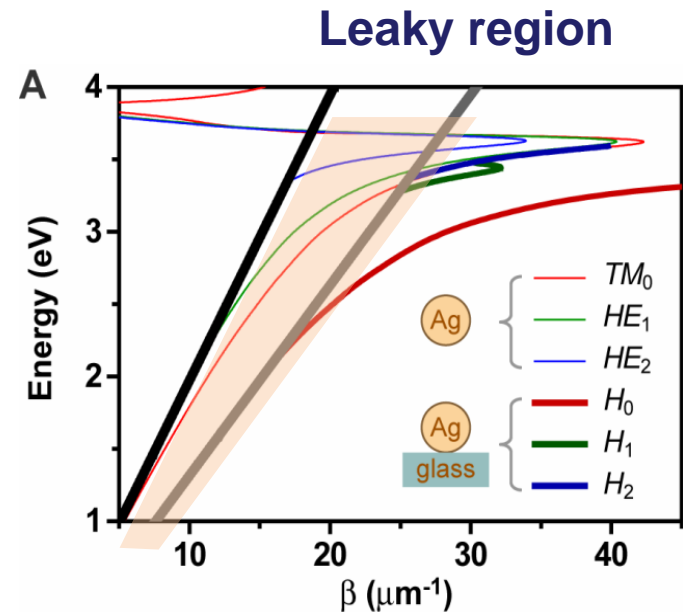
The propagation length of the  $H_0$  mode can be larger in NWOS than that in air.

When the phase constant  $\beta < n_s \cdot k_0$ , the mode can leak into the substrate as it propagates along the nanowire. This is a big drawback for the NWOS configuration.



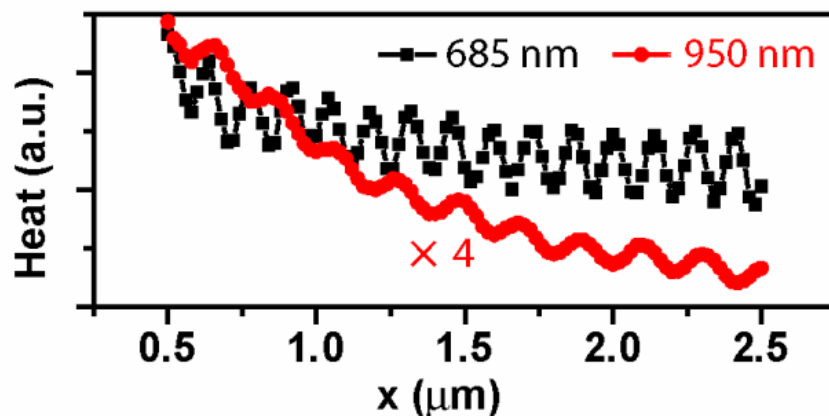
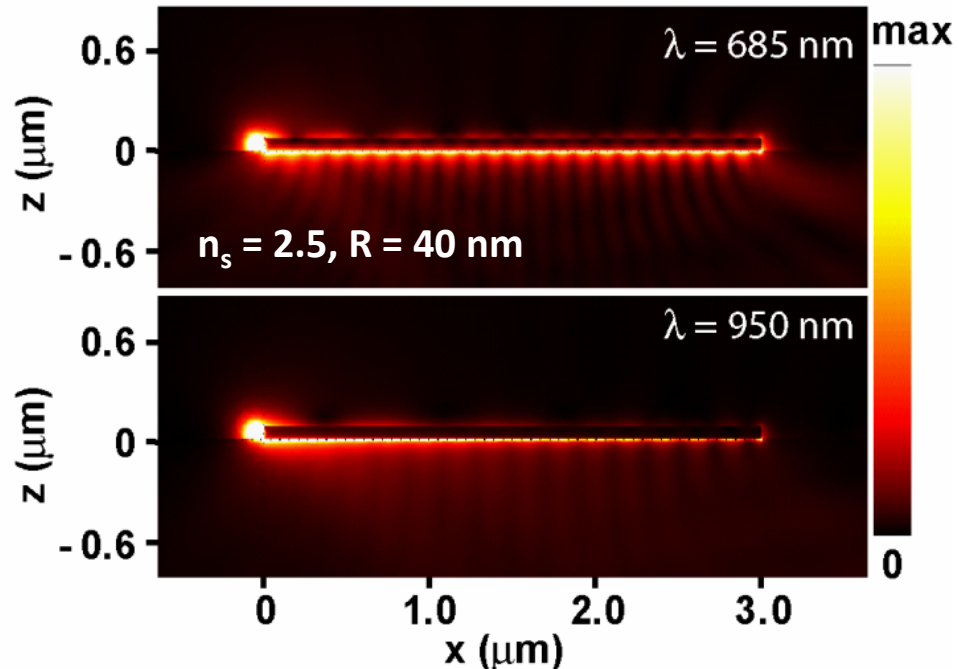
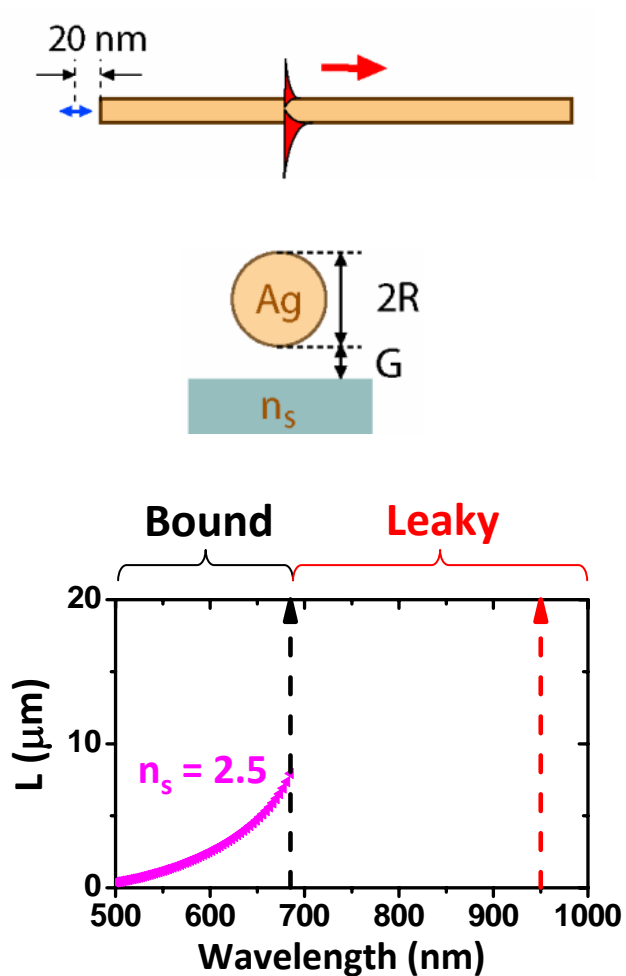
Shegai T et al., Unidirectional Emission ...

**Nano Lett.** 11, 706–711 (2011)



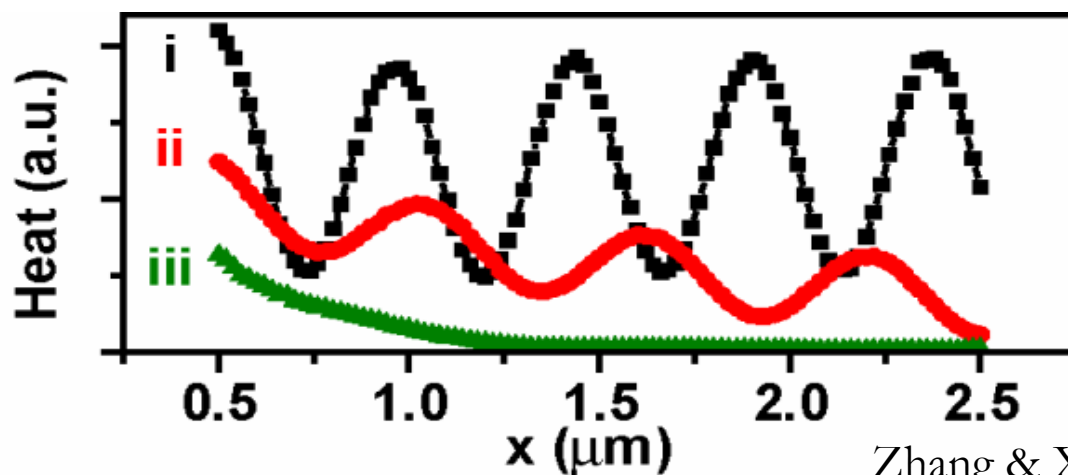
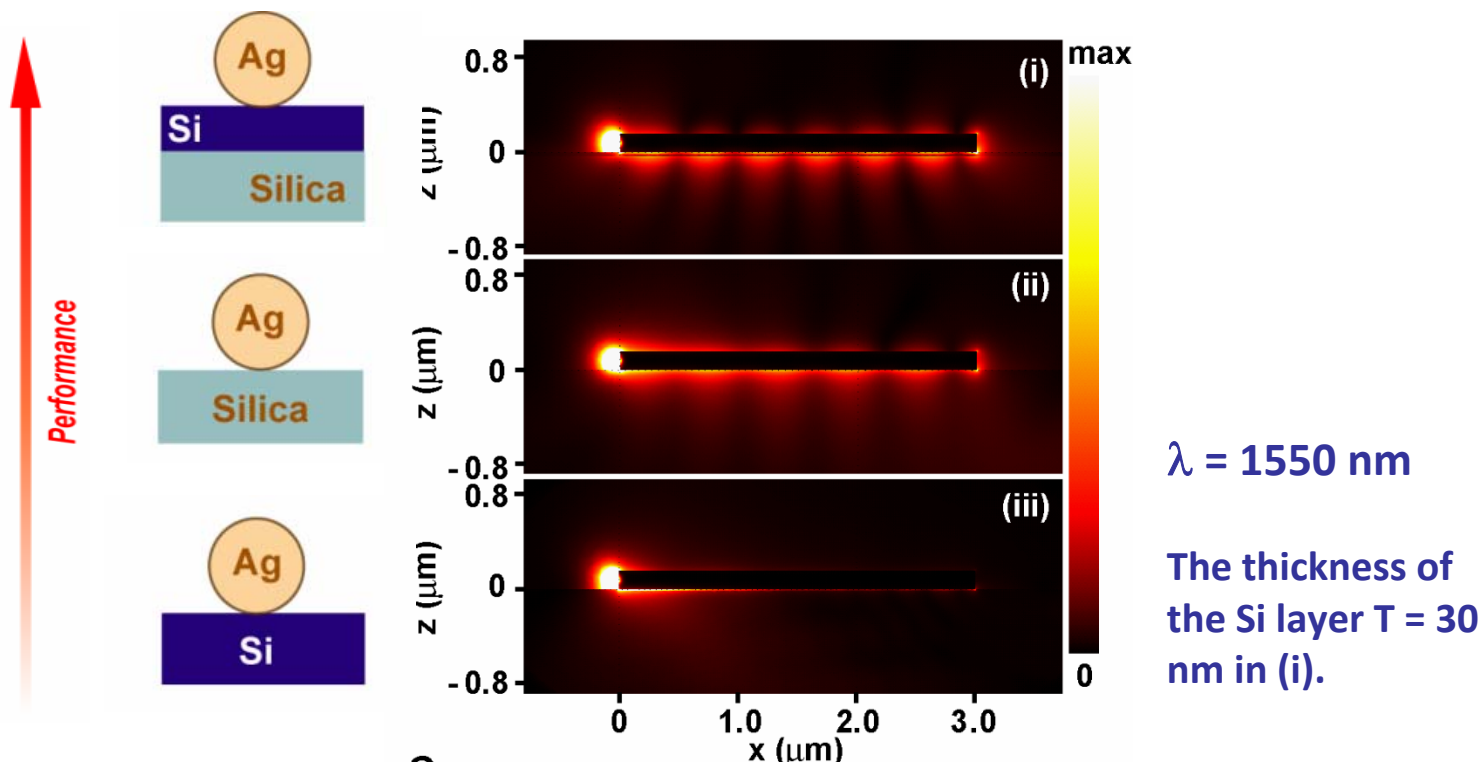
Zhang & Xu ACS Nano, accepted

# Bound vs. Leaky region



Leakage raises the propagation losses, which prevents the NWOS to work with high-permittivity substrate and in long-wavelength region

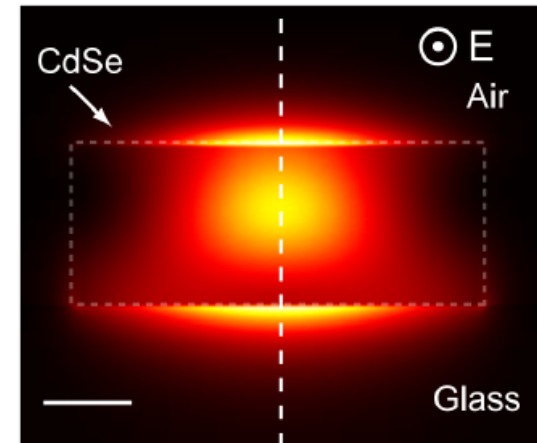
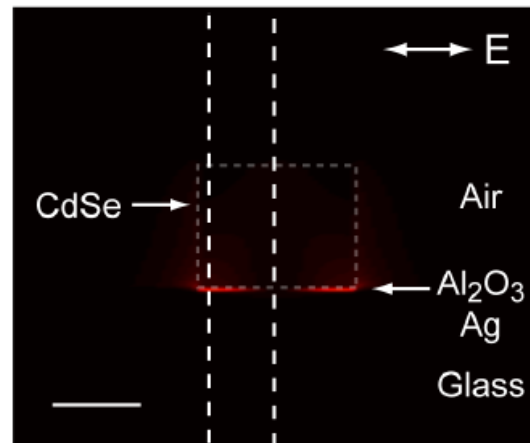
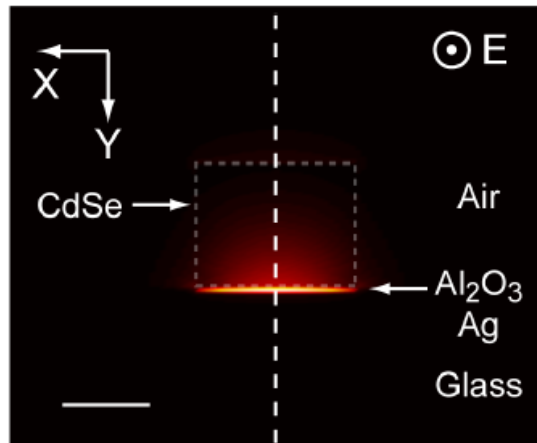
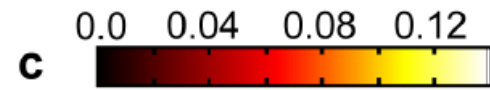
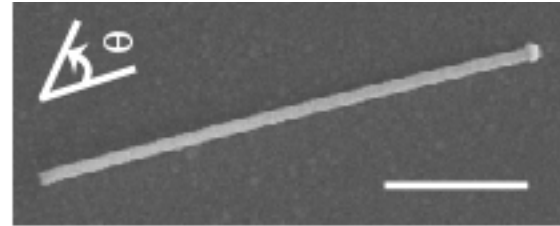
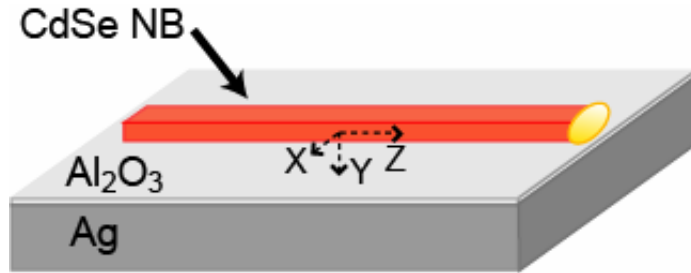
# Layered substrate provides an optical barrier



# Outline

- Near-field, Network and Logic
- Wire plasmon modes/Chiral wire plasmons
- Tunable wire plasmons
- Substrate-Mediated Plasmon
- **Plasmon Amplification**

# CdSe nanobelt/ $\text{Al}_2\text{O}_3$ /Ag hybrid plasmonic waveguide

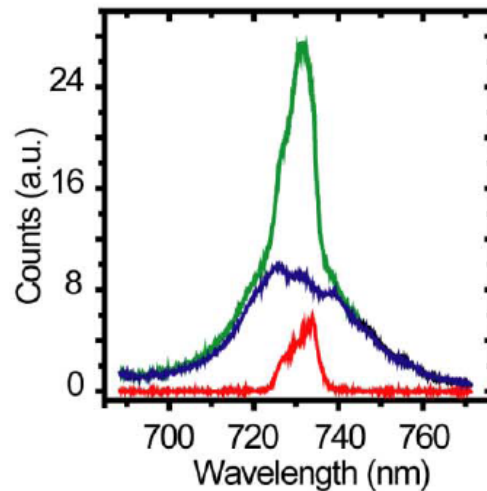
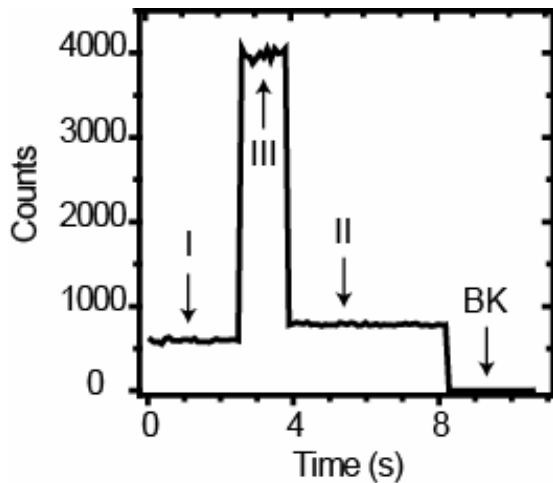
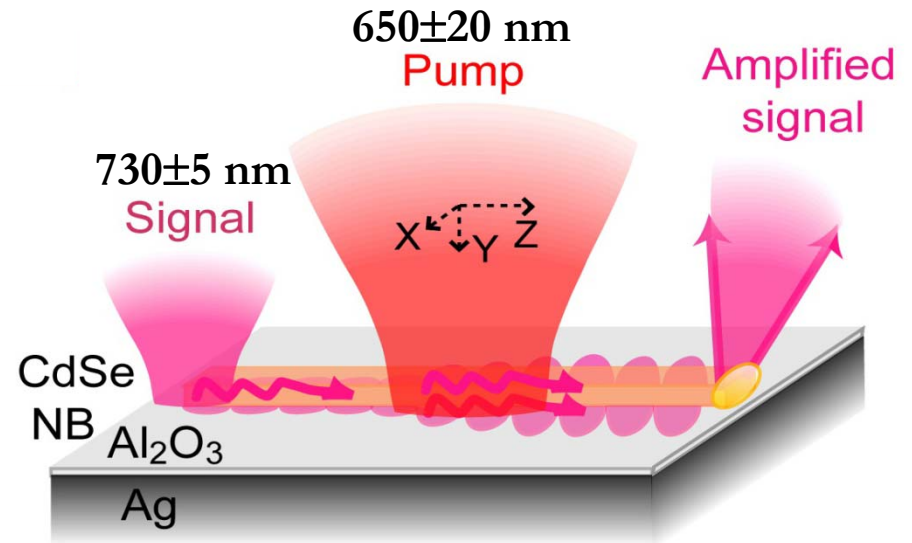
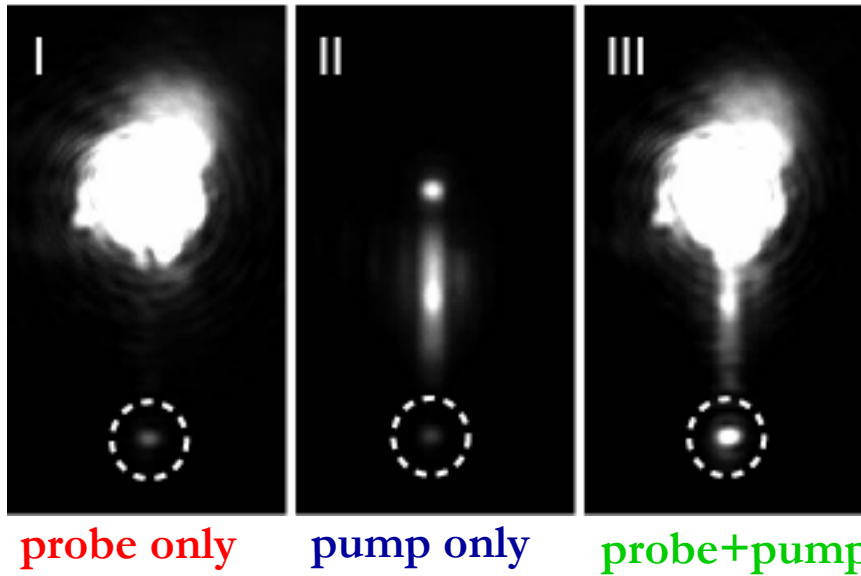


plasmonic

photonic

# Weak signal amplification in plasmonic waveguides

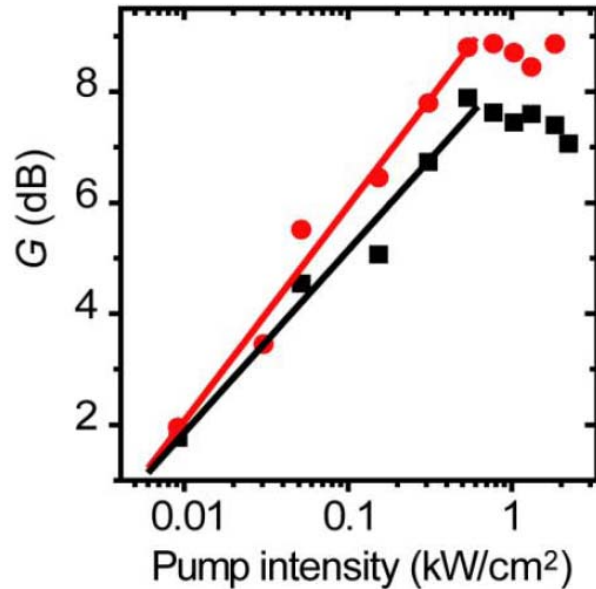
“Pump-Probe” setup to measure optical gain of plasmonic waveguides



All wavelengths in the probe signal, spanning over 10 nm, are amplified.  
broadband loss compensation

# gain for TM and TE modes

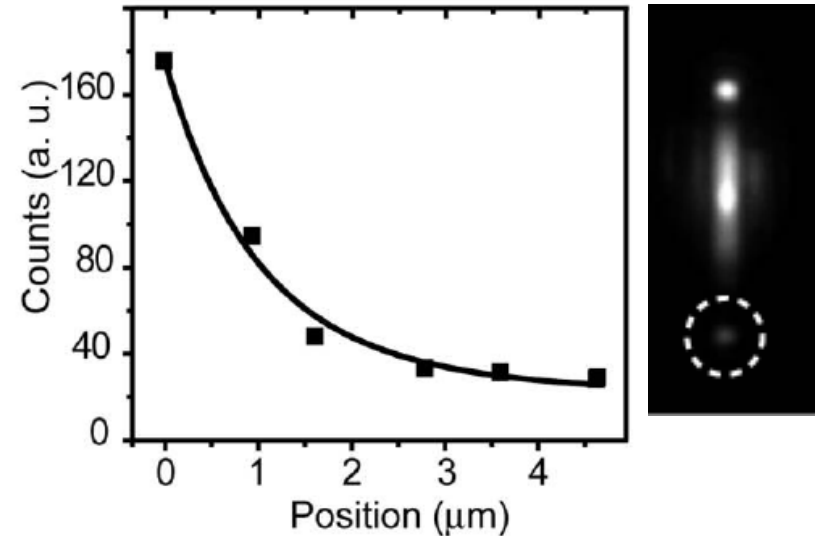
$$G(\text{dB}) = 10 \log \left( \frac{I_{on} - I_{sp}}{I_{off}} \right) = 10 \log(G)$$



- : parallel polarization (TM)
- : perpendicular polarization (TE)

Internal gain coefficient:  
 $g = 6140 \text{ cm}^{-1}$  for TM mode;  
 $g = 6755 \text{ cm}^{-1}$  for TE mode.

output intensity *vs* pump location

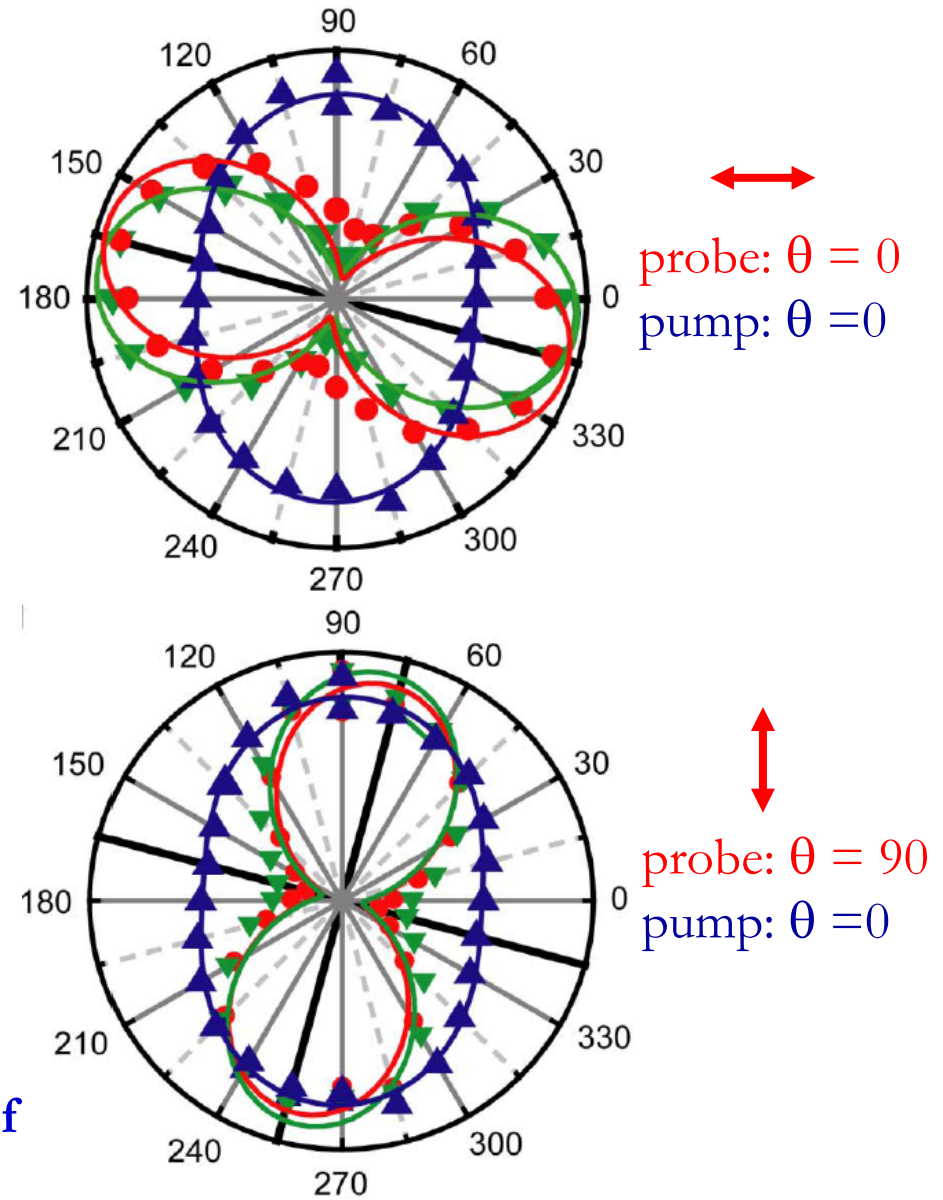
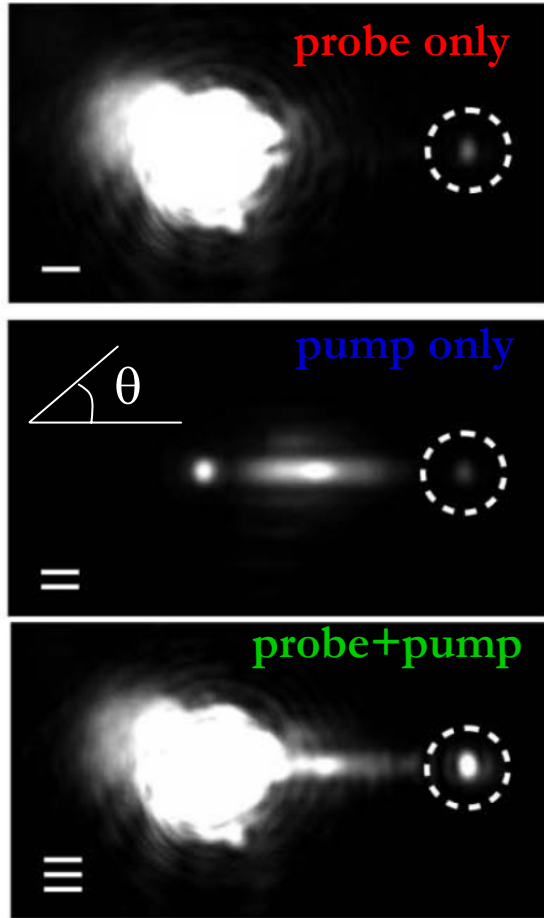


Propagation loss coefficient:  
 $6230 \text{ cm}^{-1}$  for TM mode;  
 $11420 \text{ cm}^{-1}$  for TE mode.

**The propagation loss of TM mode was almost fully compensated.**



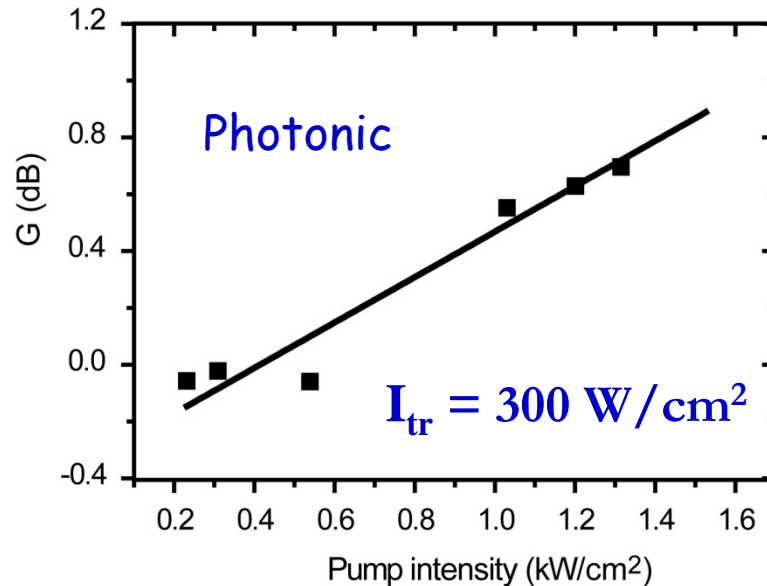
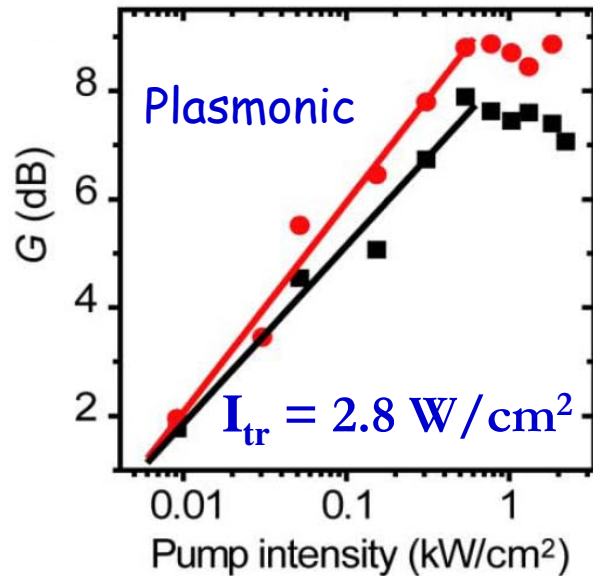
# Emission polarization for input signals of TM and TE polarization



The polarization of the compensated signal (green) follows the polarization of the probe signal (red).

# Comparison of gain in plasmonic and photonic waveguides

$$G = G_0 \ln \frac{I}{I_{tr}} \quad I_{tr}: \text{transparency pump intensity, indicating the start of gain}$$



Internal gain coefficient  $g = fg_m$

$f$ : fractional factor as the ratio of electric field in CdSe nanobelt and in entire structure.

$f=0.64$  for plasmonic,  $f=0.52$  for photonic

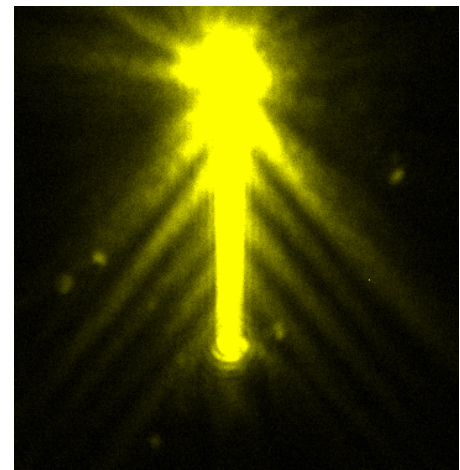
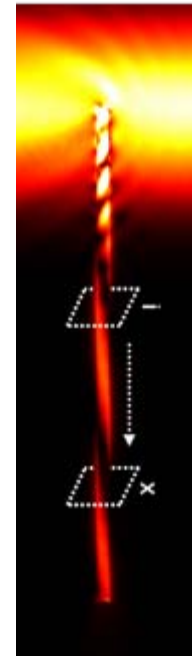
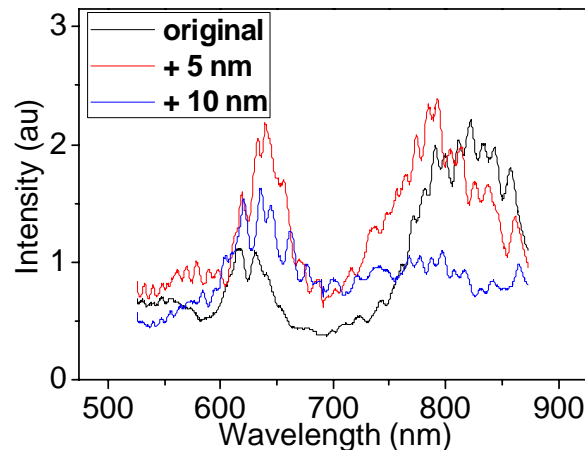
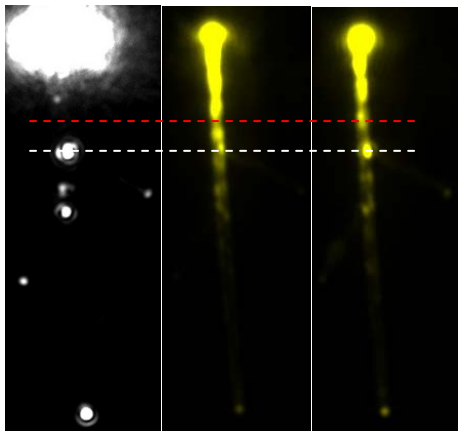
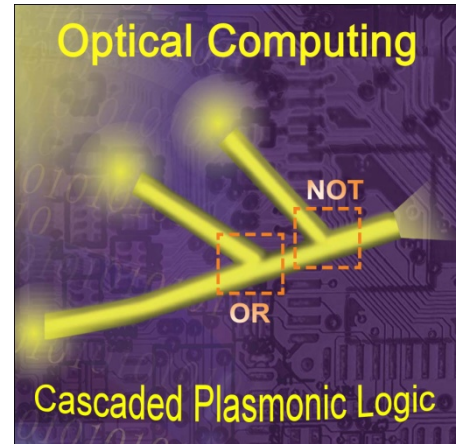
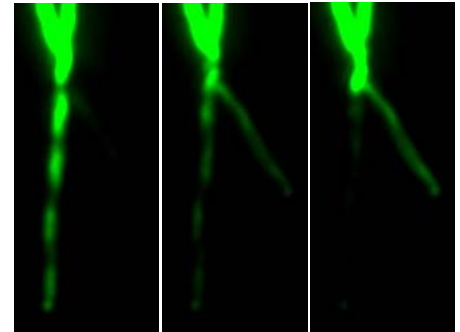
$g_m$ : material gain coefficient

Pump rate determined by the electric field intensity within the CdSe nanobelt: **2.34**

The transfer of photo-generated hot electrons from Ag film to CdSe nanobelt results in the large difference of  $I_{tr}$  for plasmonic and photonic waveguides.

# Summary

- Quantum dot near field imaging
- Plasmon-based nanowire devices: switch, splitter, router,  $\lambda/4$  wave plate, ...
- Interferometric logic, cascade
- Effect of dielectric environment, controlling the beating periods
- Directional propagation in Ag film





**Hongxing Xu Group:** <http://n03.iphy.ac.cn>

**Position openings:**

- International Young Scientist Fellowship (Post Doc)
- Research Scientist (Staff)

**Contact: Prof Hongxing Xu, [hxxu@iphy.ac.cn](mailto:hxxu@iphy.ac.cn)**

**Acknowledge:** Support from CAS, NSF, MOST





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**Hongxing Xu Group** <http://n03.iphy.ac.cn>



**Thanks for your attention!**